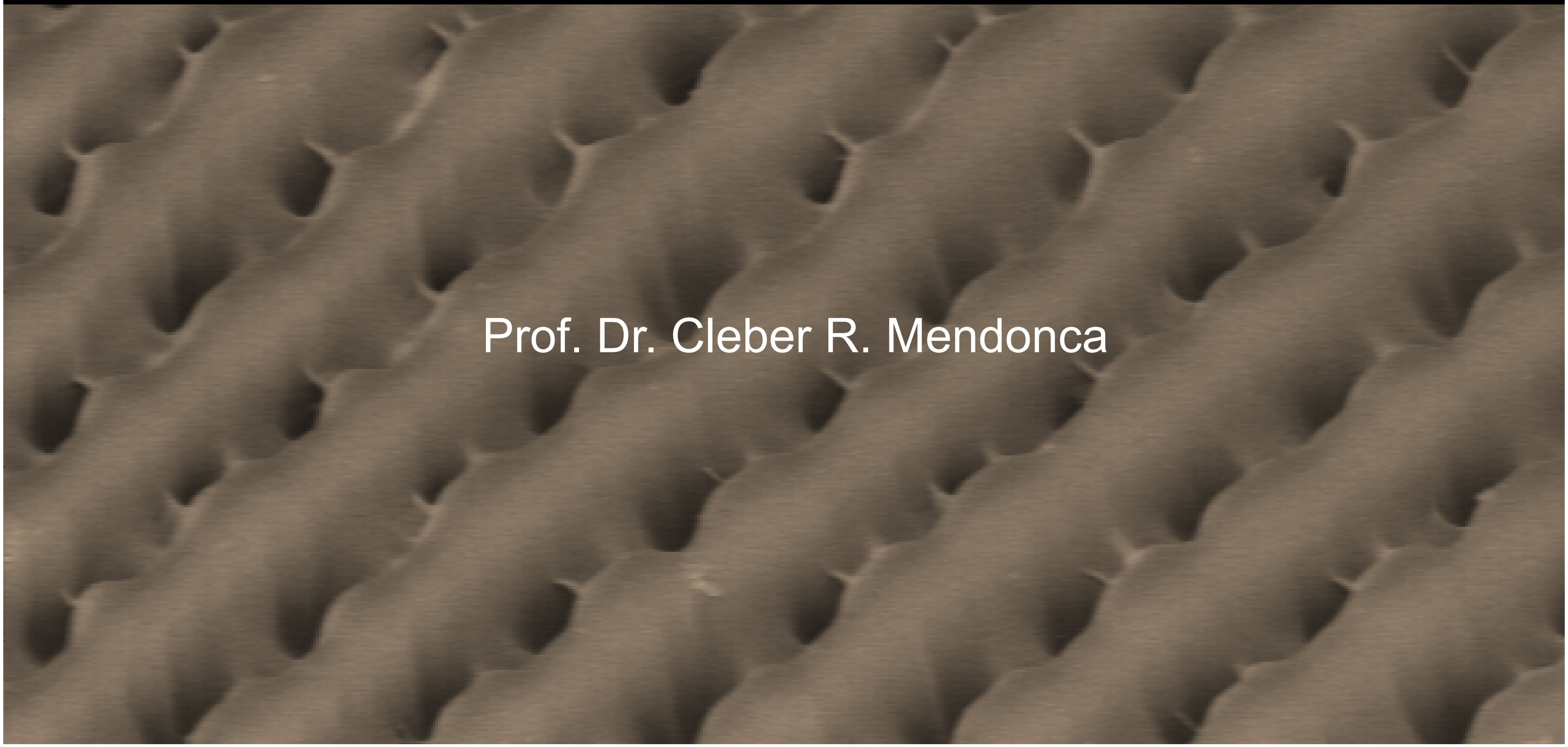
Sculpturing with light: advanced processing of materials for optical and biological applications



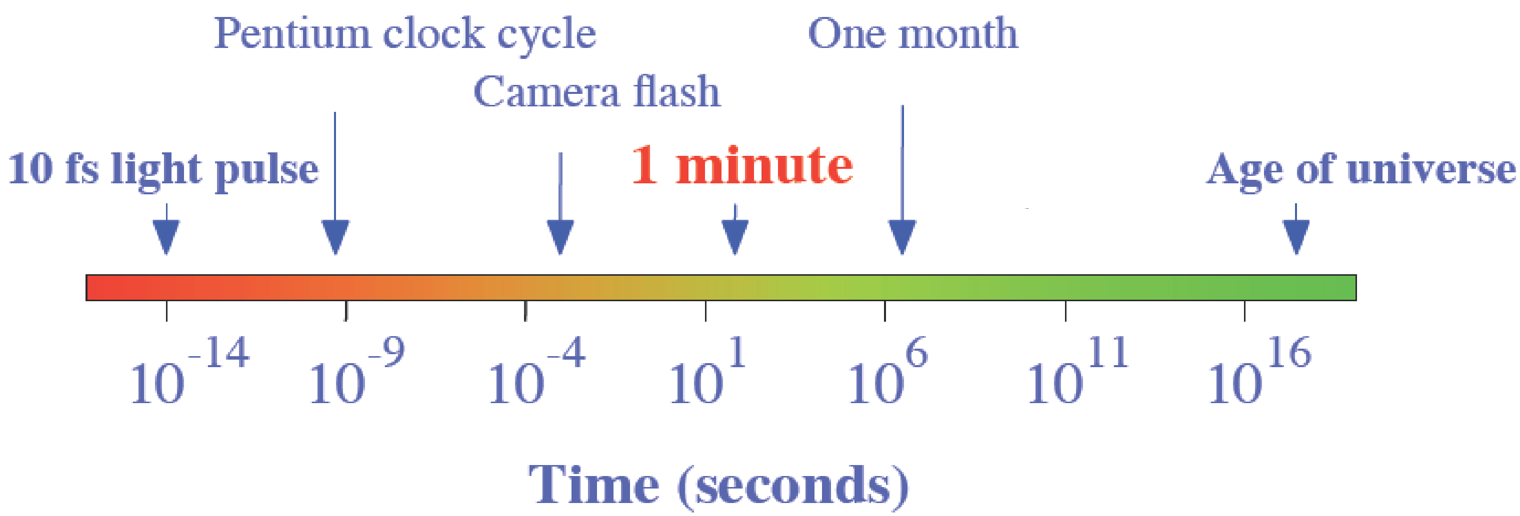
Prof. Dr. Cleber R. Mendonca

Microfabrication

Microfabricate and microstructure materials using fs-laser and nonlinear optical processes

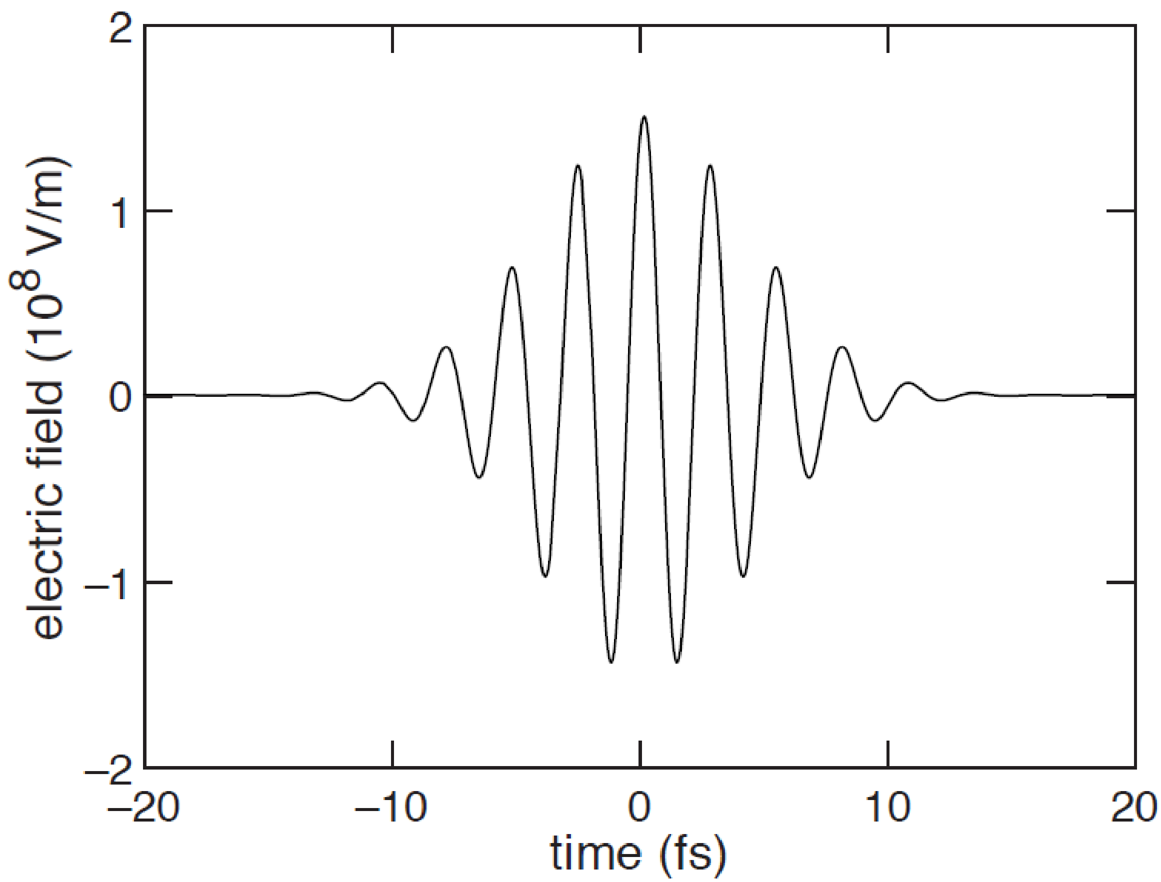
Microfabrication

1 fs = 10^{-15} s



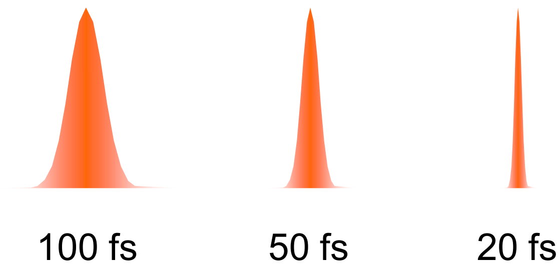
introduction

how short is a femtosecond pulse ?



Microfabrication

Ti:Sapphire lasers



Very intense light

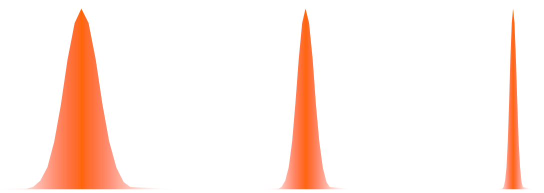
Laser intensities ~ 100 GW/cm²

1×10^{11} W/cm²

Laser pointer: 1 mW/cm² (1×10^{-3} W/ cm²)

fs-laser micromachining

Ti:Sapphire lasers

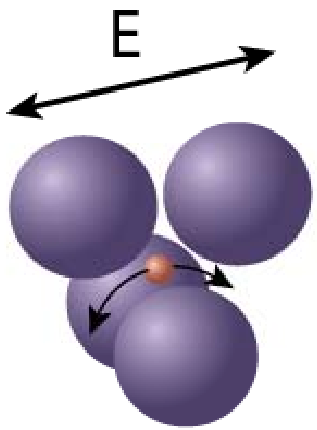


100 fs   50 fs   20 fs

Very intense light

Nonlinear Optical Phenomena

Nonlinear Optics



anharmonic oscillator

high light intensity

$E_{rad.} \sim E_{inter.}$

nonlinear polarization response

$$P = \chi^{(1)} E + \chi^{(2)} E^2 + \chi^{(3)} E^3 + \ldots$$

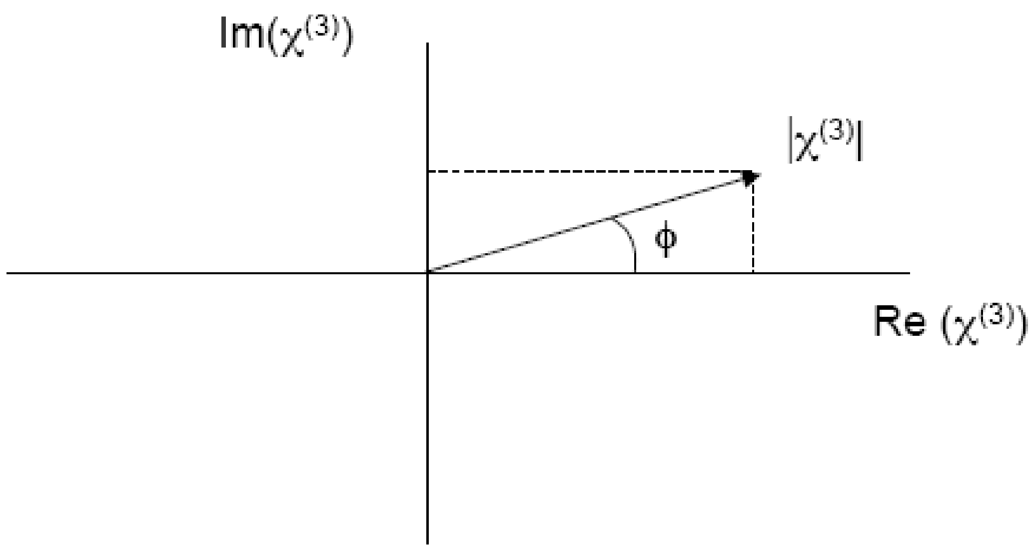
Nonlinear Optics

$\chi^{(3)}$ is a complex quantity

$$\chi^{(3)} = \mathrm{Re}\,(\chi^{(3)}) + i\,\mathrm{Im}(\chi^{(3)})$$

Related to intensity dependent refractive index

Related to two-photon absorption

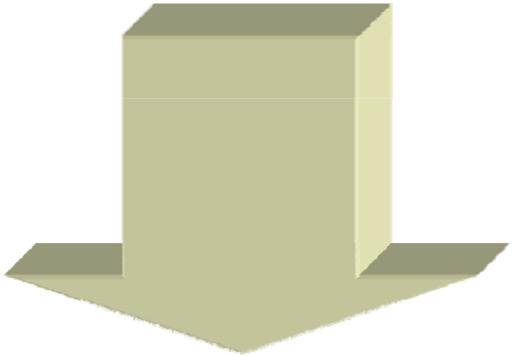


Nonlinear Optics

Third order processes: $\chi^{(3)}$

Refractive process:

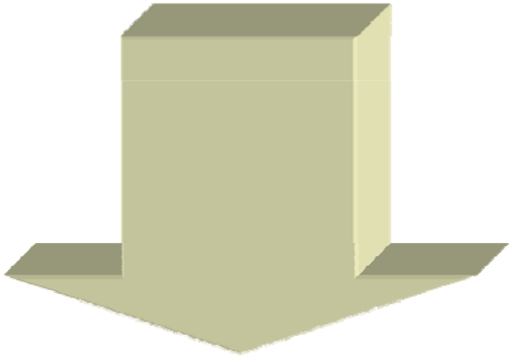
$$n = n_0 + n_2 I$$



- self-phase modulation
- lens-like effect

Absorptive process:

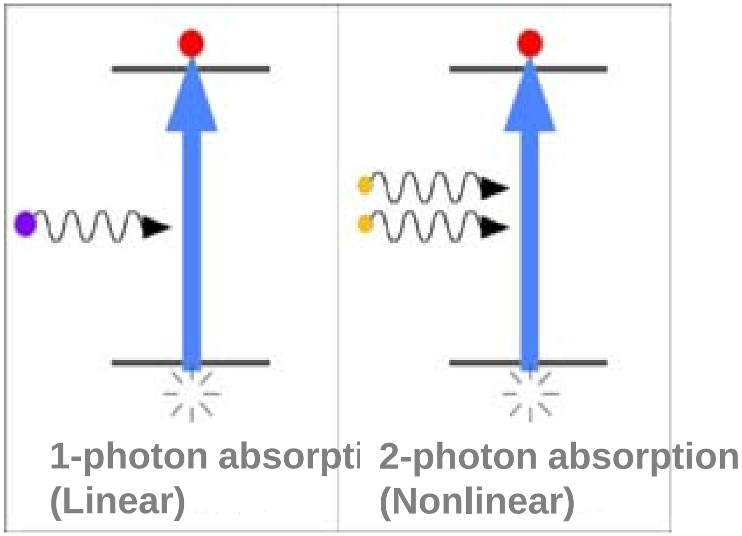
$$\alpha = \alpha_0 + \beta I$$



- nonlinear absorption
- two-photon absorption

Two-photon absorption

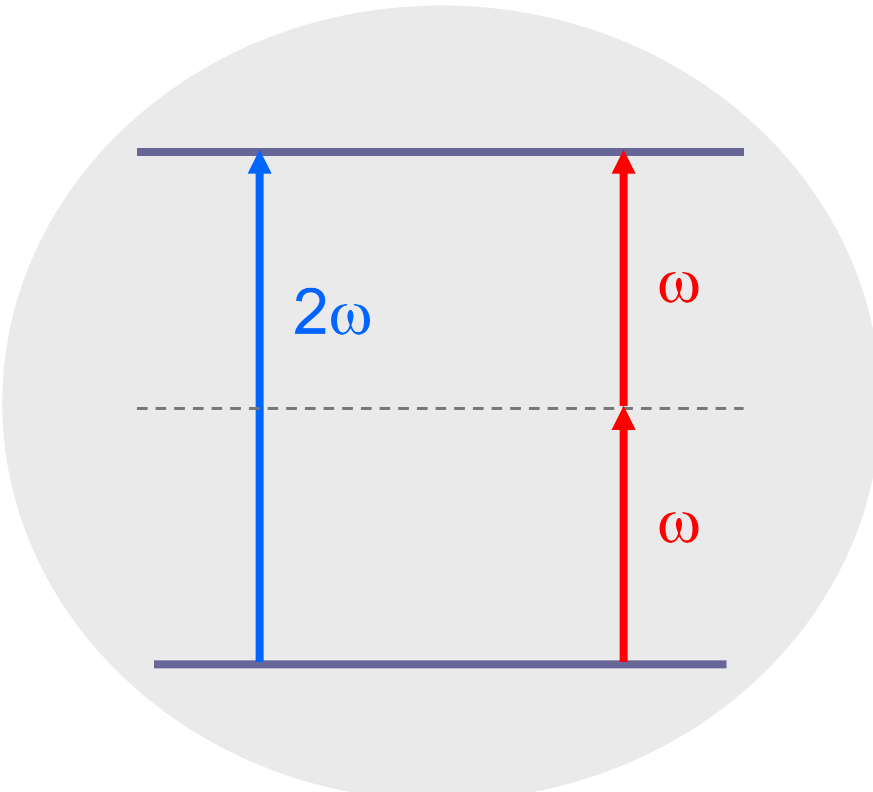
Phenomenon does not described for the Classical Physics and does not observed until the development of the Laser.



Theoretical model: Maria Göppert-Mayer, 1931

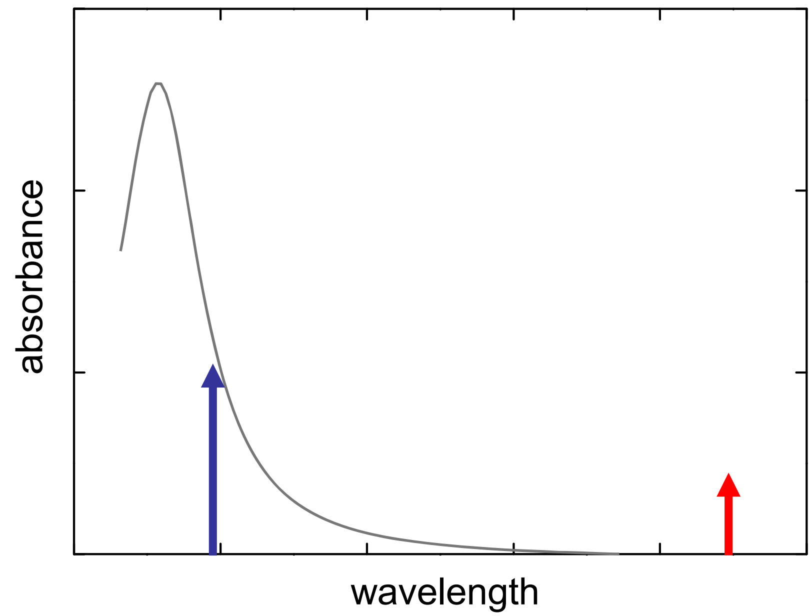
Two photons from an intense laser light beam are simultaneously absorbed in the same “quantum act”, leading the molecule to some excited state with energy equivalent to the absorbed two photons.

Two-photon absorption



$$\alpha = \alpha_0 + \beta I$$

Third order processes $\chi^{(3)}$



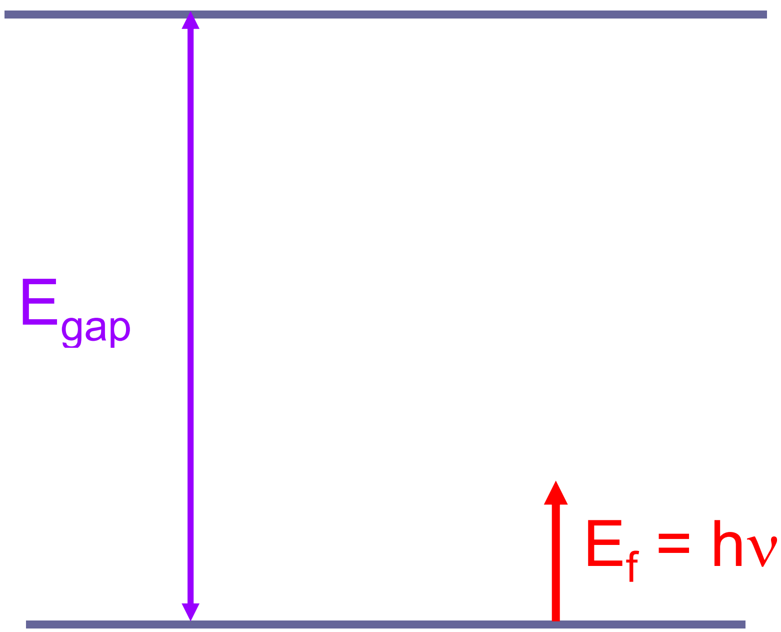
fs-laser microfabrication

photon energy < bandgap

nonlinear interaction

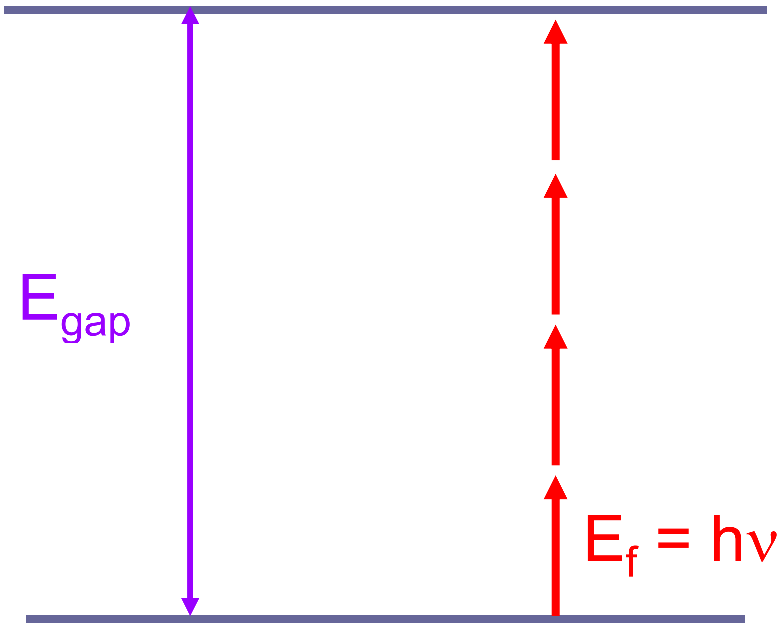
fs-laser microfabrication

nonlinear interaction



fs-laser microfabrication

nonlinear interaction

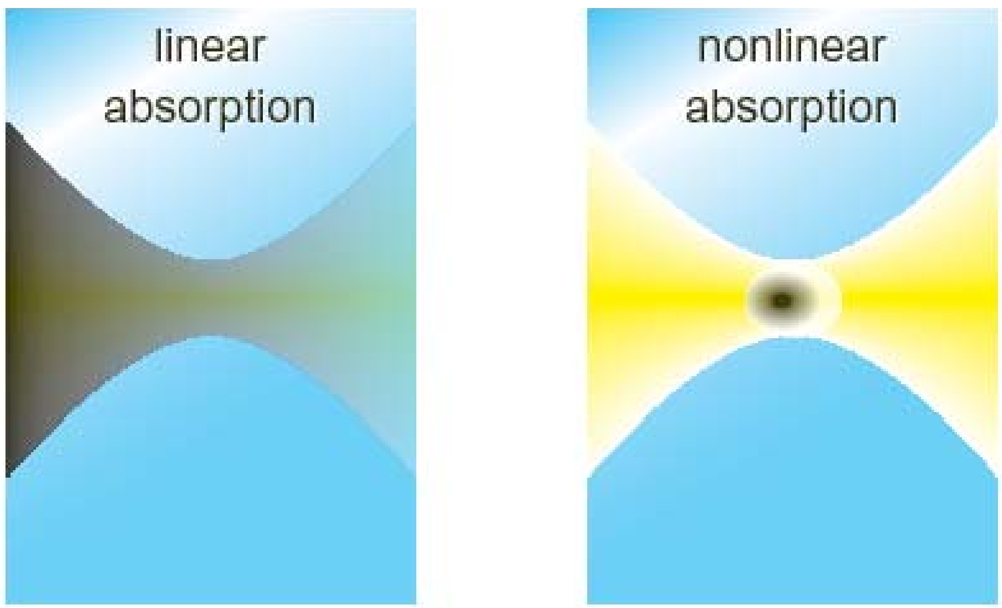


multiphoton absorption

Multi-photon absorption

Nonlinear interaction provides spatial confinement of the excitation

fs-microfabrication



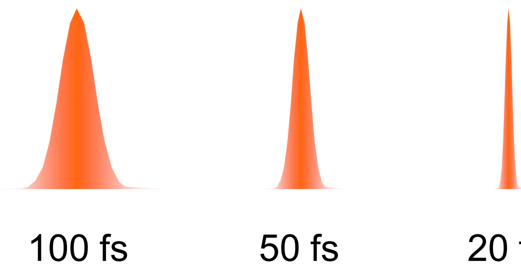
$$\alpha = \alpha_0 \qquad\qquad \alpha = \alpha_0 + \beta I$$

Two-photon absorption

spatial confinement of excitation

femtosecond pulses

Ti:Sapphire lasers

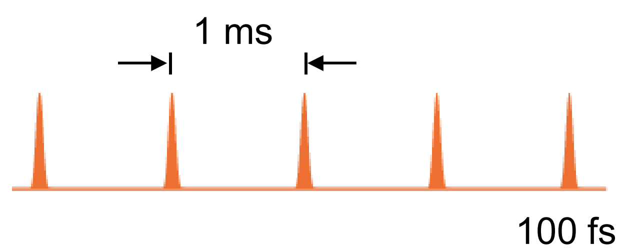


1 fs = 10^{-15} s

Repetition rate

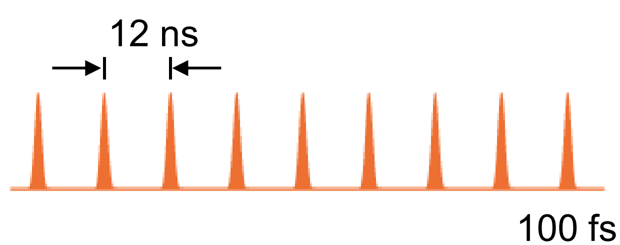
Energy

1 KHz



mJ

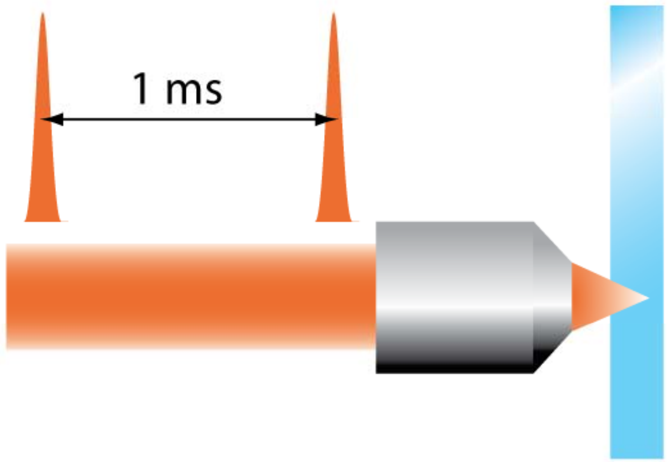
86 MHz



nJ

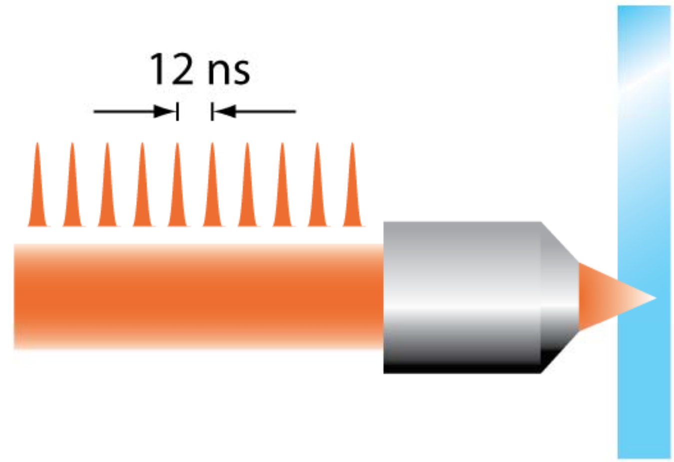
femtosecond pulses

amplified laser



repetitive

oscillator

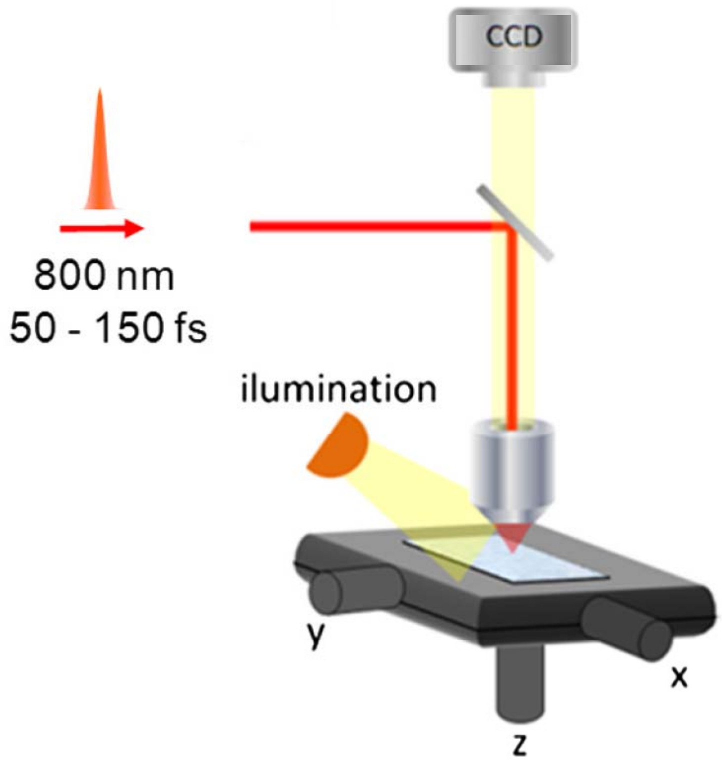


cumulative

two main techniques

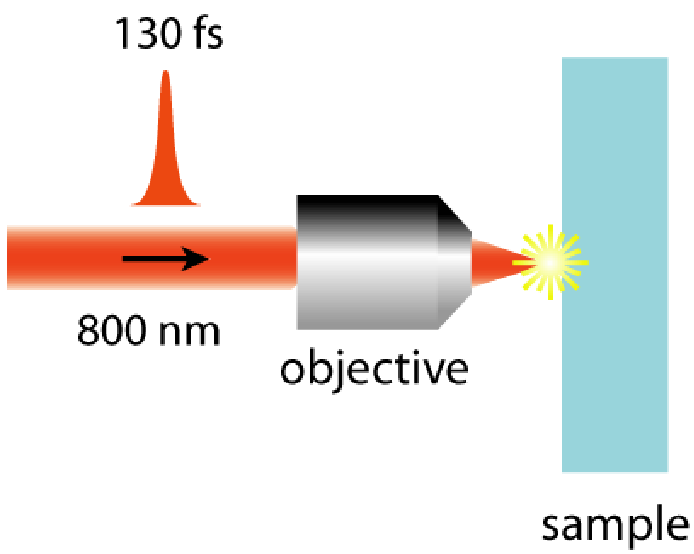
- fs-laser micromachining/microstructuring
- microfabrication via two-photon polymerization

fs-laser microstructuring experimental setup

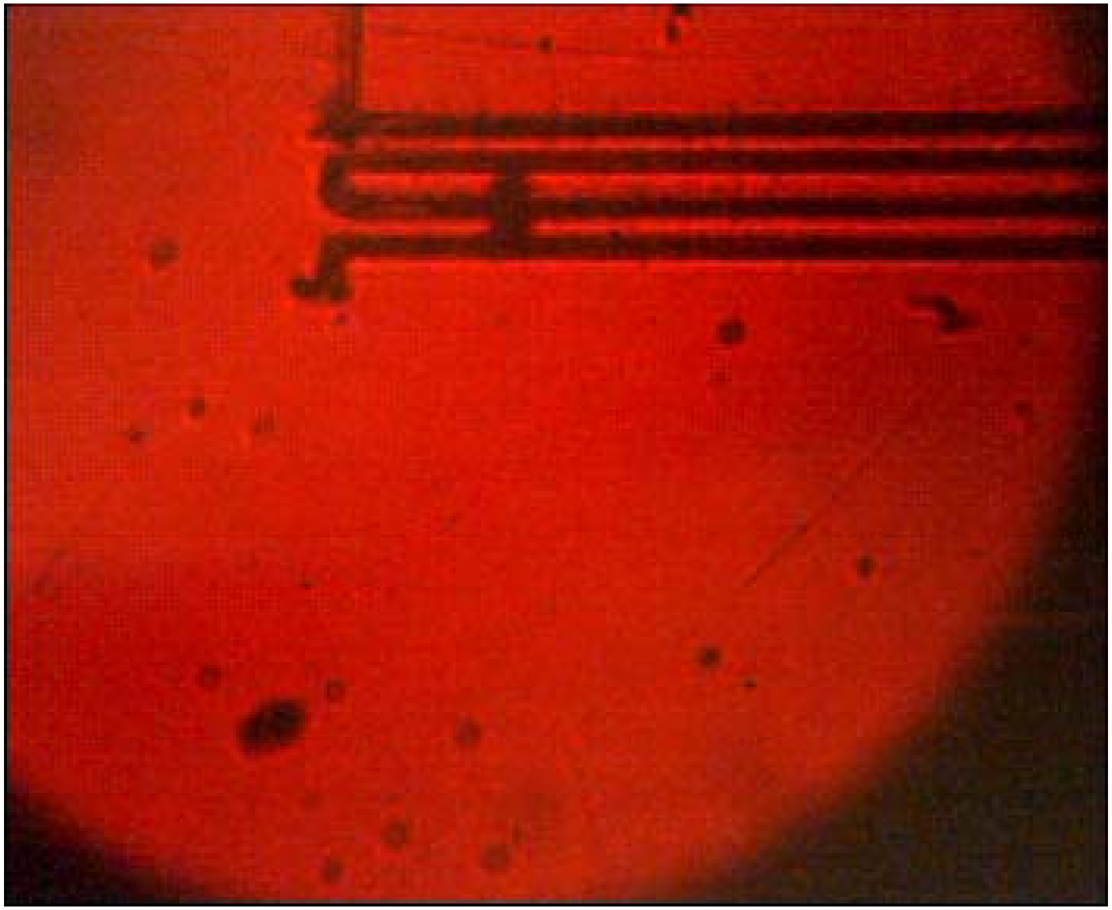


fs-laser micromachining

Surface

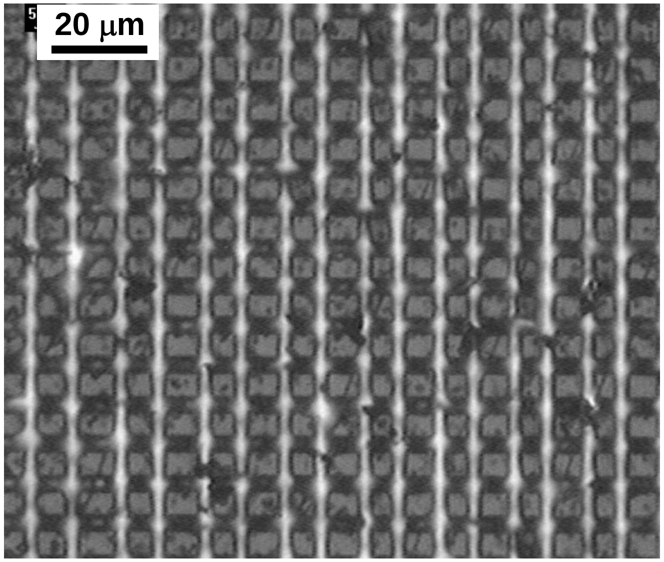


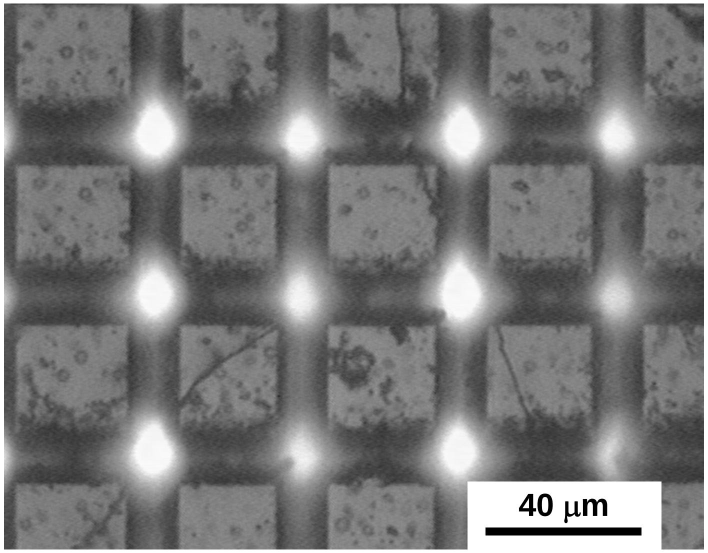
microstructuring polymer: super hydrophobic surface



laser microfabrication: super hydrophobic surface

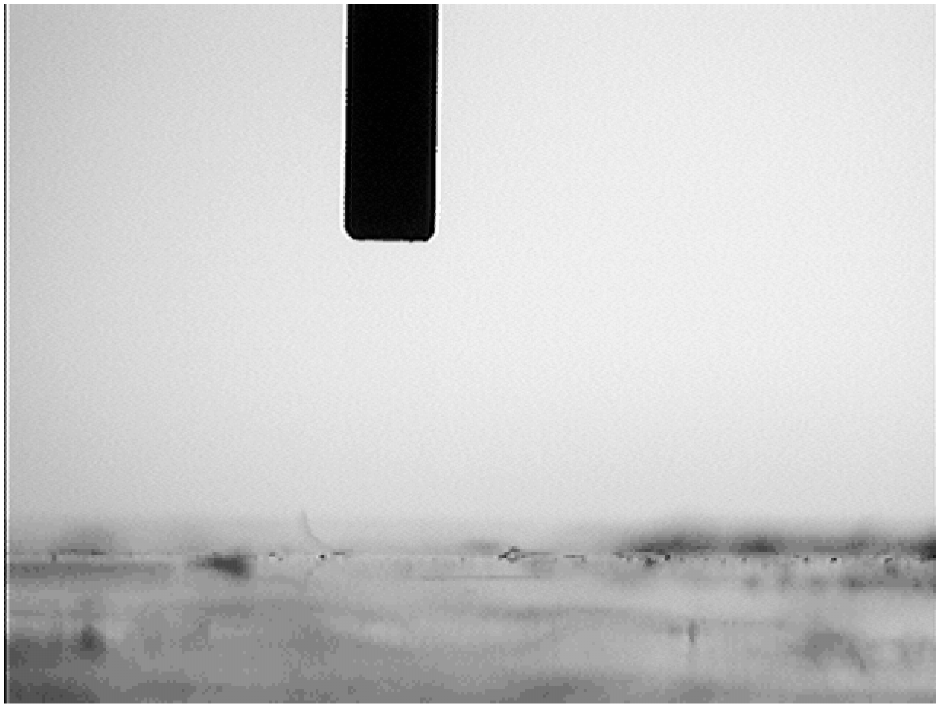
examples of fabricated surfaces

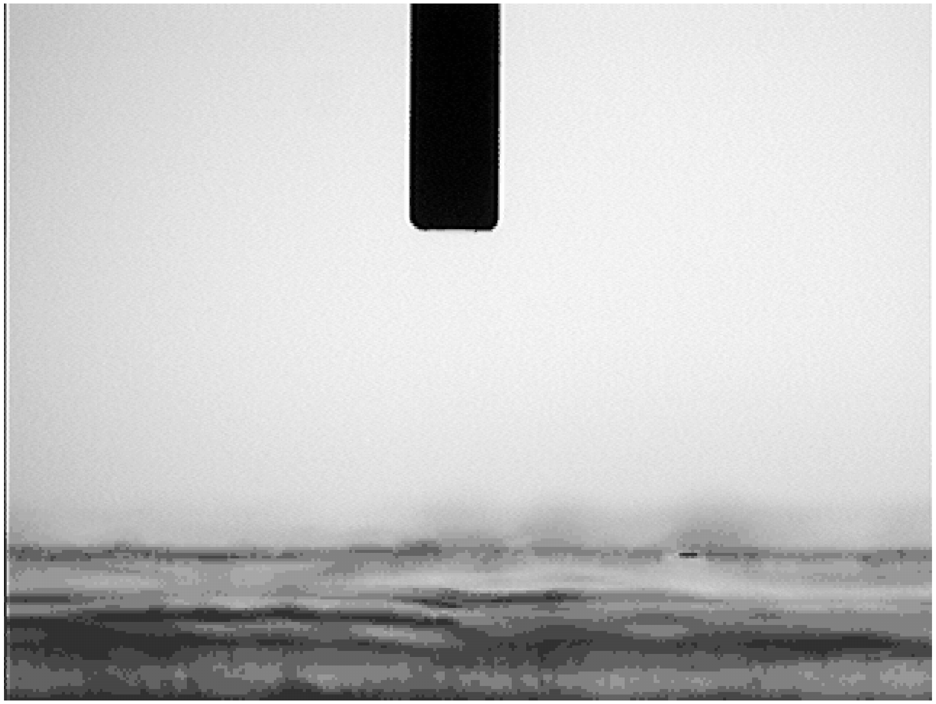




laser microfabrication: super hydrophobic surface

Superhydrophobic surfaces

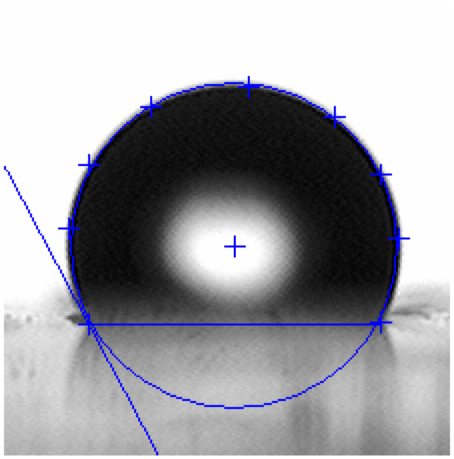




flat surface

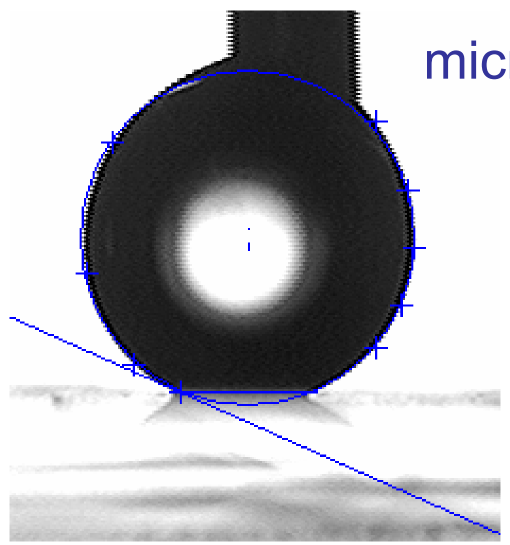
microstructured surface

microstructuring polymer



flat surface

θ = 118º

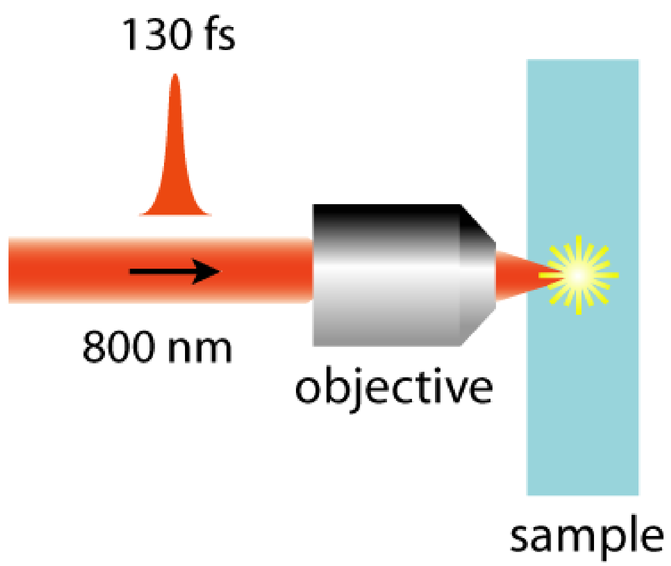


microstructured surface

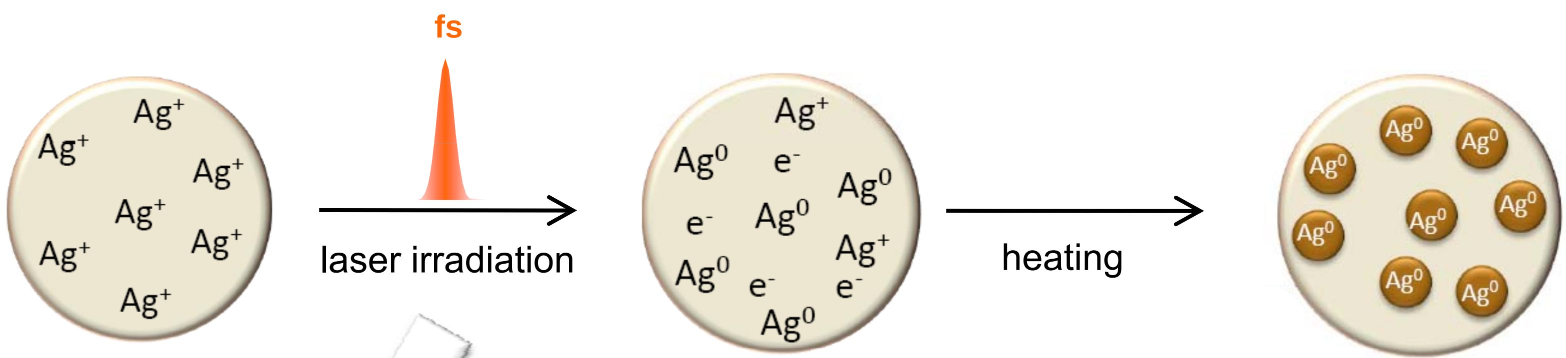
θ = 160º

fs-laser micromachining

Volume



Generation of Ag nanoparticles



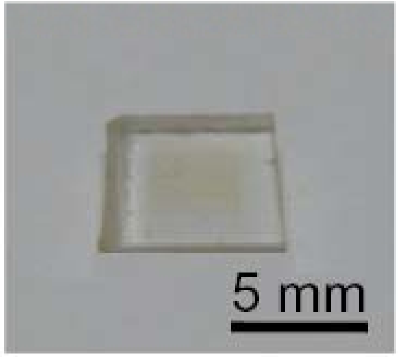
Ag nanoparticles are generated only in the irradiated area due to the **fs-laser induced photoreduction**

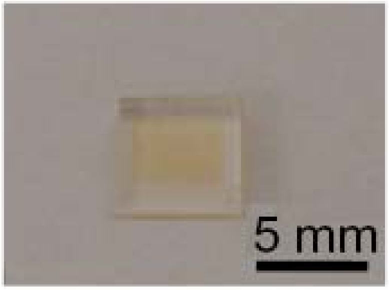
Free electron generation
Photoreduction reaction
$Ag^+ + e^- \rightarrow Ag^0$

Generation of Ag nanoparticles

Silver doped barium borate glass (Ag:BBO)

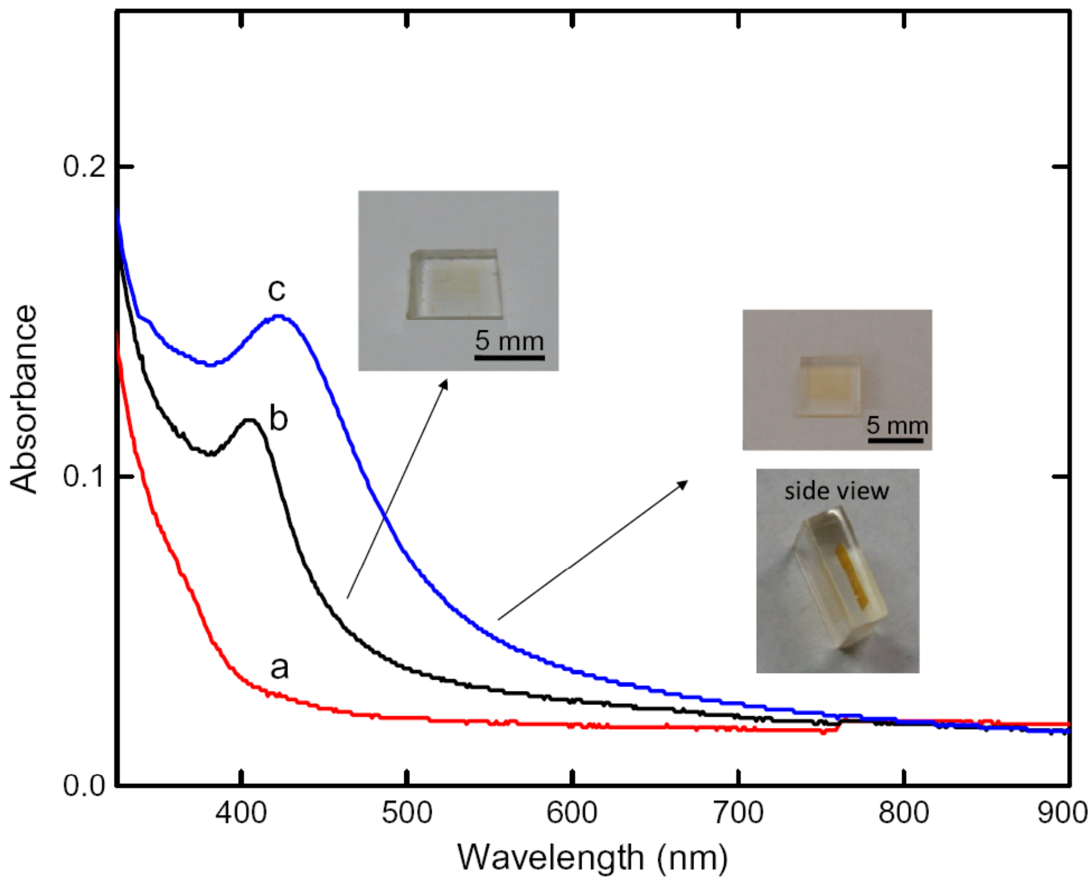
Sample after irradiation with the amplified fs-laser (1 kHz) and subsequent thermal treatment at 400 C for 1 h





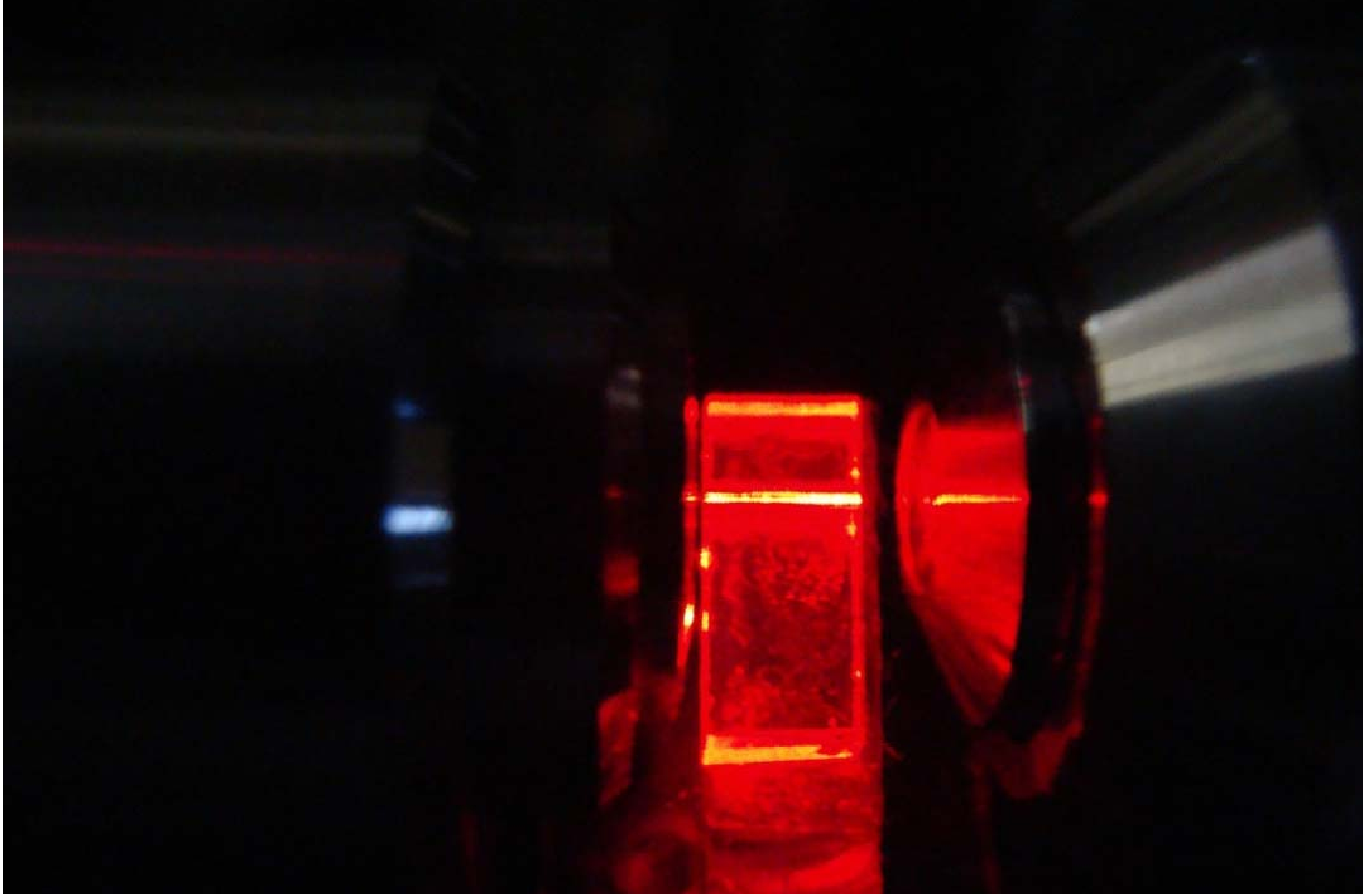
Sample after irradiation with the 5 MHz fs-laser

Generation of Ag nanoparticles



Absorption spectrum of the Ag:BBO sample as prepared (a), after irradiation with the 5 MHz fs-laser (b) and after irradiation with the amplified fs-laser (1 kHz) and subsequent thermal treatment.

fs-laser waveguides fabrication



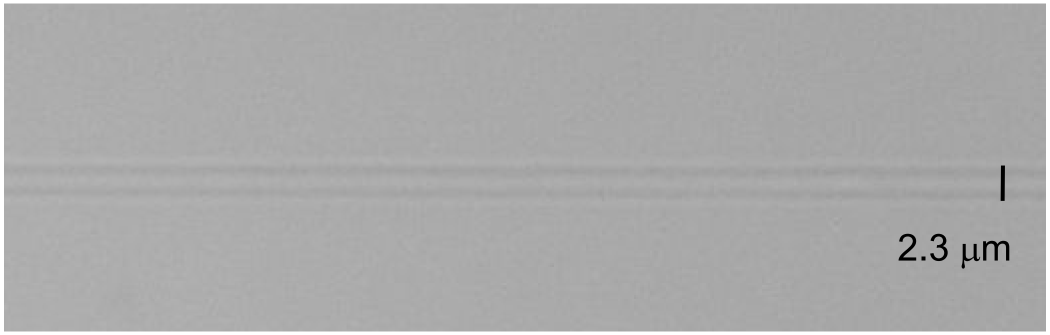
Waveguides fabrication

Sample:

Ag:P7W3

Tungsten lead pyrophosphate glass - ($70Pb_2P_2O_7$-$30WO_3$):1AgCl (%mol)

Waveguides fabricated using the 5-MHz laser system (50 fs) with 37 nJ/pulse and v = 10 μm/s

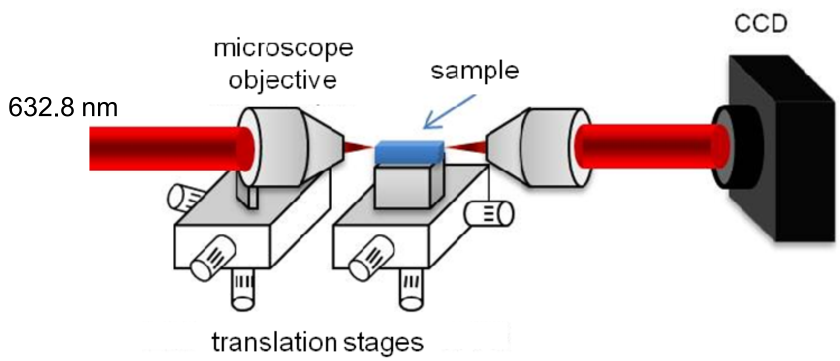


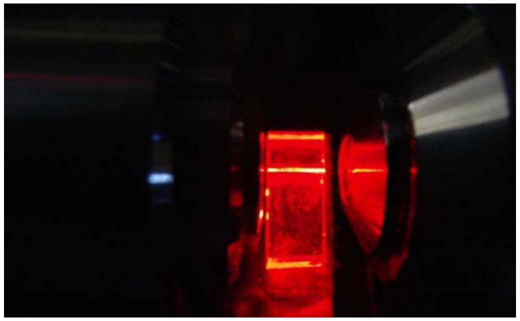
Top view

Cross-section view

Waveguides fabrication

Coupling light into the waveguides





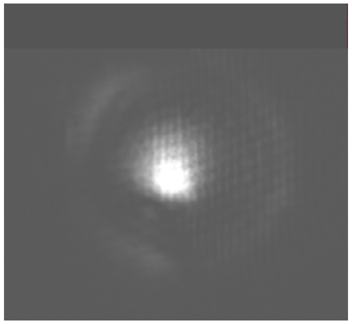
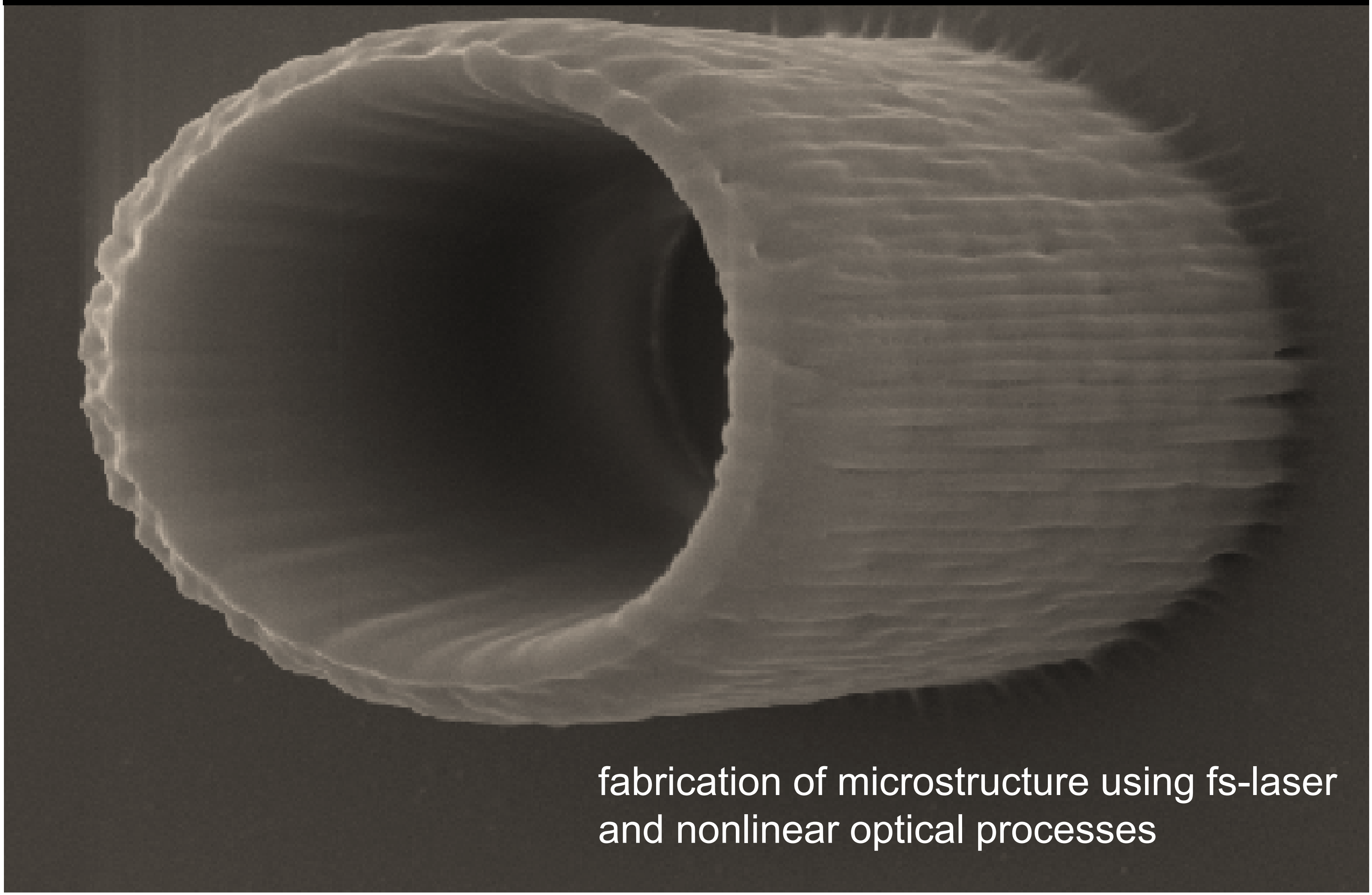


image of the waveguide output

measured waveguide loss L = 1.3 dB/mm

fs-laser microfabrication



Two-photon polymerization

Photopolymerization

Monomer + Photoinitiator $\rightarrow$ *Polymer*

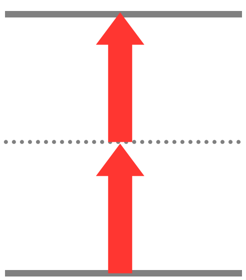
light

Two-photon polymerization

Monomer + Photoinitiator → Polymer

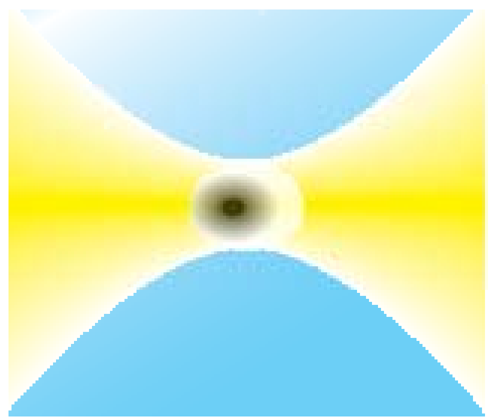
Photoinitiator is excited by ***two-photon absorption***

$$R_{2PA} \propto I^2$$

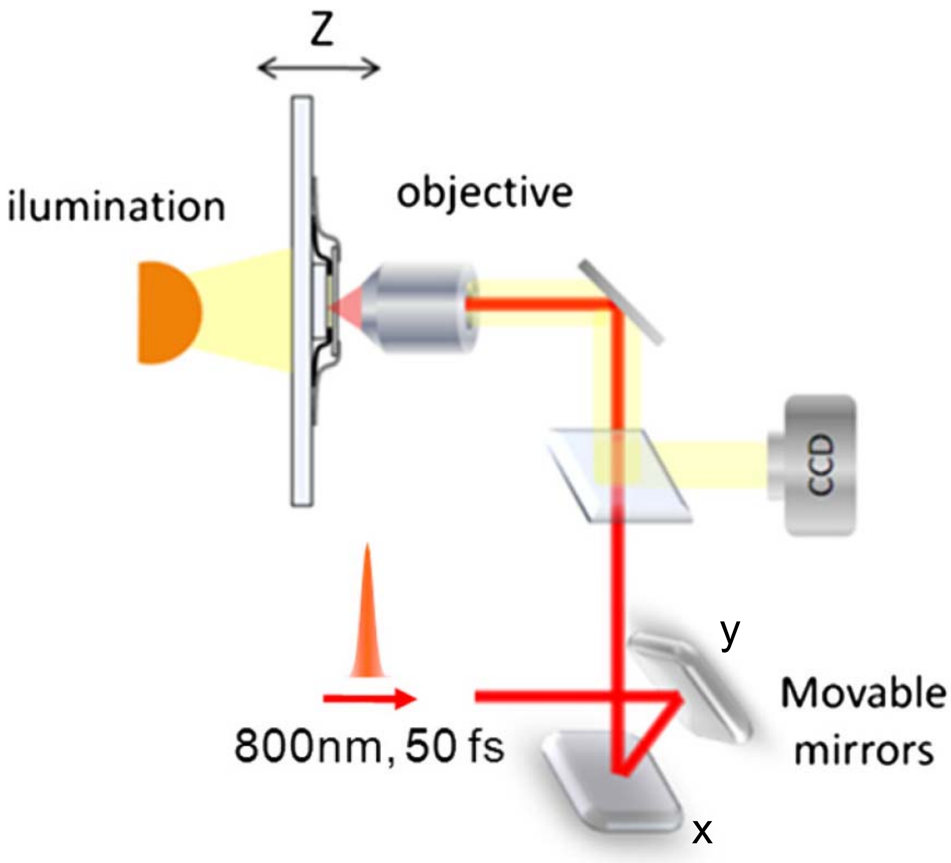


The polymerization is confined to the focal volume.

High spatial resolution



Two-photon polymerization setup



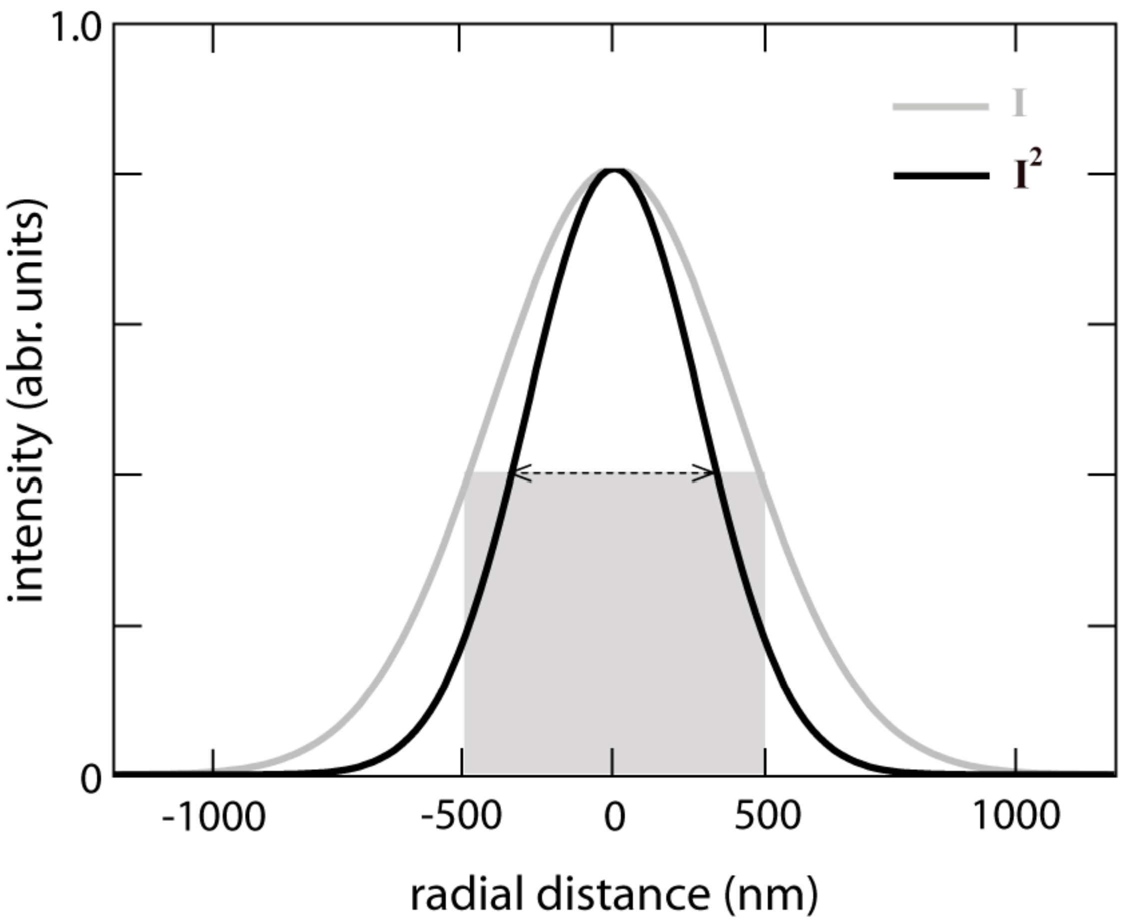
Ti:sapphire laser oscillator

- 50 fs
- 800 nm
- 80 MHz
- 20 mW

Objective

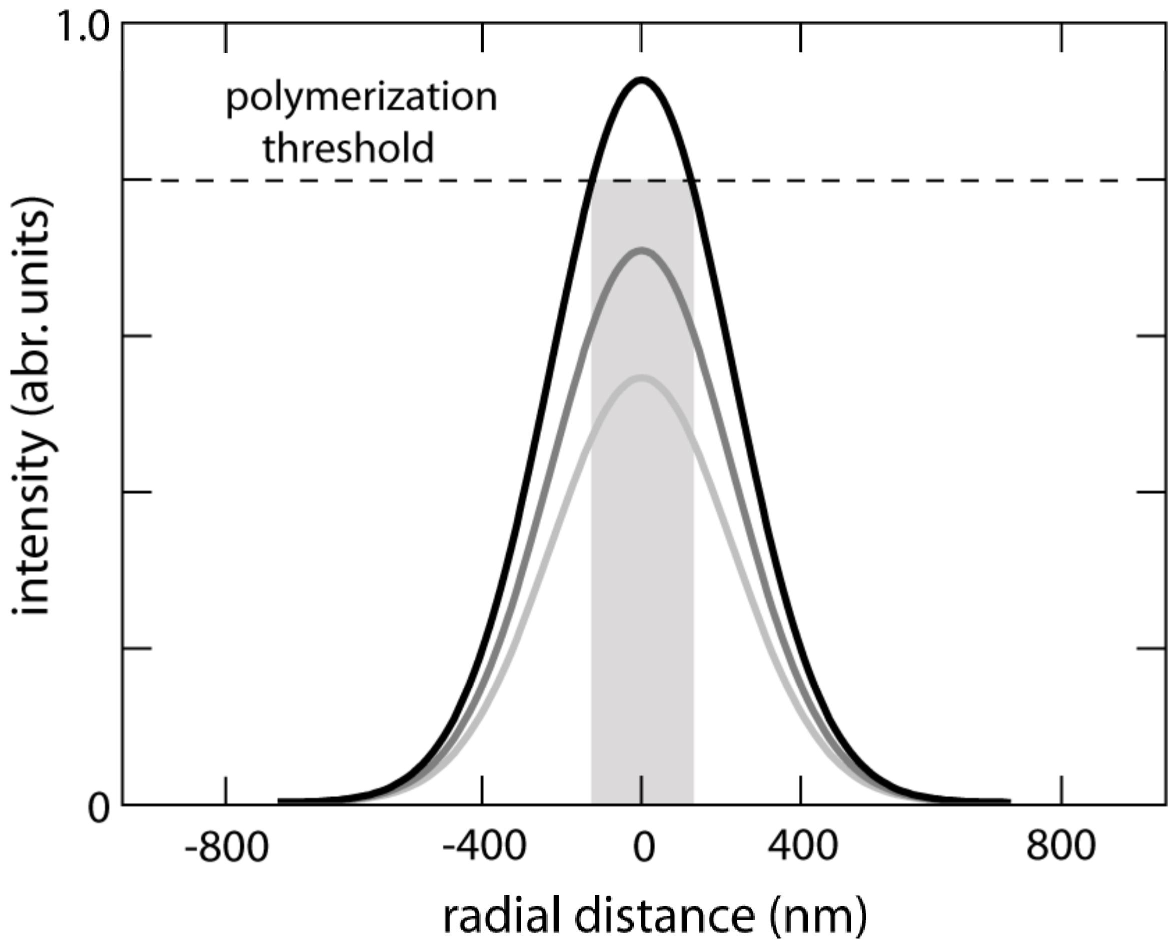
40 x
0.65 NA

Two-photon polymerization



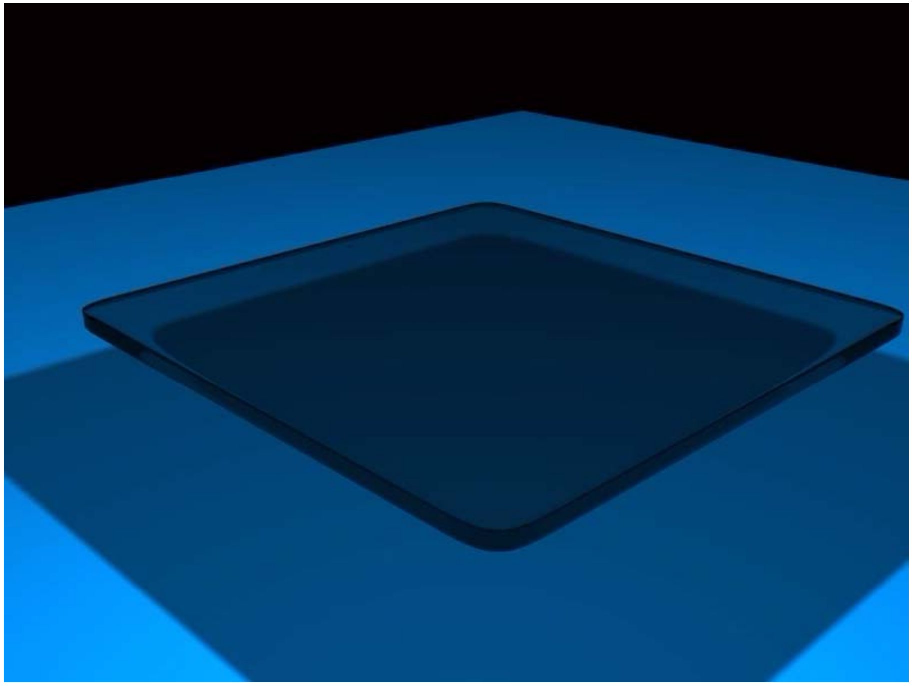
bellow the diffraction limit

Two-photon polymerization

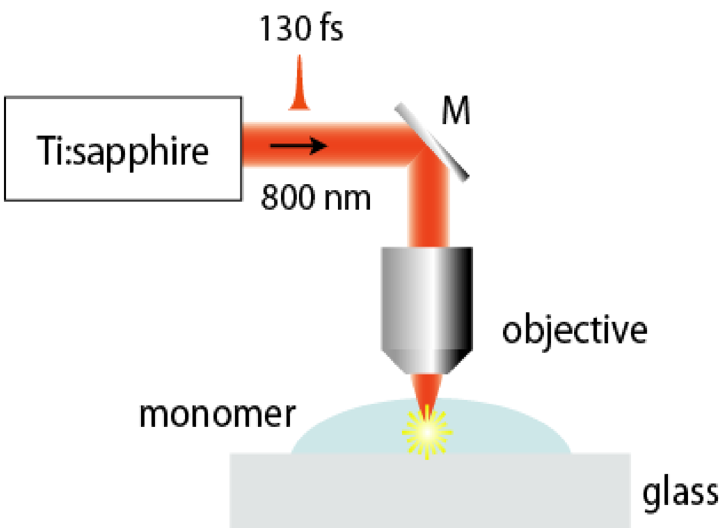


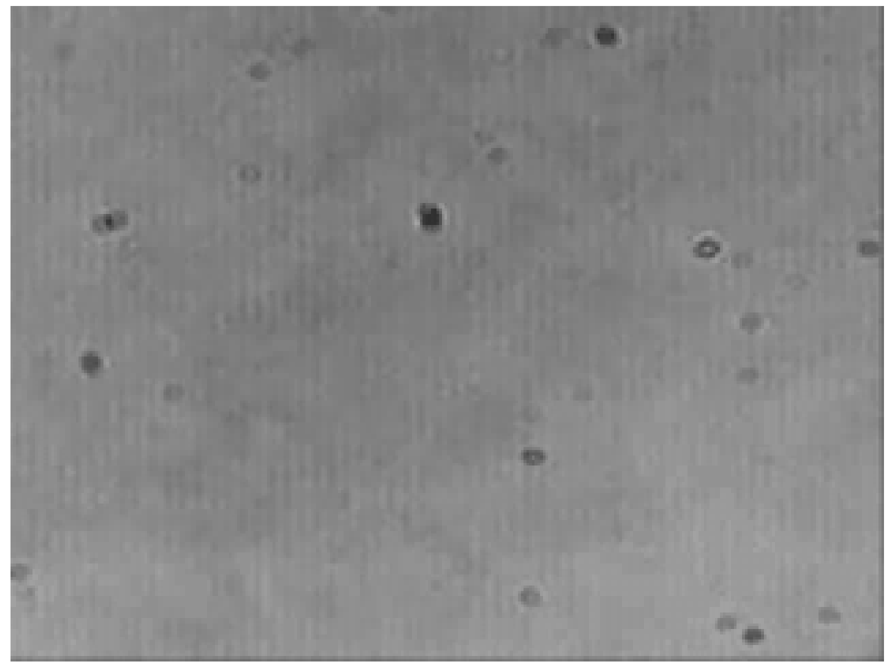
even higher spatial resolution

Two-photon polymerization

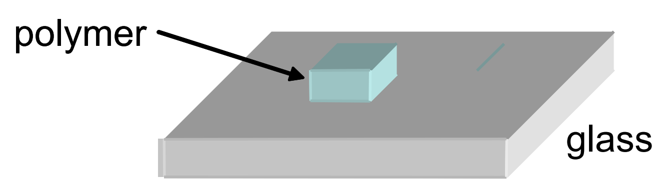


Two-photon polymerization

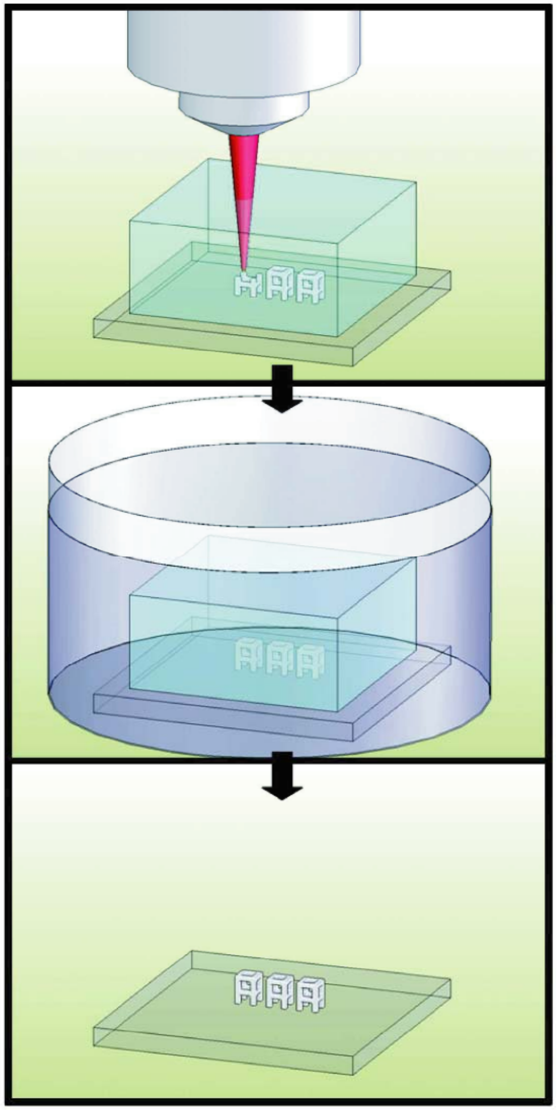




30 µm x 30 µm x 12 µm cube



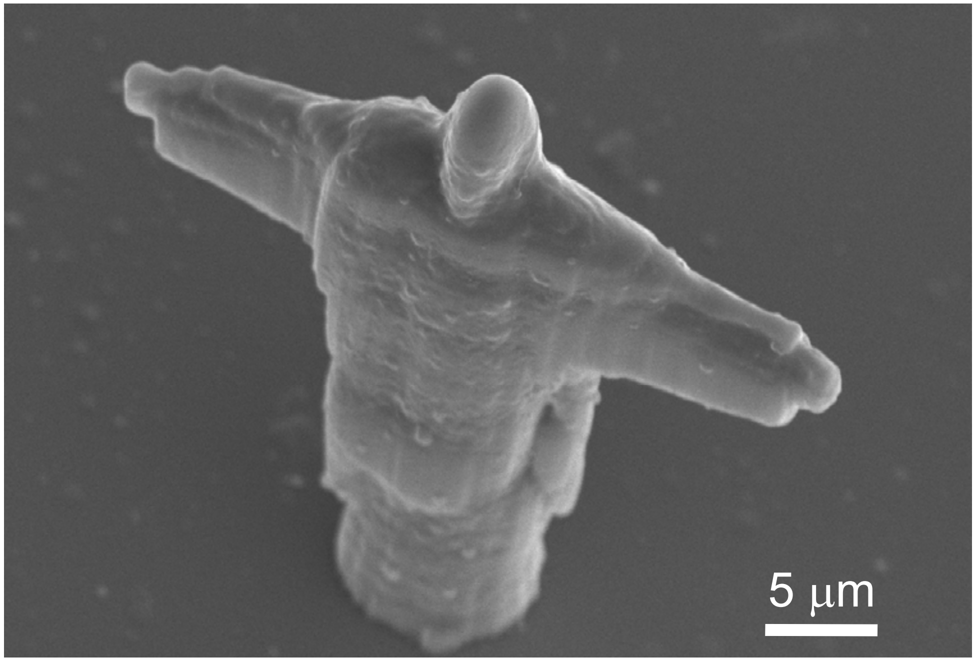
Two-photon polymerization



After the fabrication, the sample is immersed in ethanol to wash away any unsolidified resin and then dried

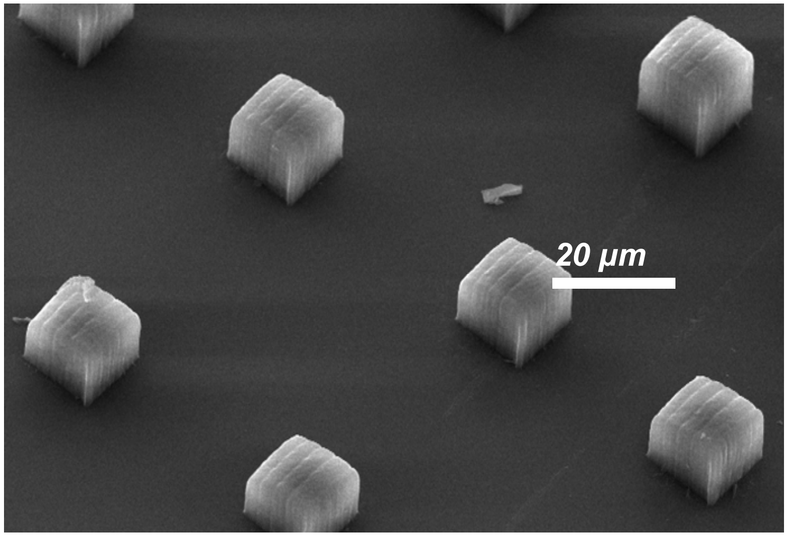
two-photon polymerization

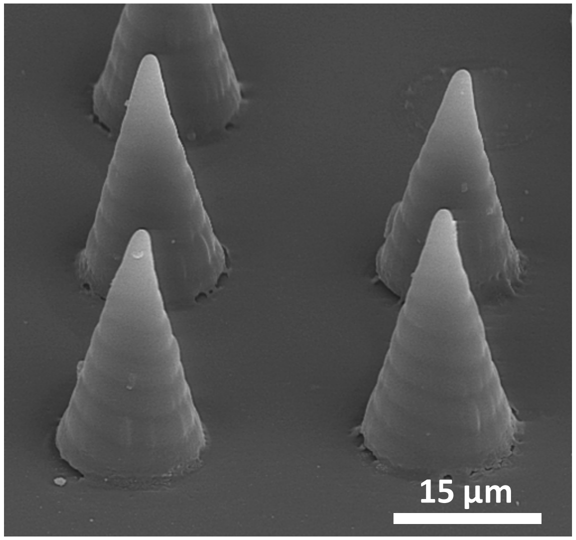
Microstructure fabricated by two-photon polymerization

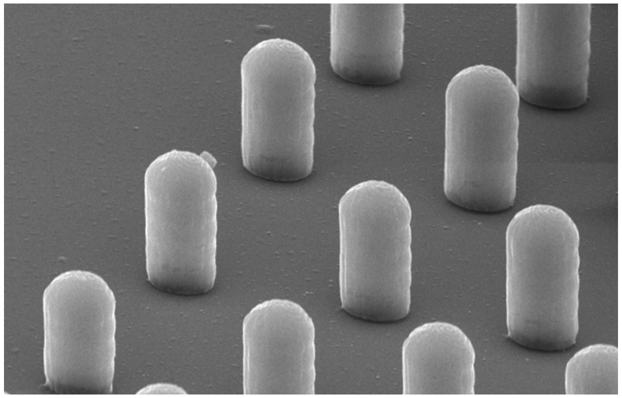


Two-photon polymerization

Microstructures fabricated by two-photon polymerization

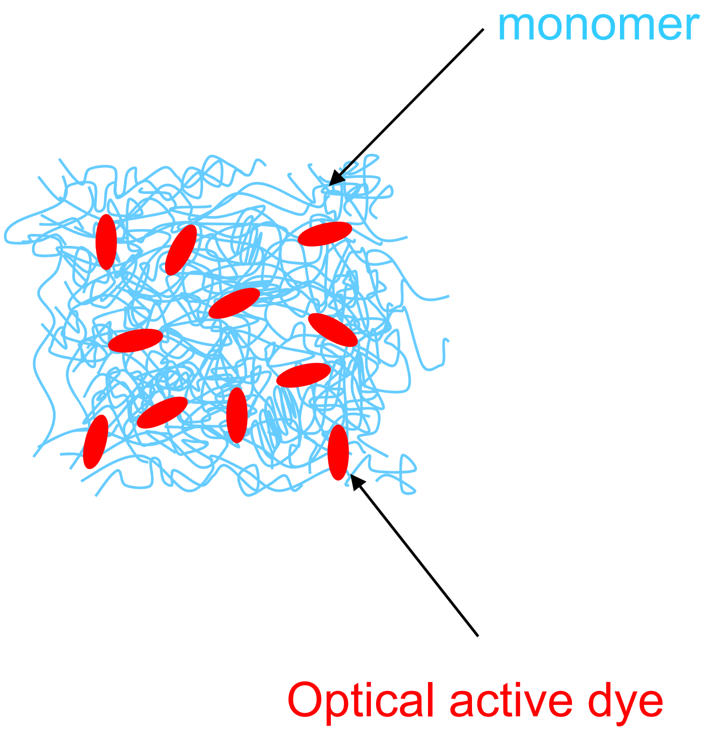


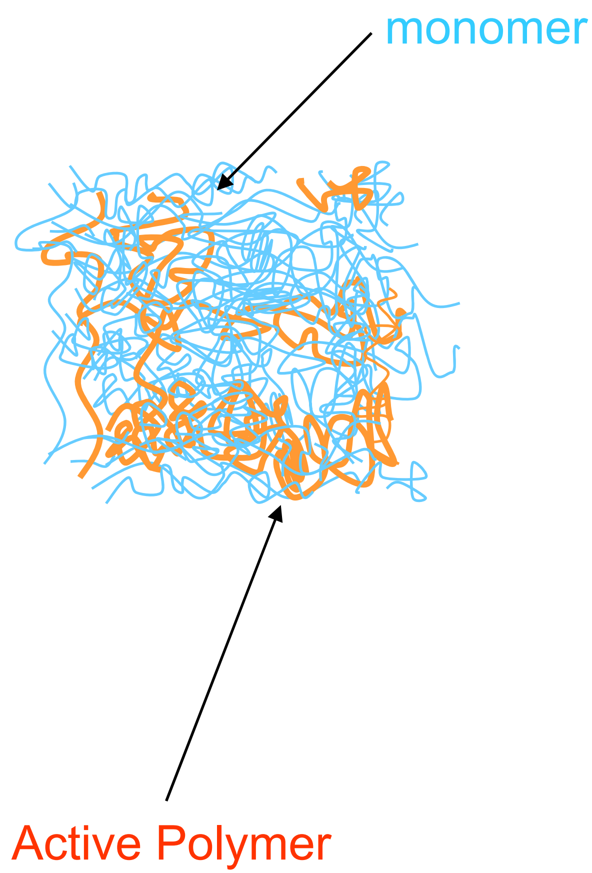




Doping microstructures

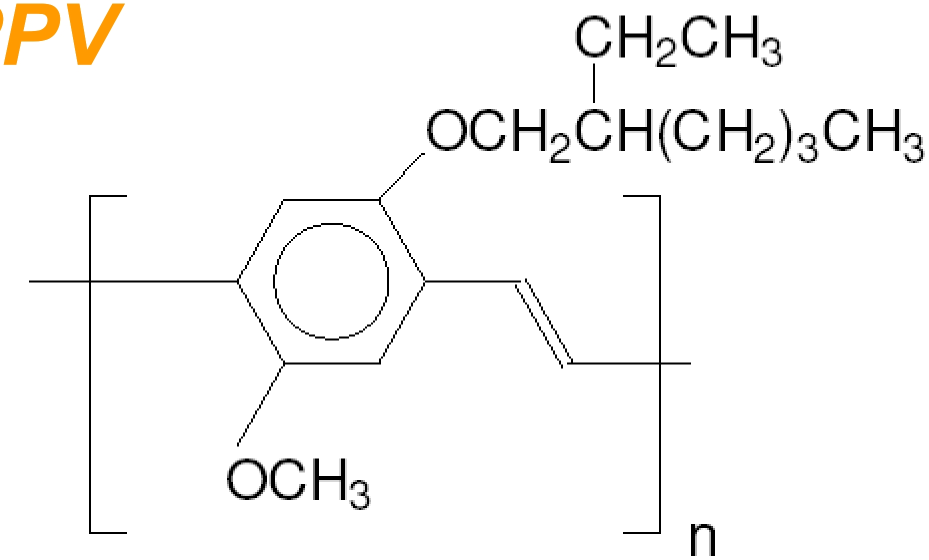
Microstructures containing active compounds





Microstructure containing MEH-PPV

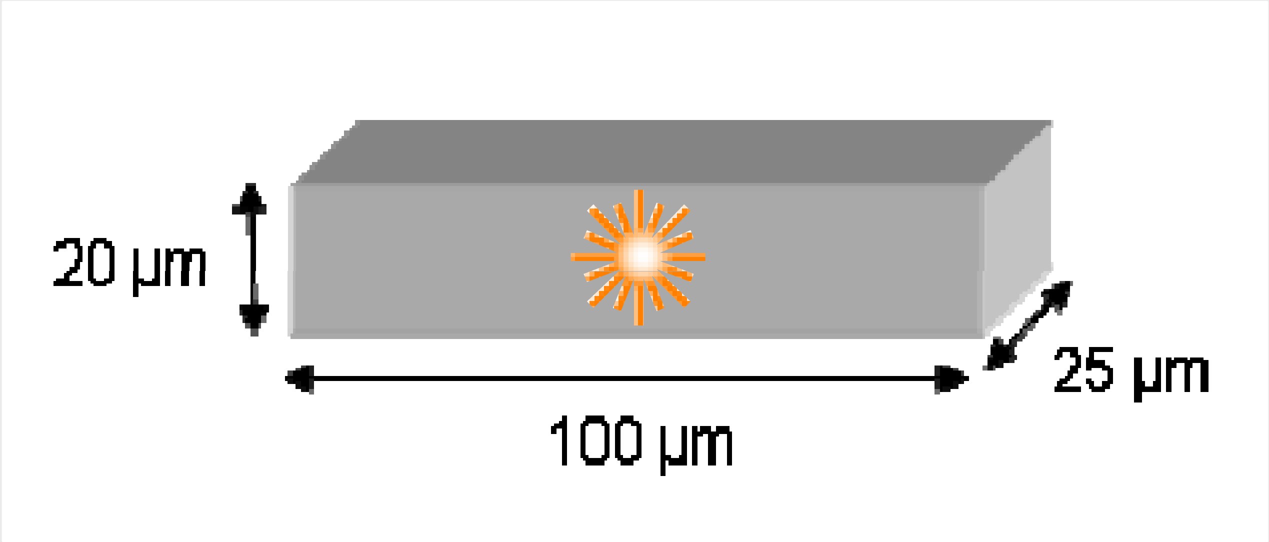
MEH-PPV



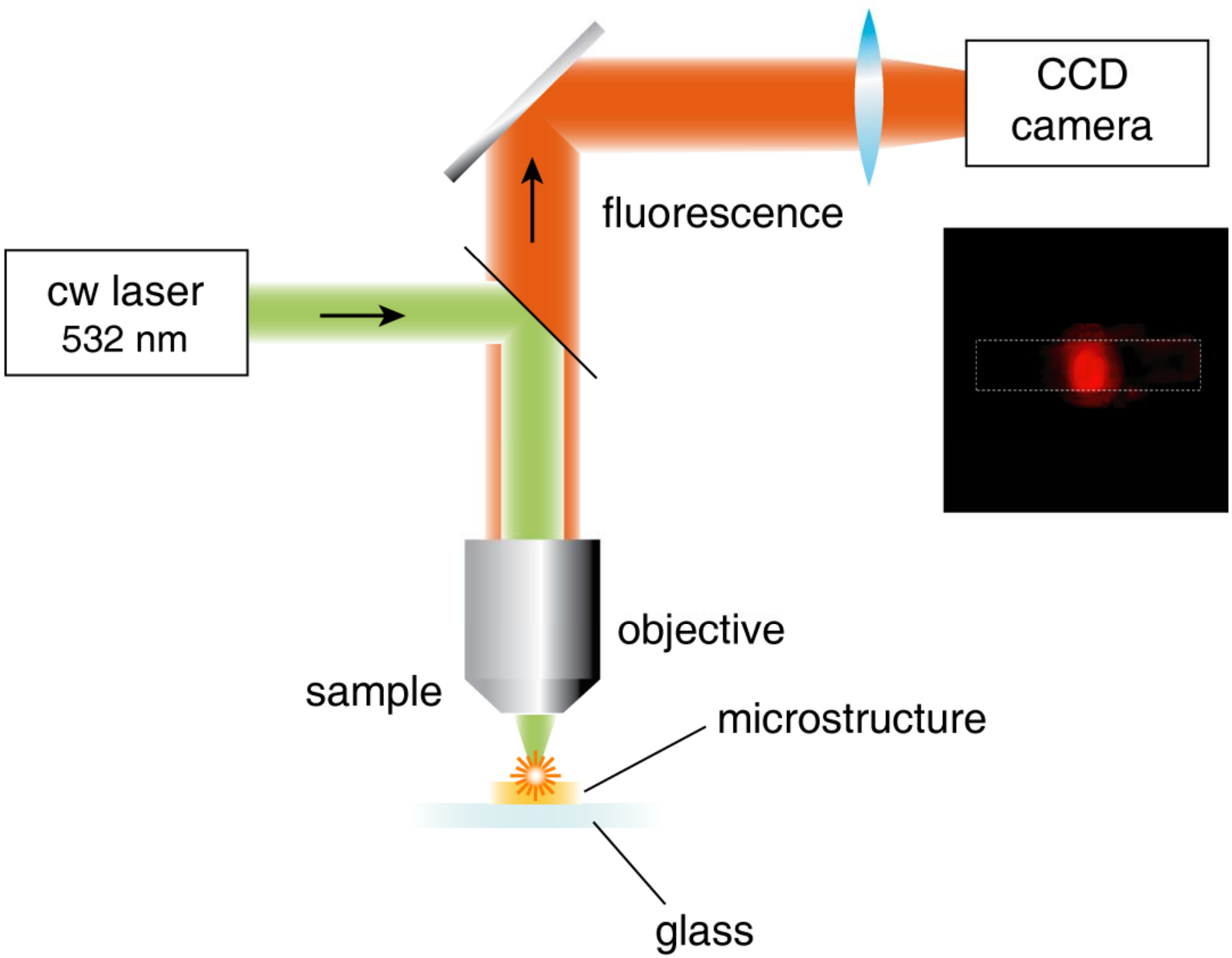
- Fluorescence
- Electro Luminescent
- Conductive

Microstructure containing MEH-PPV

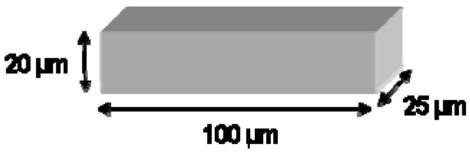
Do we have waveguiding in the microstructure ?

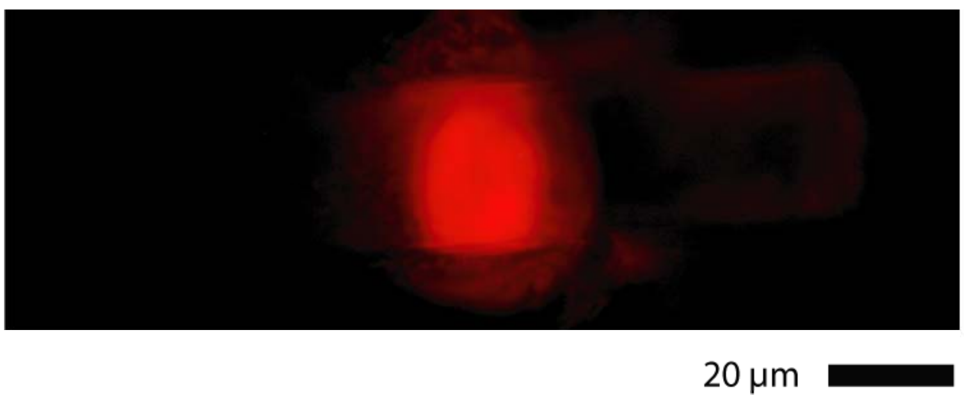


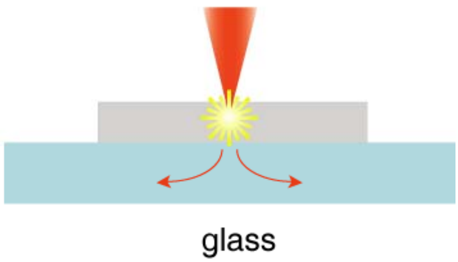
Microstructure containing MEH-PPV



Microstructure containing MEH-PPV

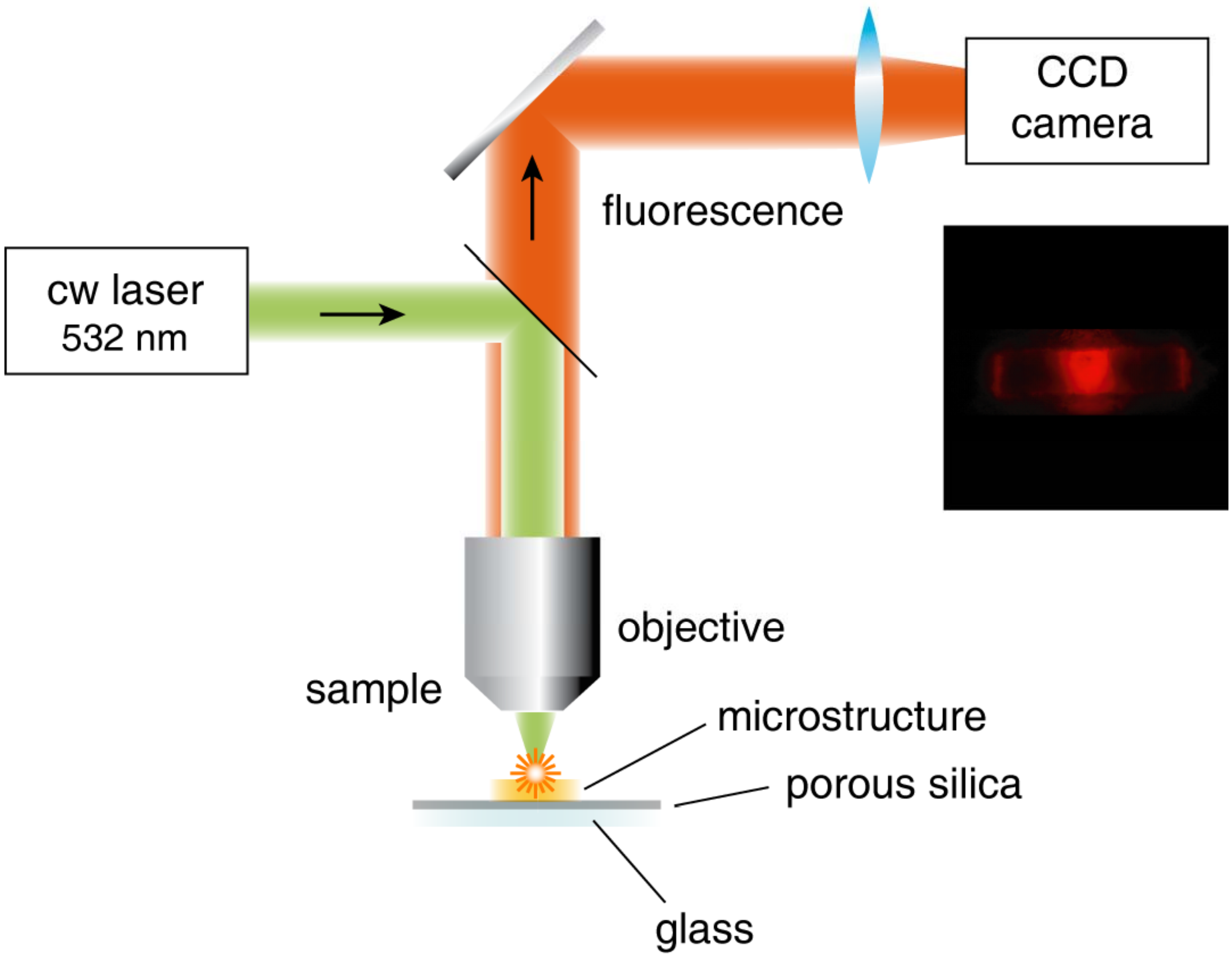




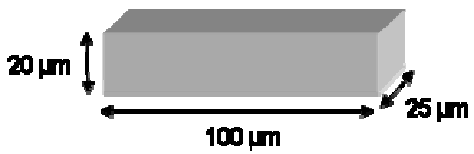


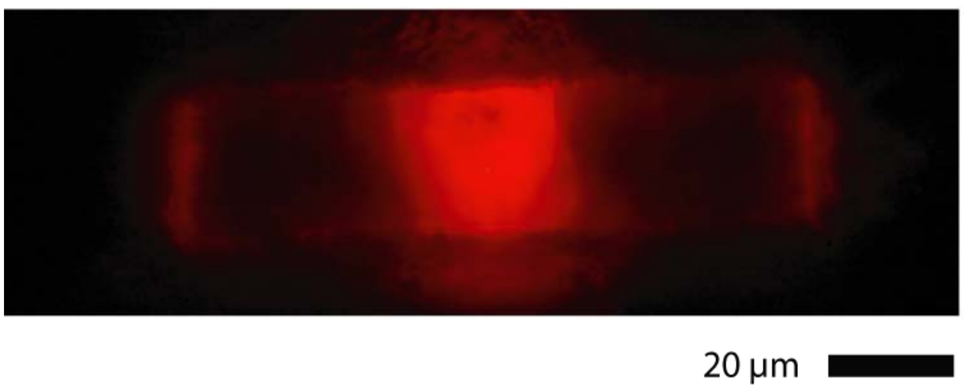
Appl. Phys. Lett., 95 1133091-3 (2009)

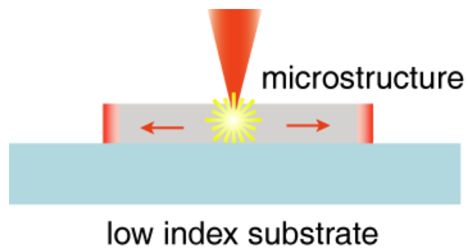
Microstructure containing MEH-PPV



Microstructure containing MEH-PPV



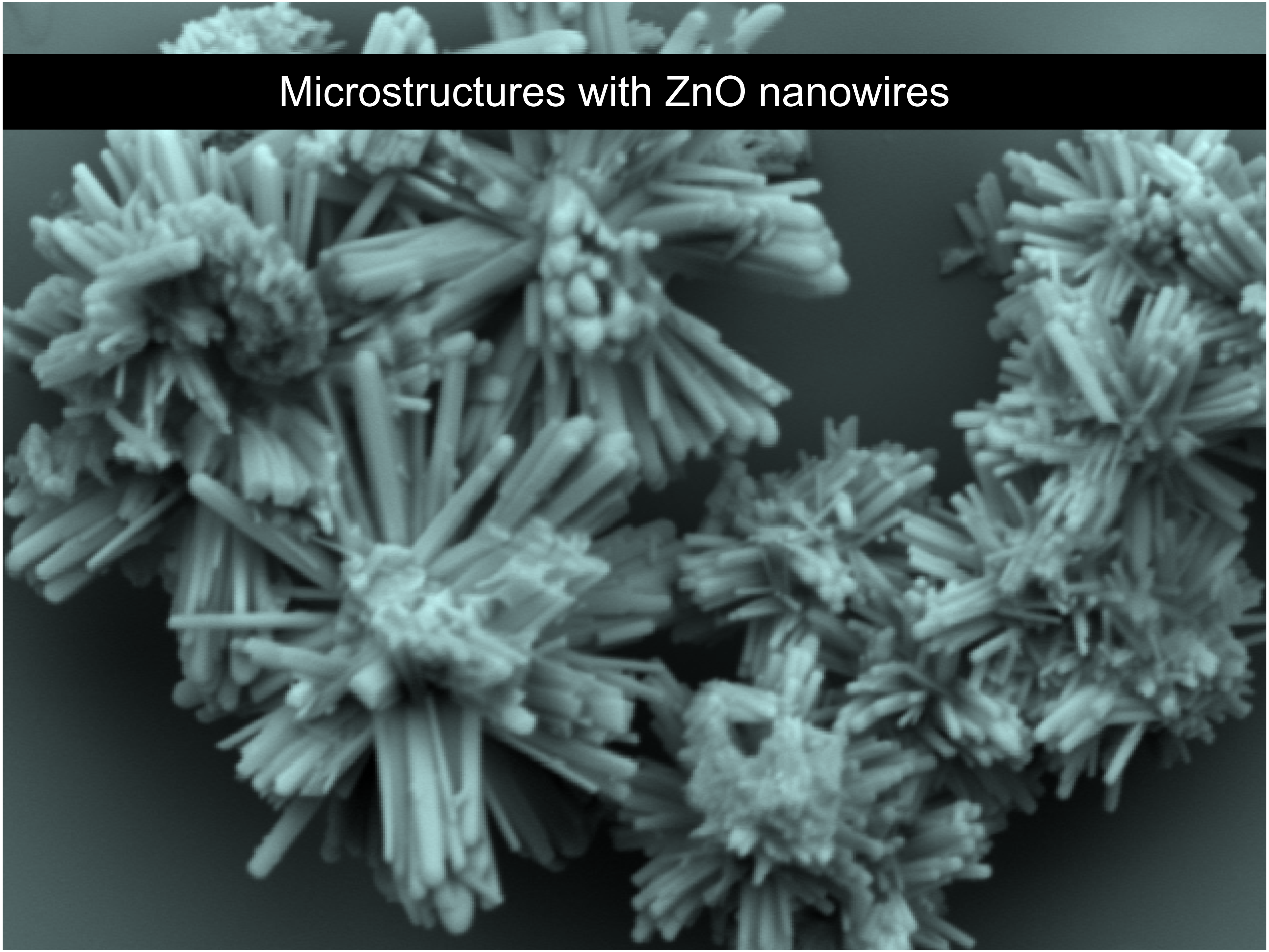




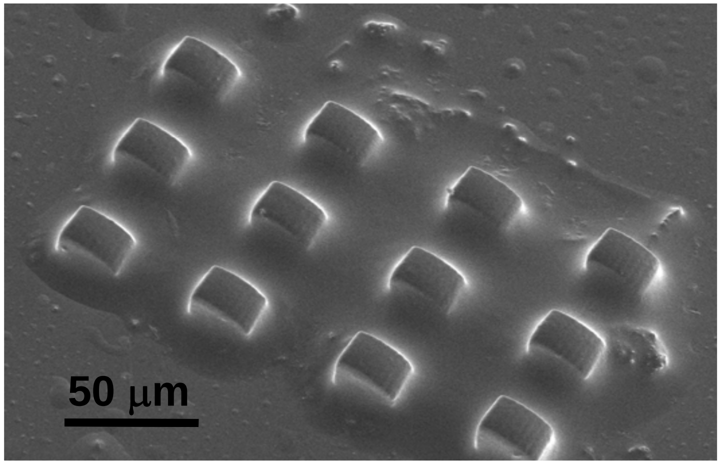
waveguiding of the microstructure fabricated on porous silica substrate (*n*= 1.185)

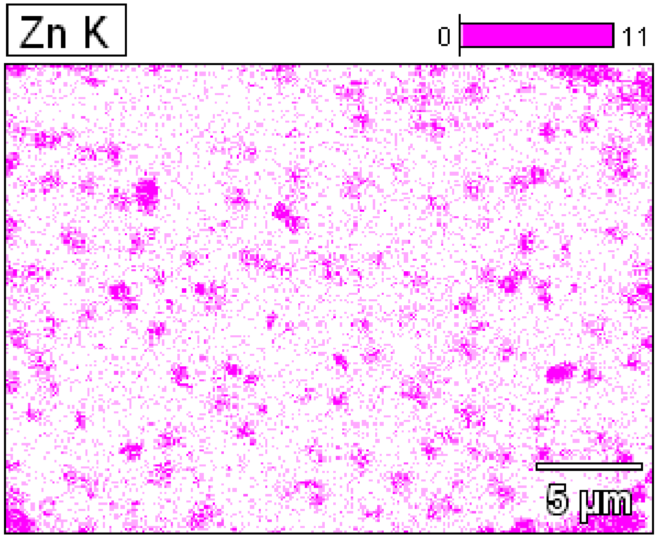
Applications: micro-laser; fluorescent microstructures; conductive microstructures

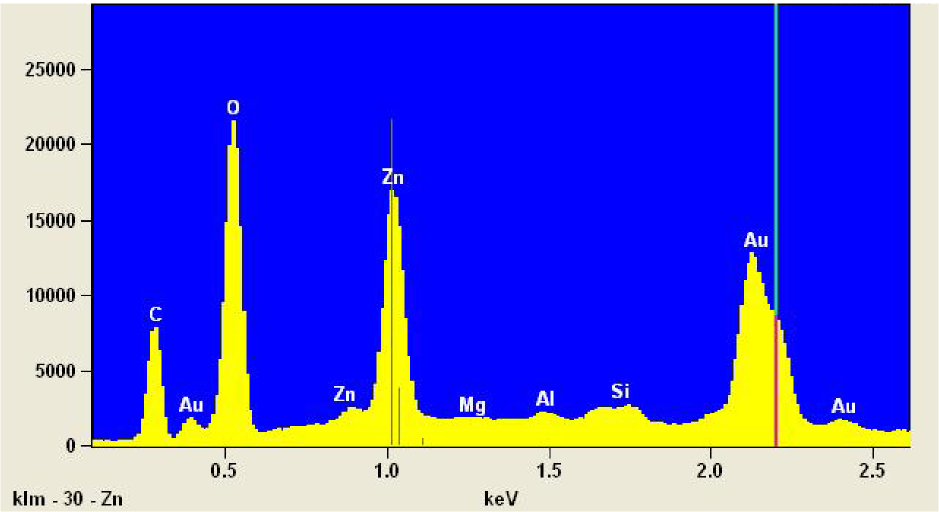
Microstructures with ZnO nanowires



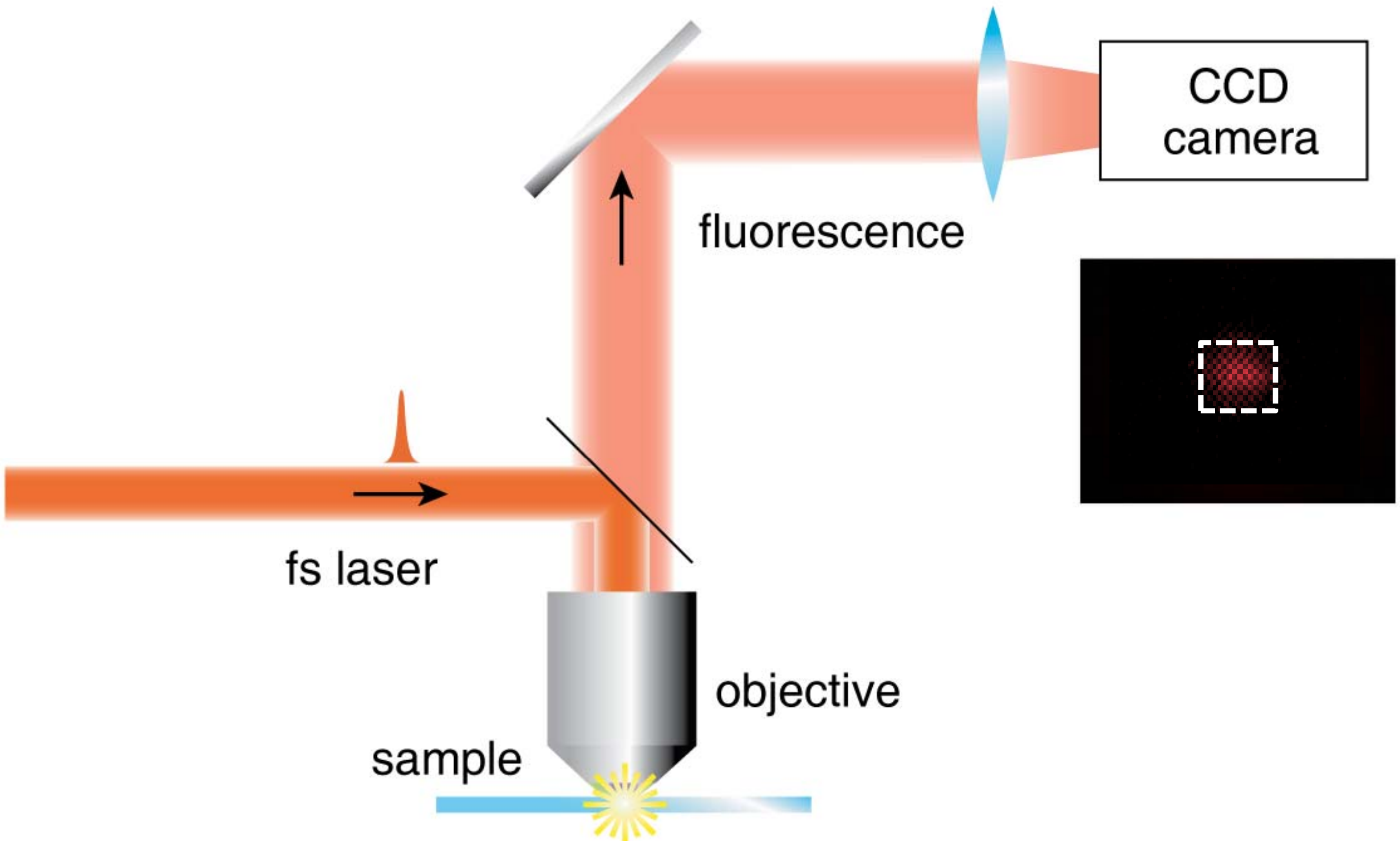
Microstructures with ZnO nanowires



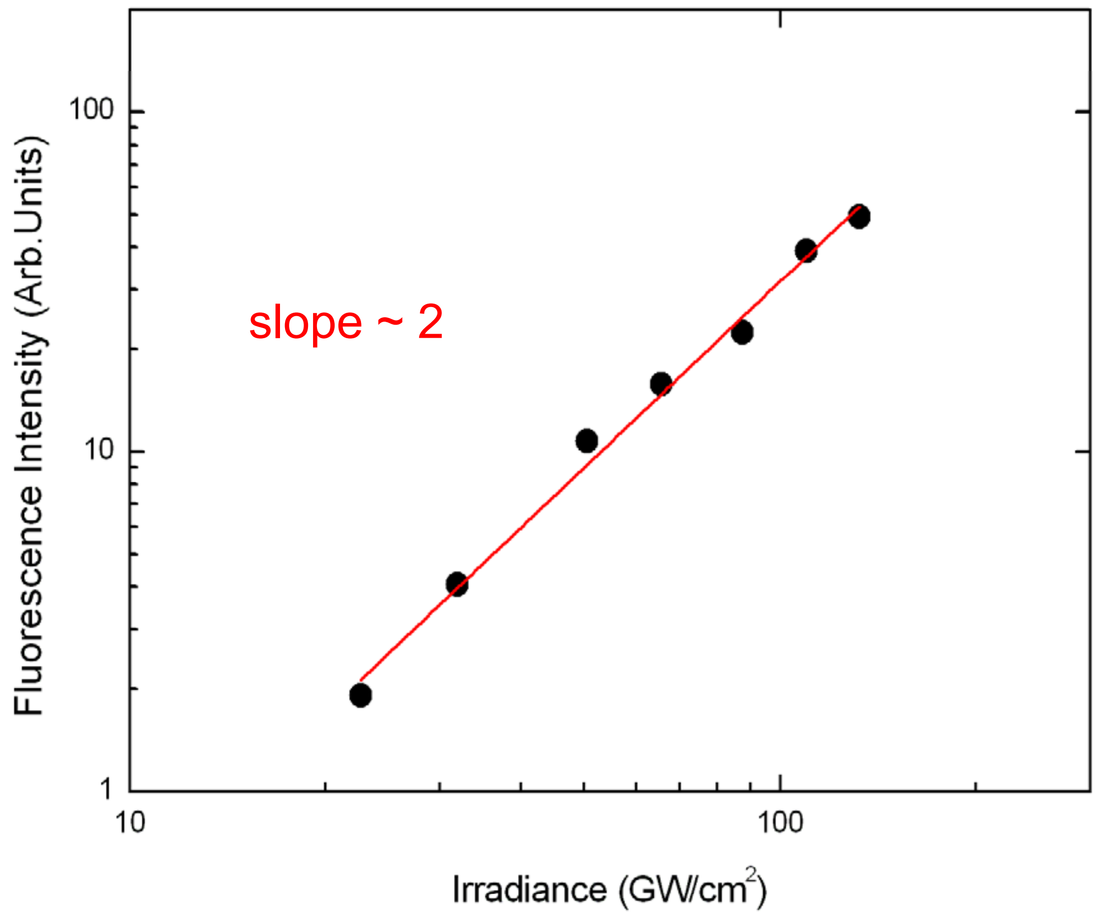




Microstructures with ZnO nanowires

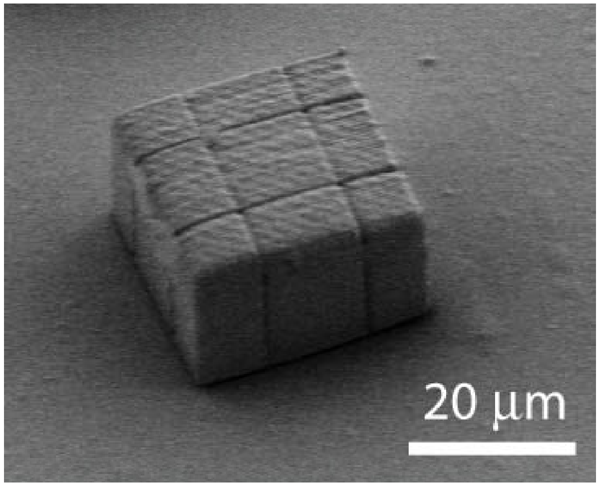


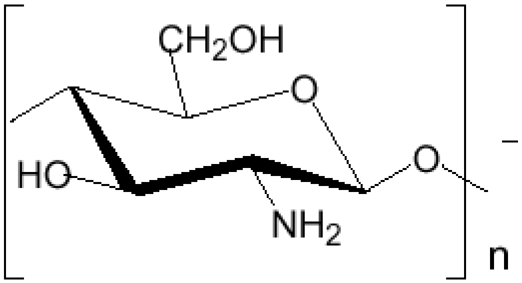
Microstructures with ZnO nanowires

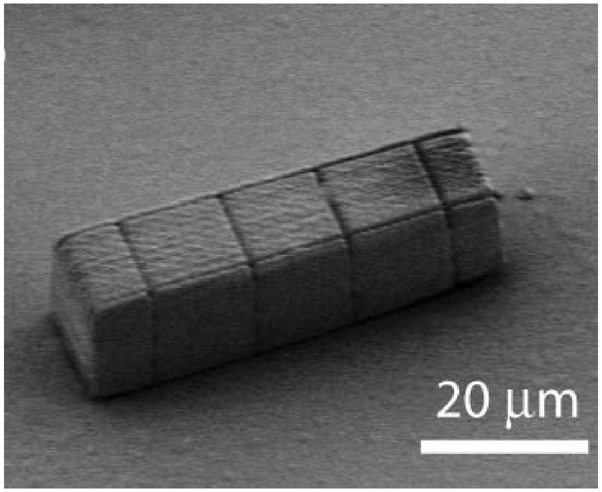


Doping microstructures

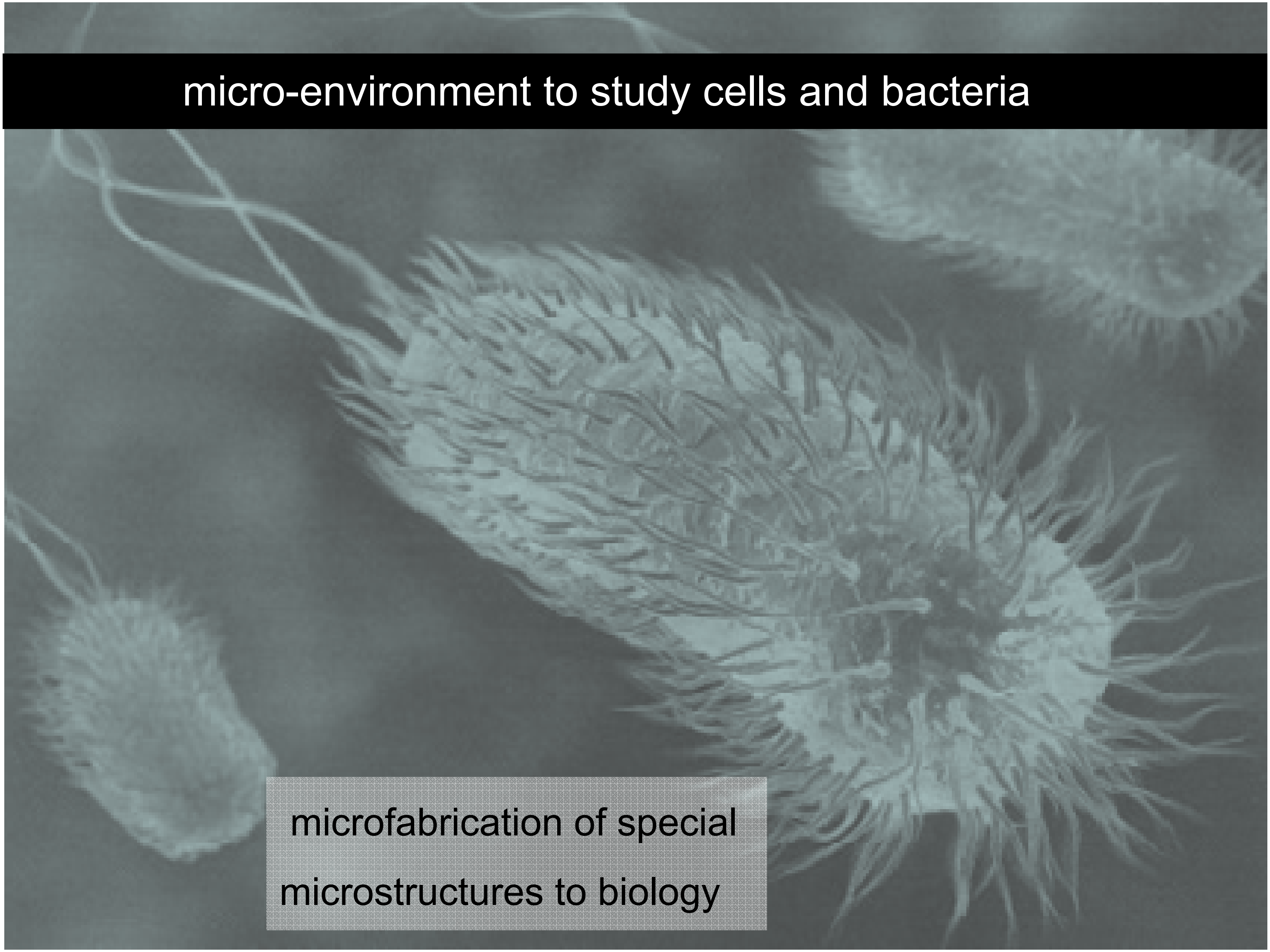
- microstructures containing biopolymer - chitosan







micro-environment to study cells and bacteria

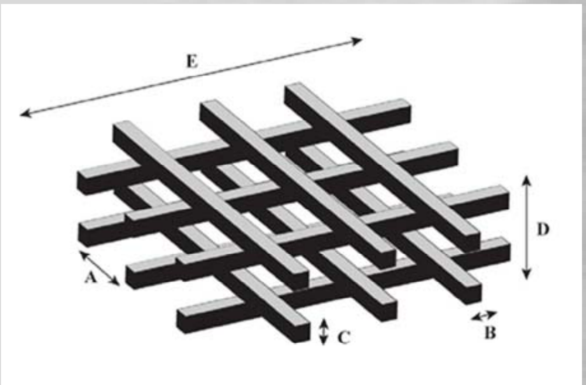


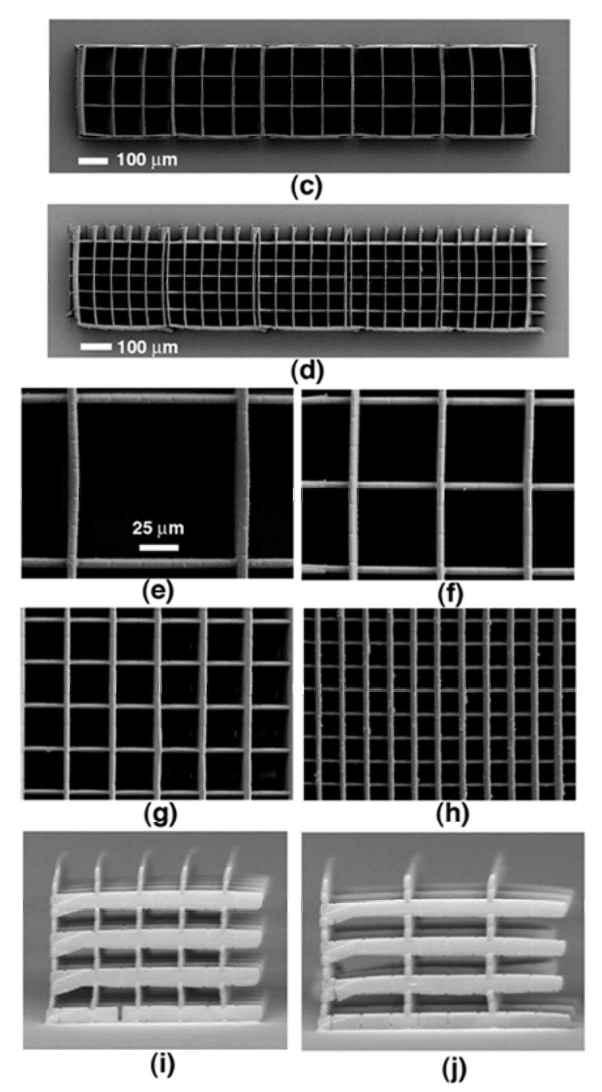
microfabrication of special microstructures to biology

3D cell migration

- 3D cell migration studies in micro-scaffolds

SEM of the scaffolds





110 µm pore size

52 µm pore size

Top view

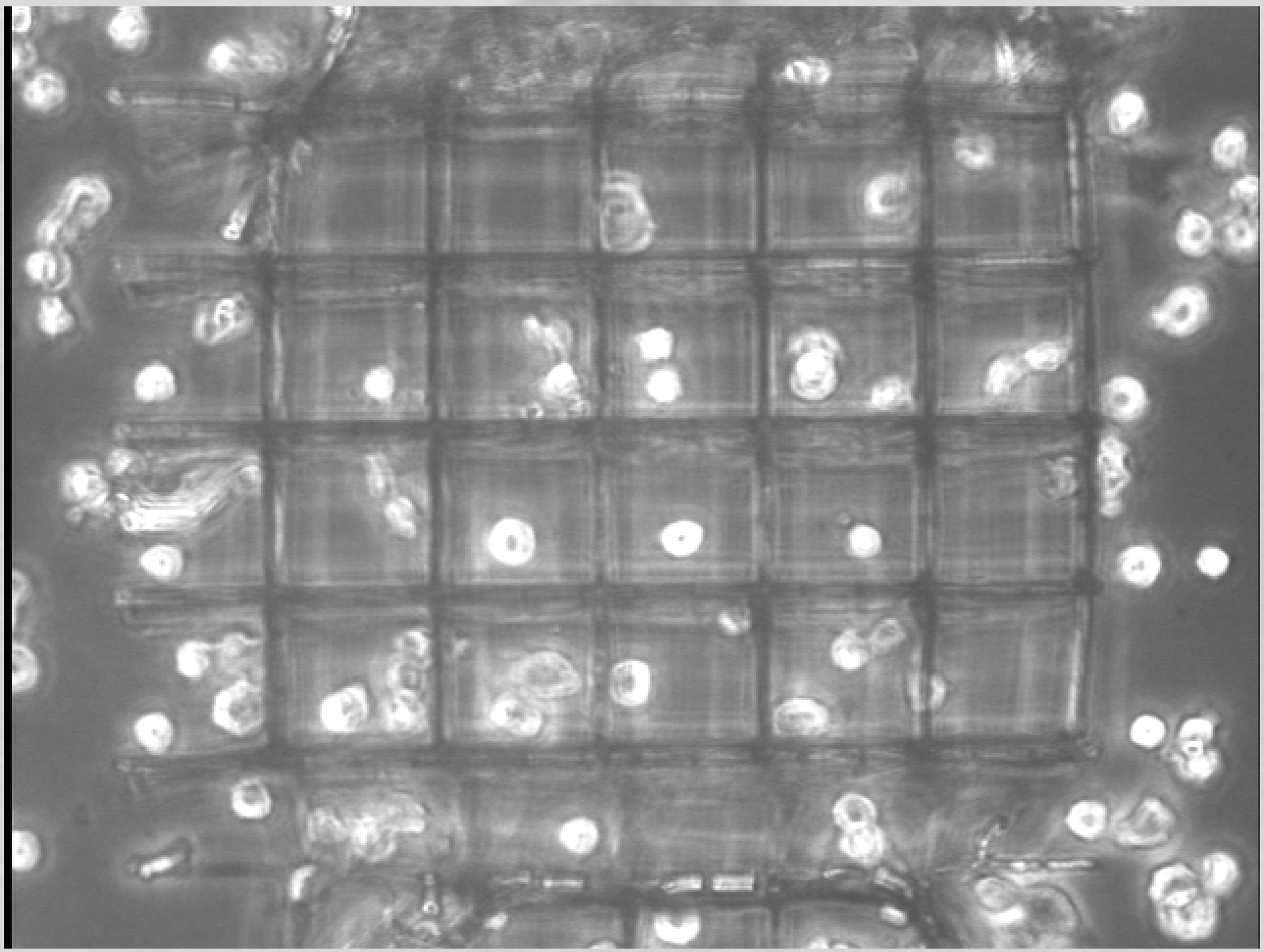
110, 52, 25, 12 µm pore size

Side view

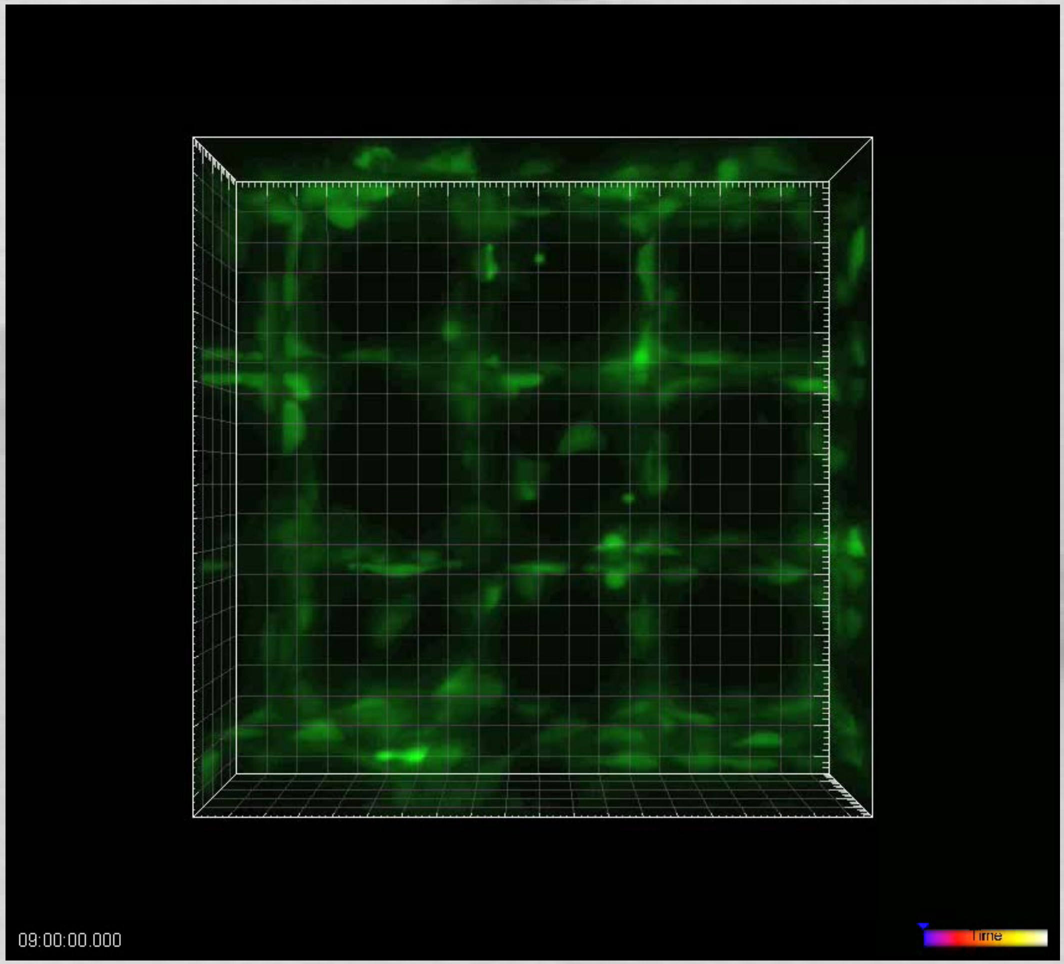
25, 52 µm pore size

3D cell migration

50 μm pore size

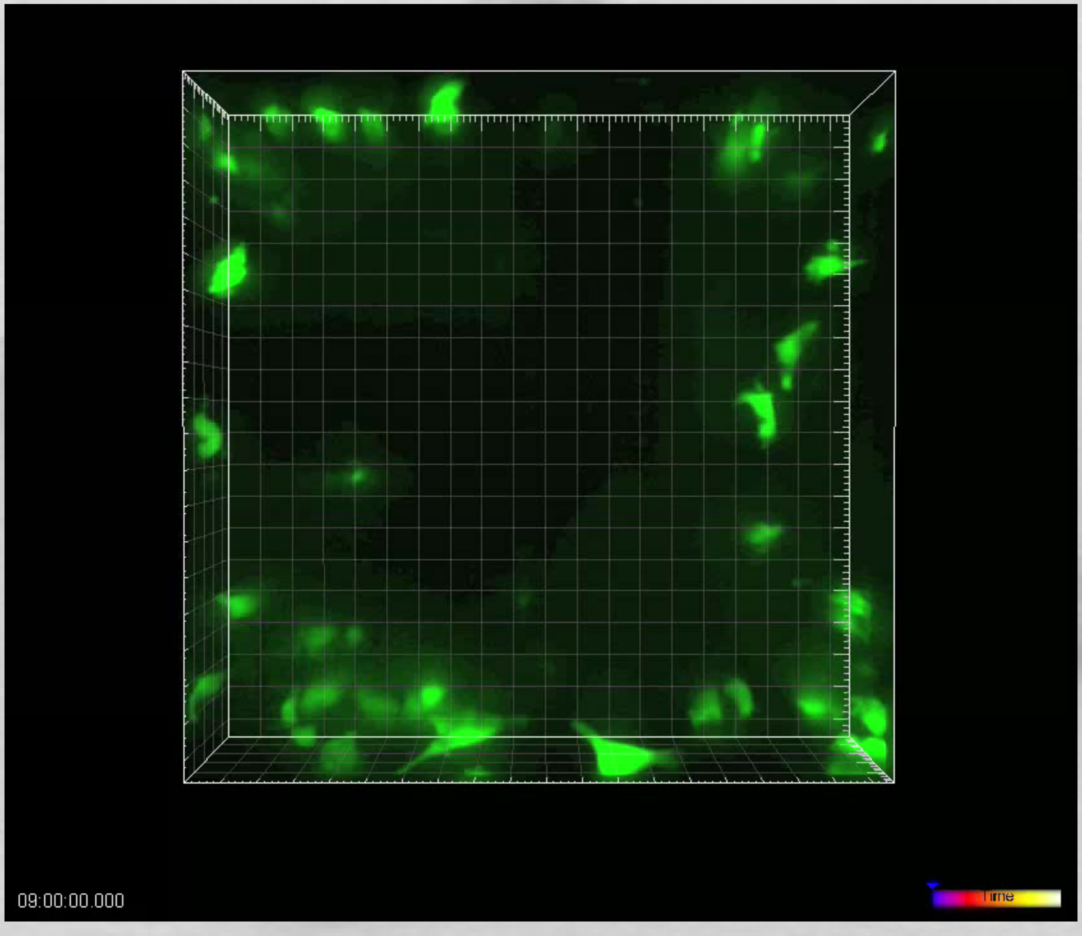


3D cell migration



110 μm pore size

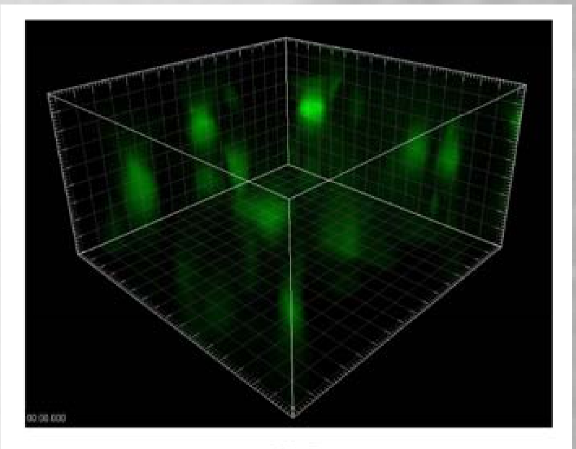
3D cell migration

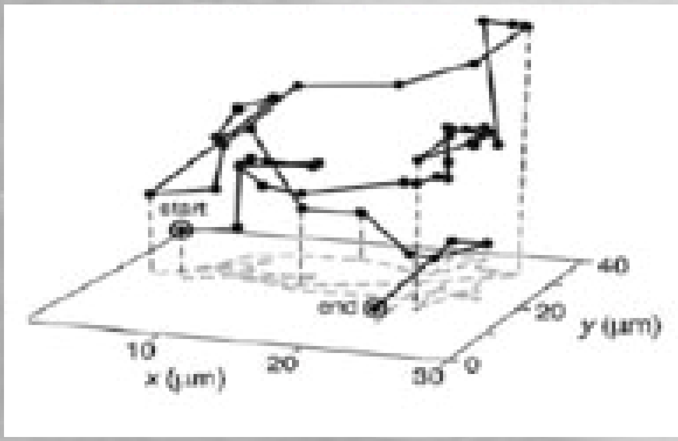


12 μm pore size

3D cell migration

- 3D cell migration studies in micro-scaffolds



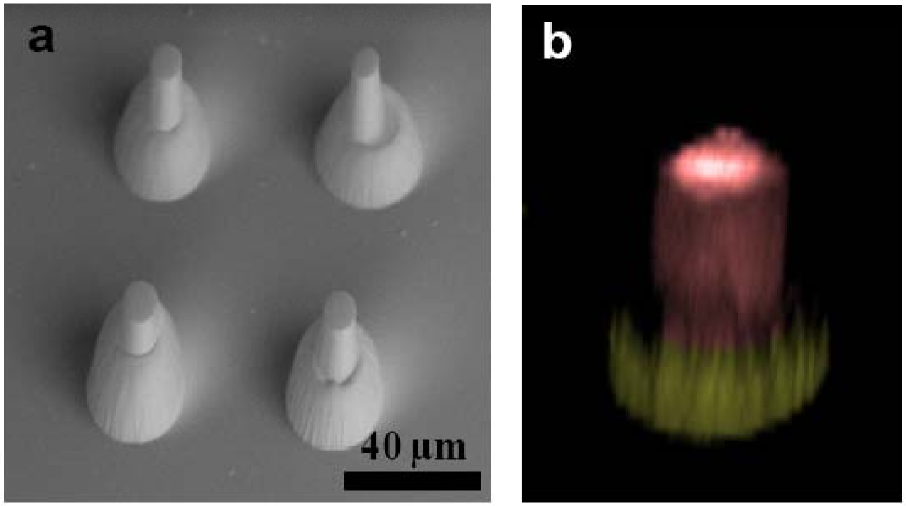


Advanced Materials, 20, 4494-4498 (2008)

Guiding bacterial growth in a micro-environment

to study bacterial growth it was needed to develop
double doped microstructures

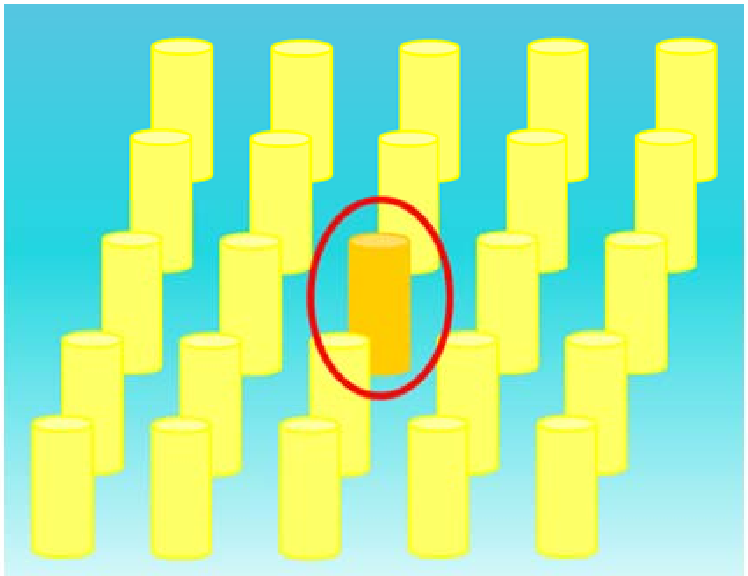
microstructure containing Fluorescein and Rhodamine

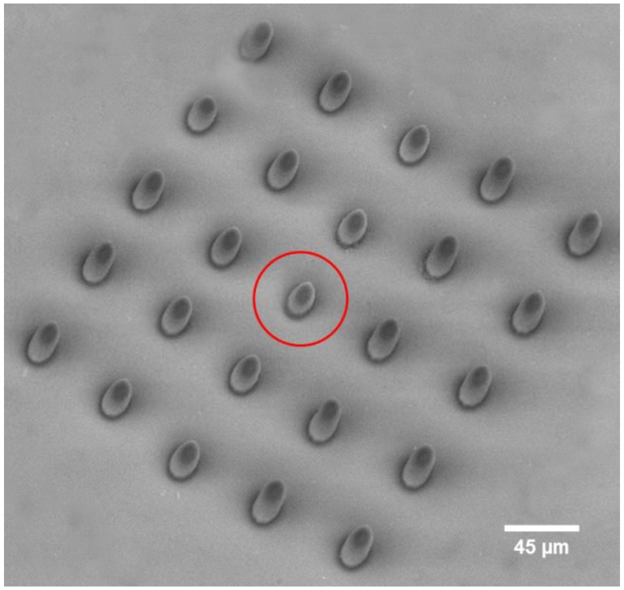


(a) SEM of a double-doped microstructure (top view).
(b) Confocal fluorescent microscopy image of the same microstructure.

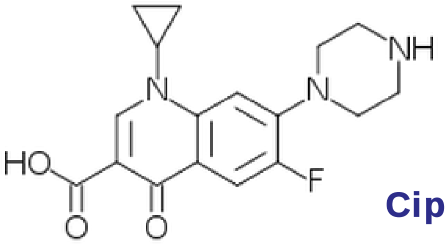
Guiding bacterial growth in a micro-environment

Study the development of E. coli in micro-environments:





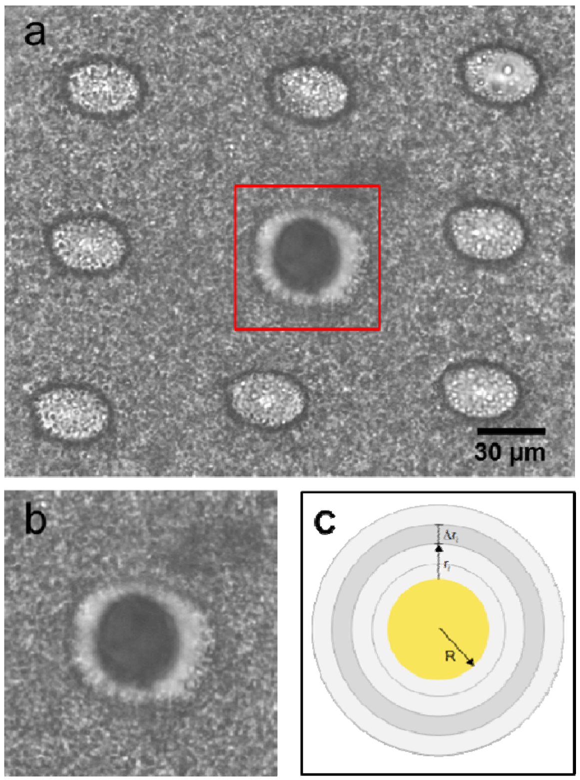
micro-environment in which the central structure contains antibiotic.



Ciprofloxacin

Guiding bacterial growth in a micro-environment

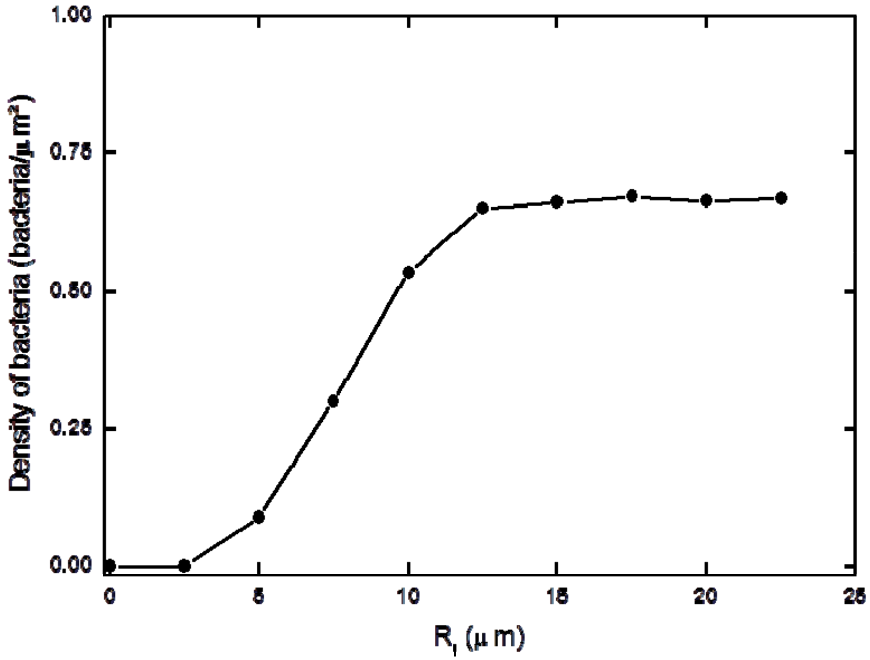
Study the development of E. coli in micro-environments:



after 3 hours, we observed that a small region around the doped structure does not show bacterial growth.

such inhibition zone was analyzed by determining the bacterial density in concentric rings

Guiding bacterial growth in a micro-environment



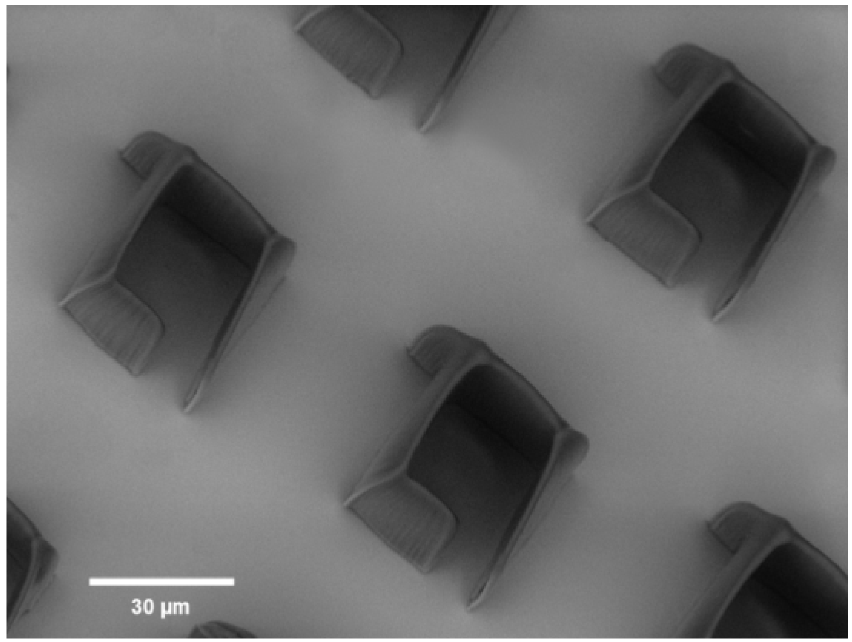
the density of bacteria grows monotonically with r_i

saturating when r_i reaches approximately 12 μm in about 0.7 bacteria/μm^2

the inhibition zone has a maximum range of approximately 10 μm, being more effective as one gets closer to the microstructure impregnated with ciprofloxacin

Guiding bacterial growth in a micro-environment

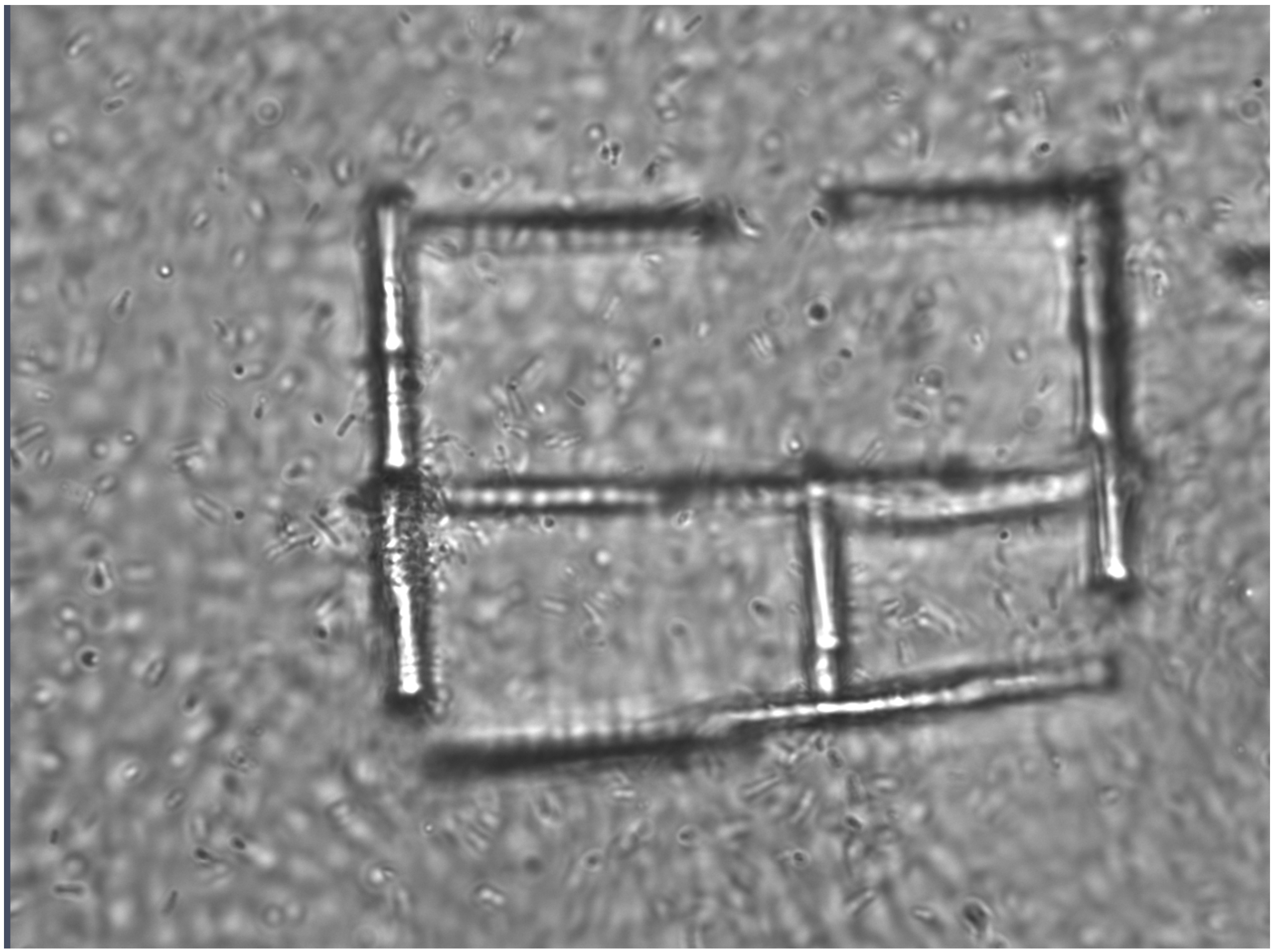
Bacteria microtraps



using micro-environments to study the dynamics of bacterial migration

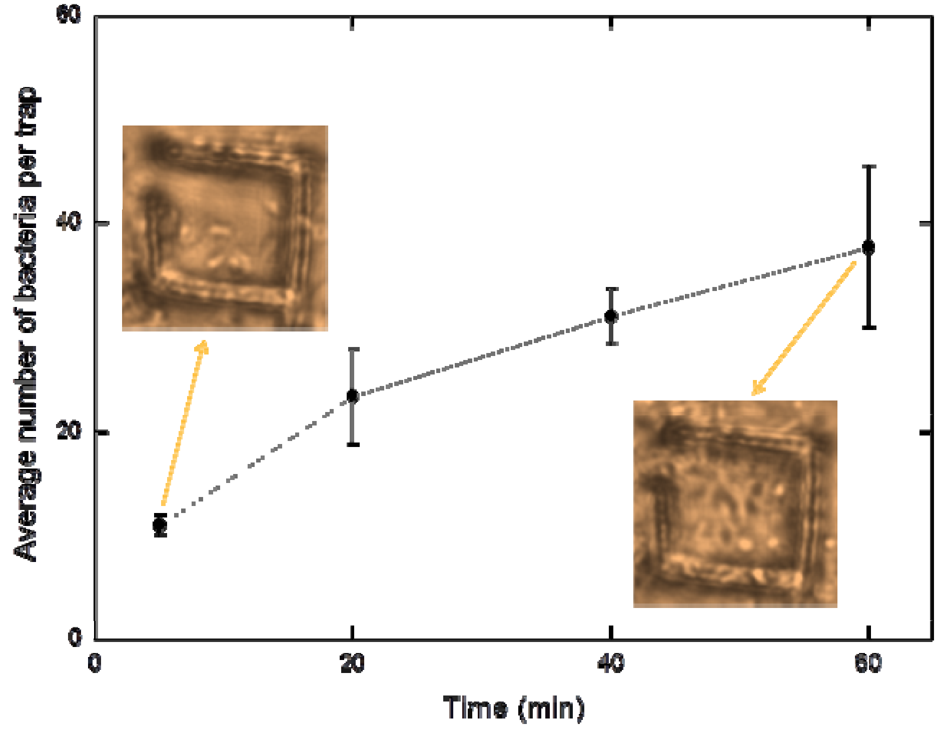
Guiding bacterial growth in a micro-environment

Bacteria microtraps



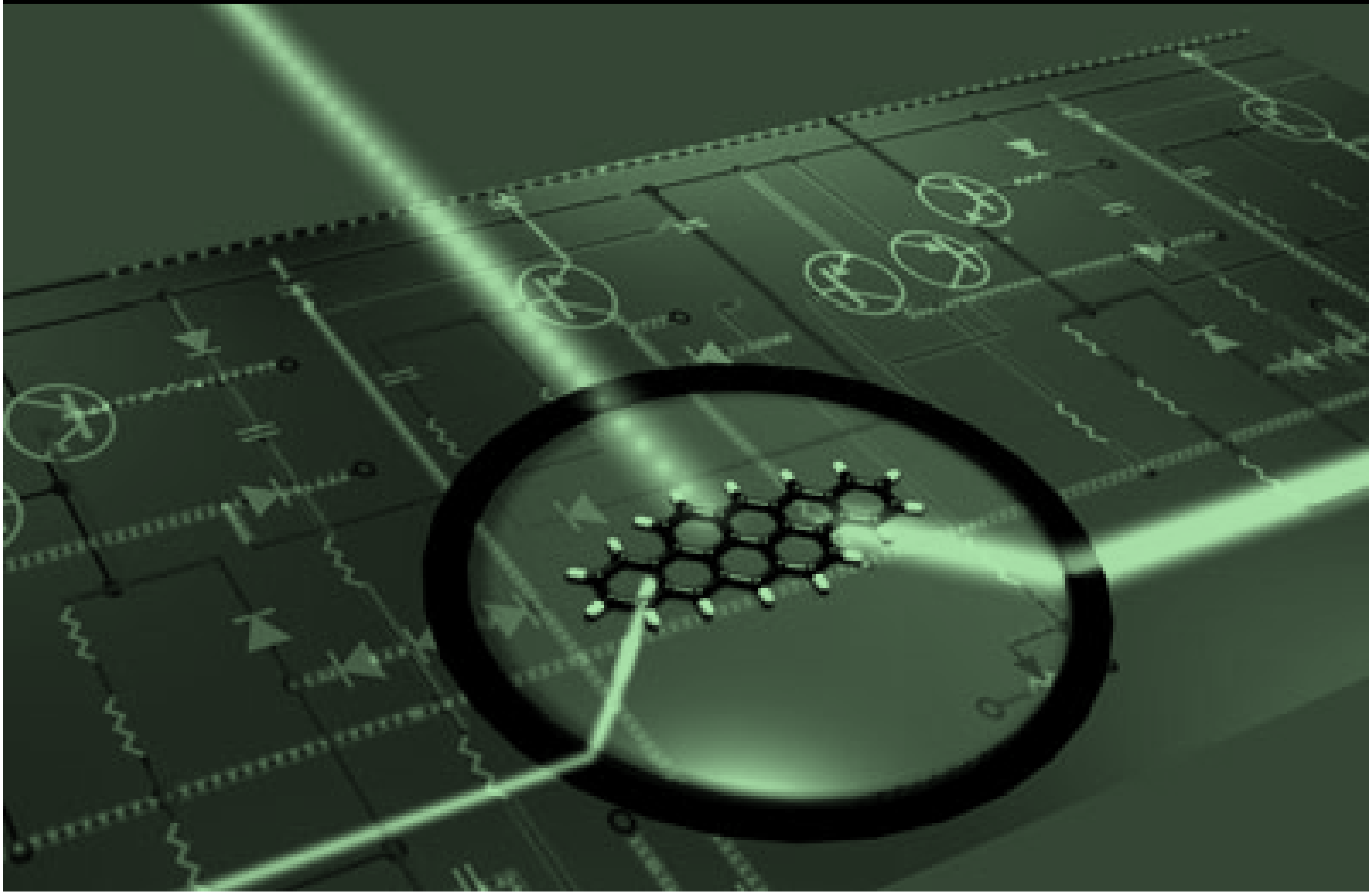
Guiding bacterial growth in a micro-environment

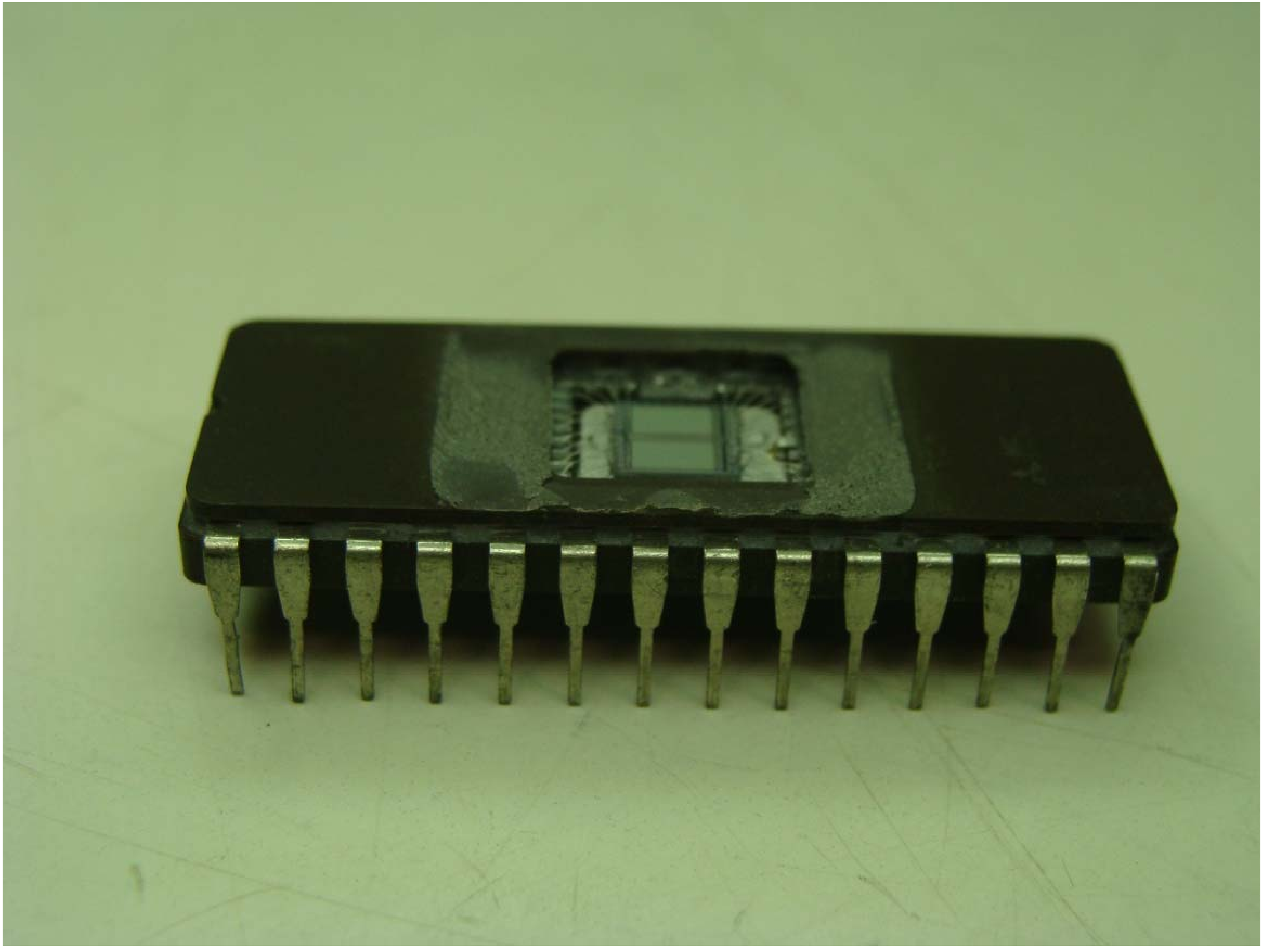
Bacteria microtraps

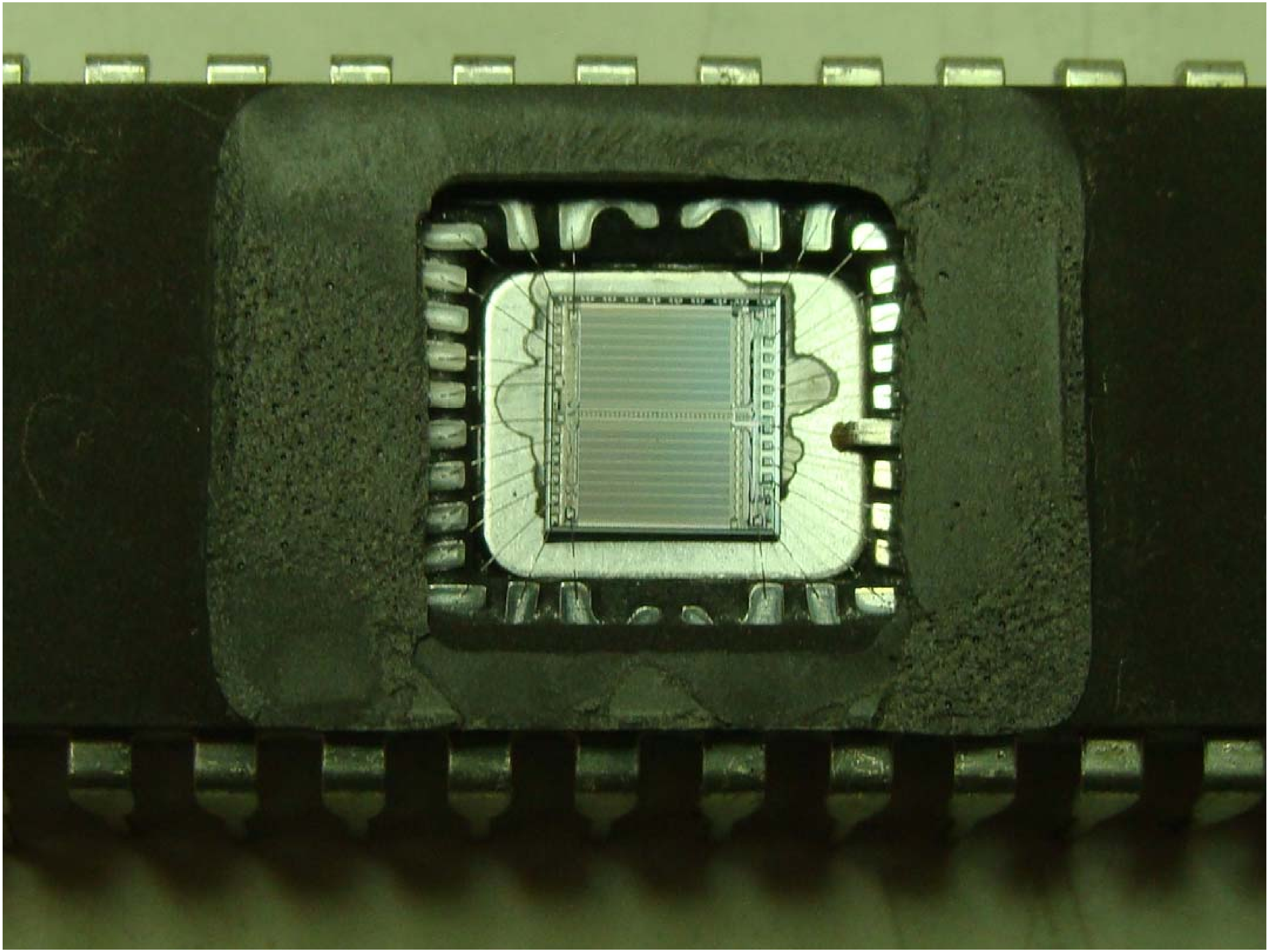


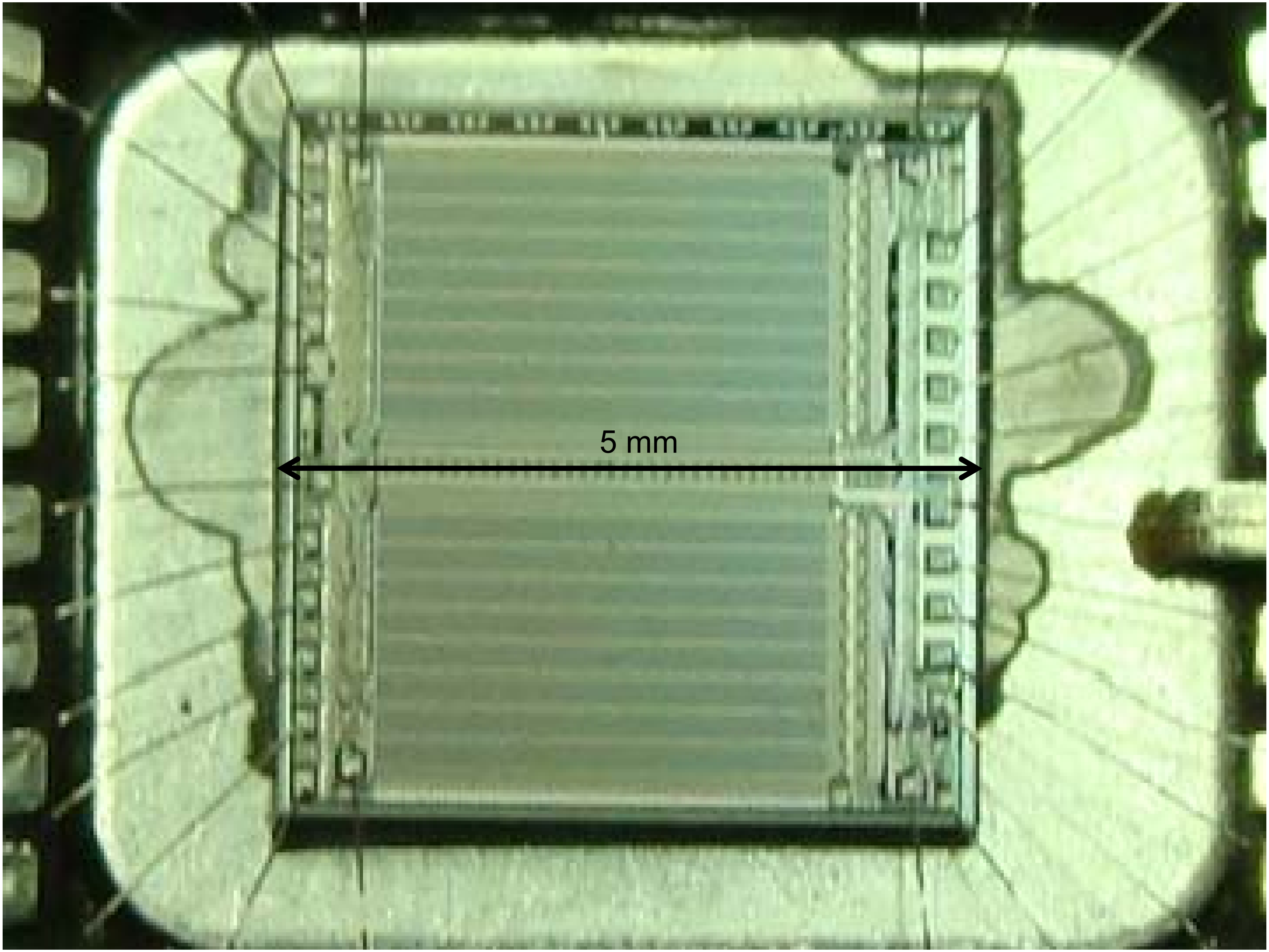
using micro-environments to study the dynamics of bacterial migration

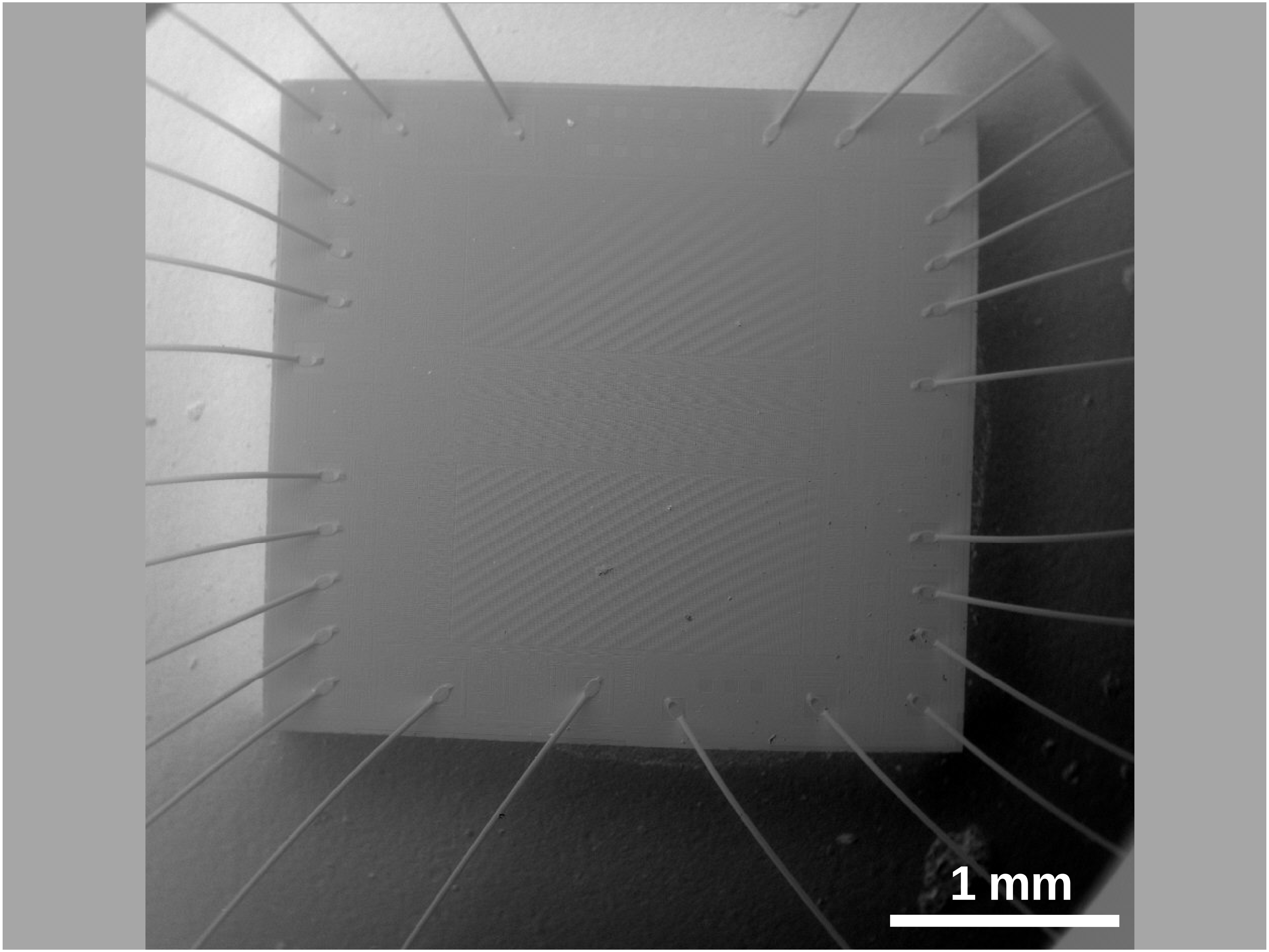
Optical circuit

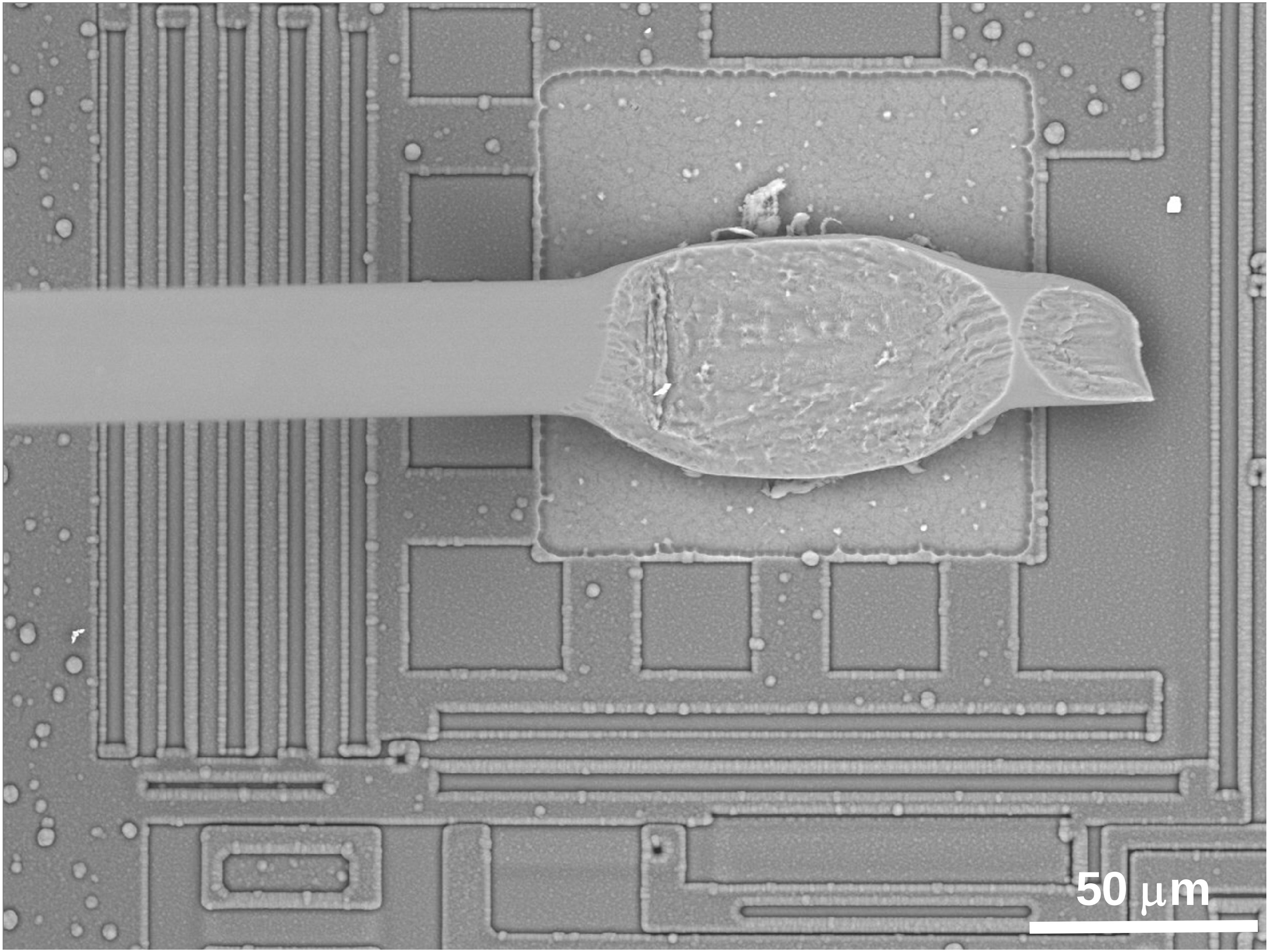






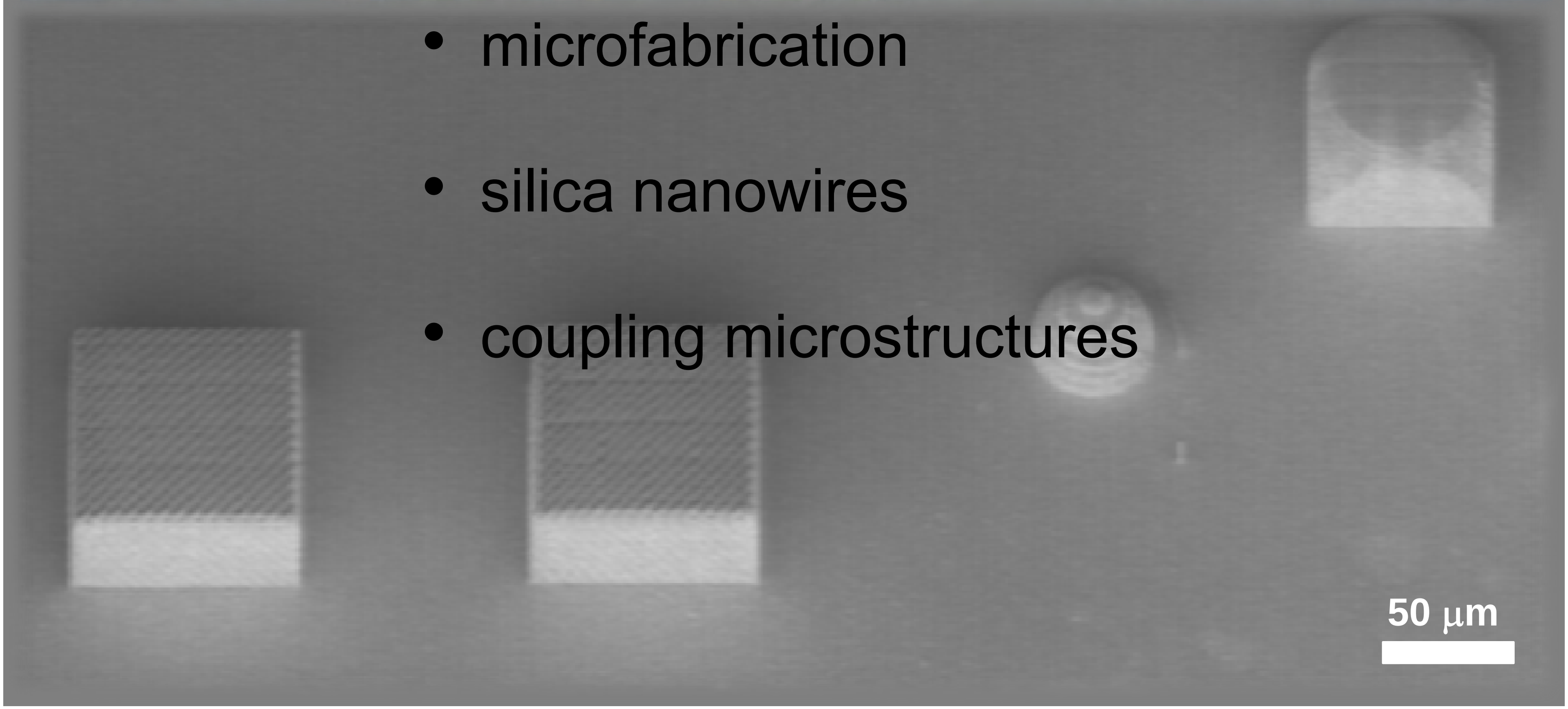

5 mm


1 mm


50 µm

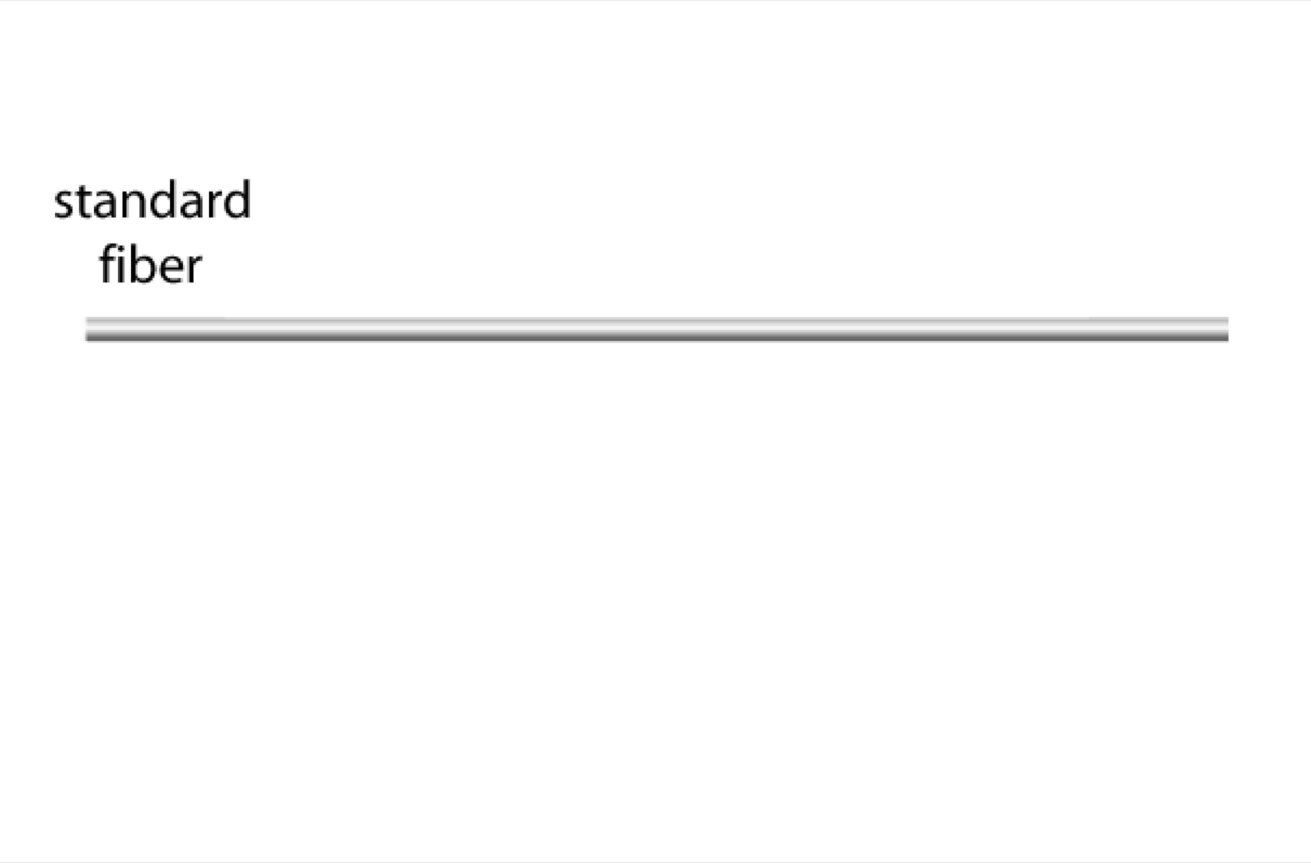
Optical circuit

- microfabrication
- silica nanowires
- coupling microstructures



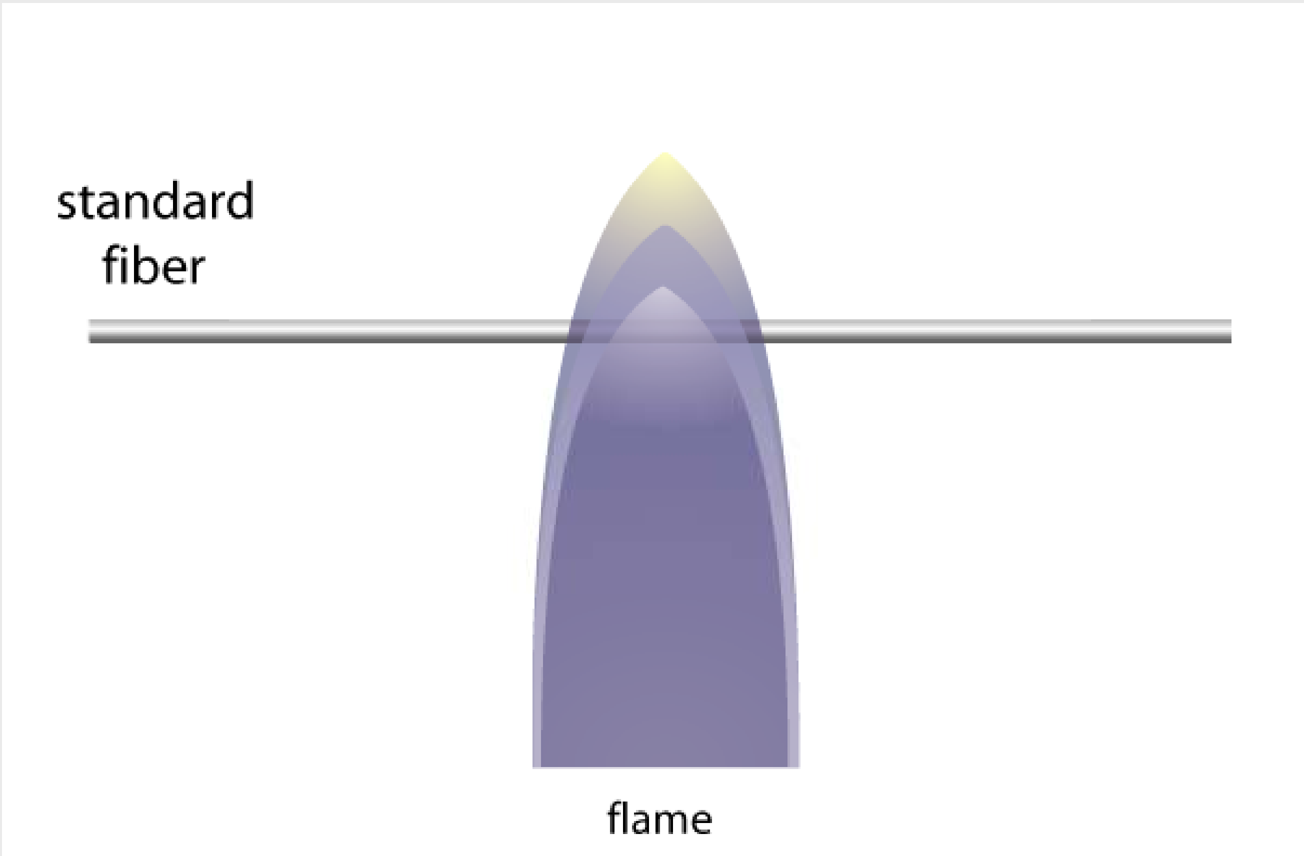
Silica nanowires

nanowires fabrication process



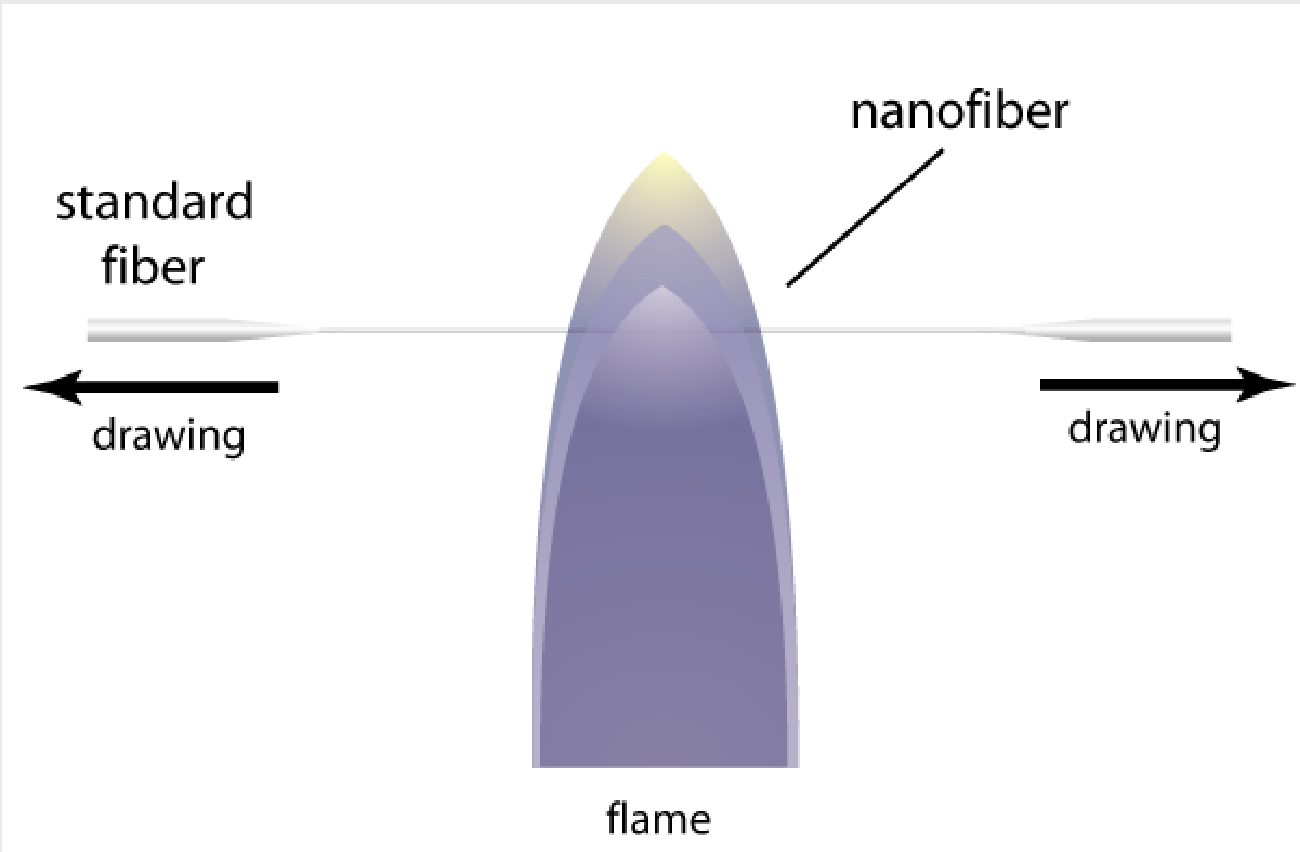
Silica nanowires

nanowires fabrication process

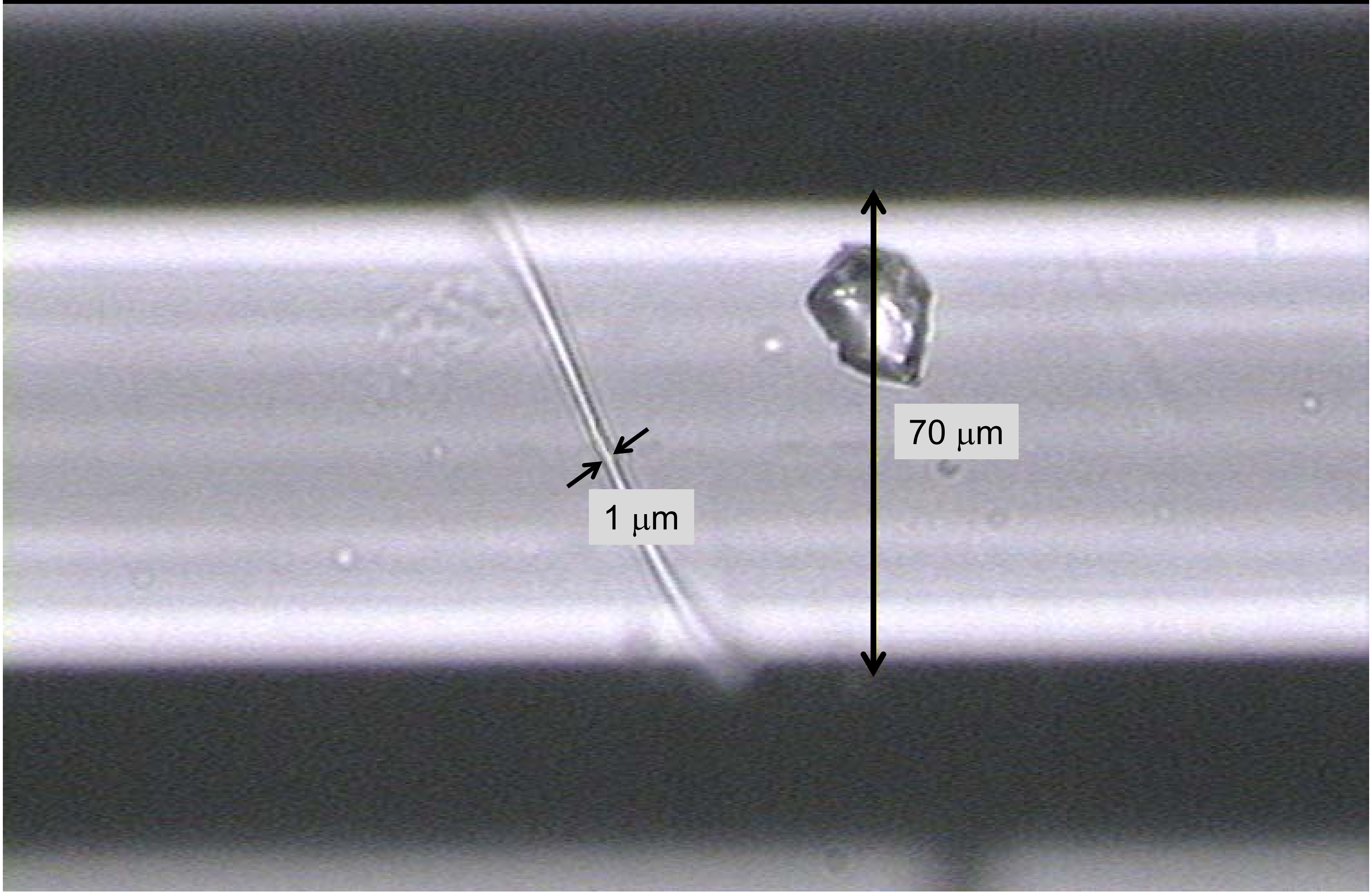


Silica nanowires

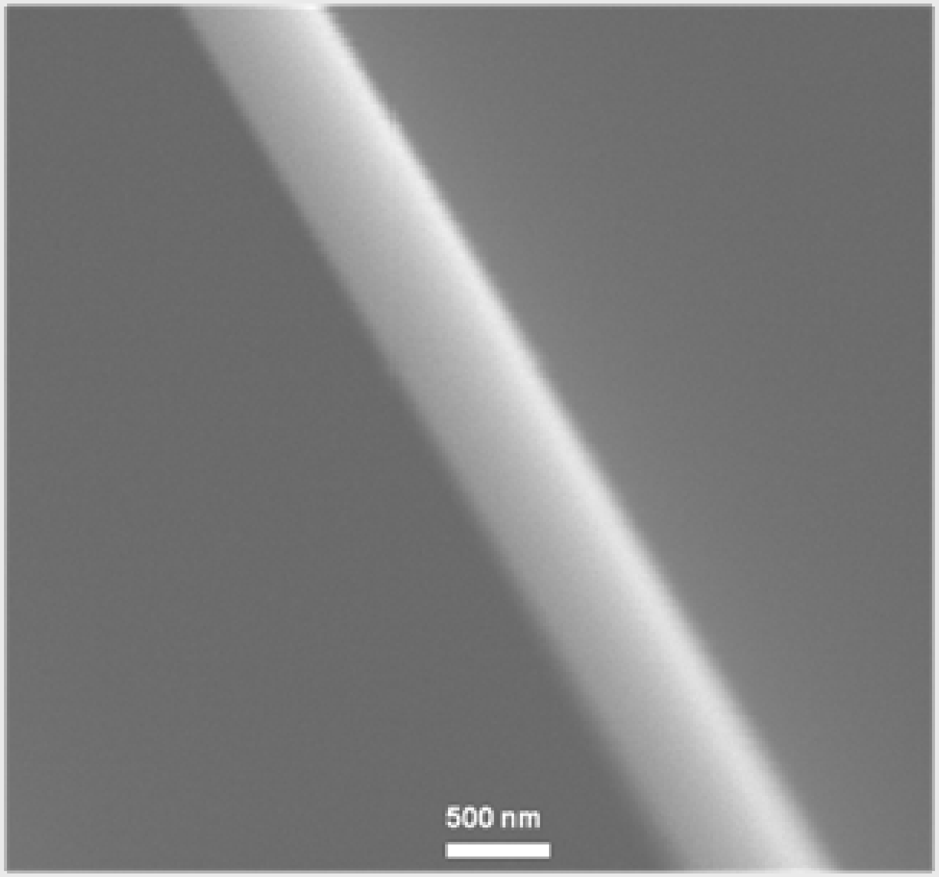
nanowires fabrication process



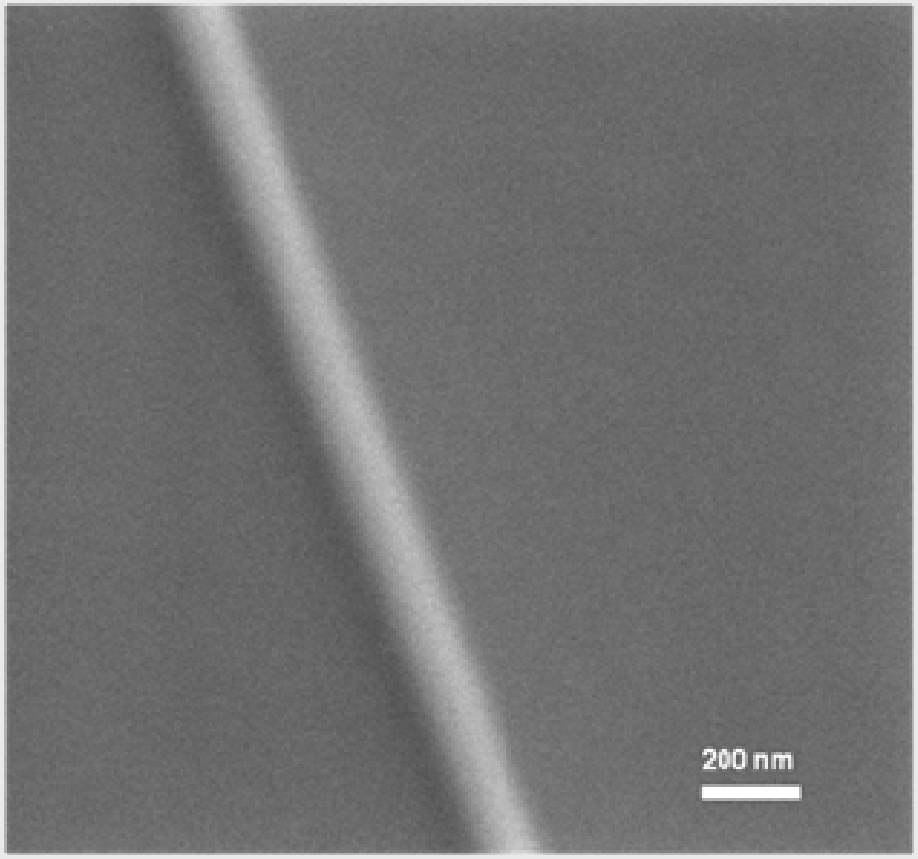
Silica nanowires



Silica nanowires

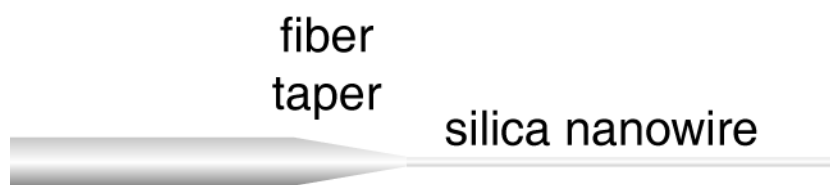


Silica nanowires



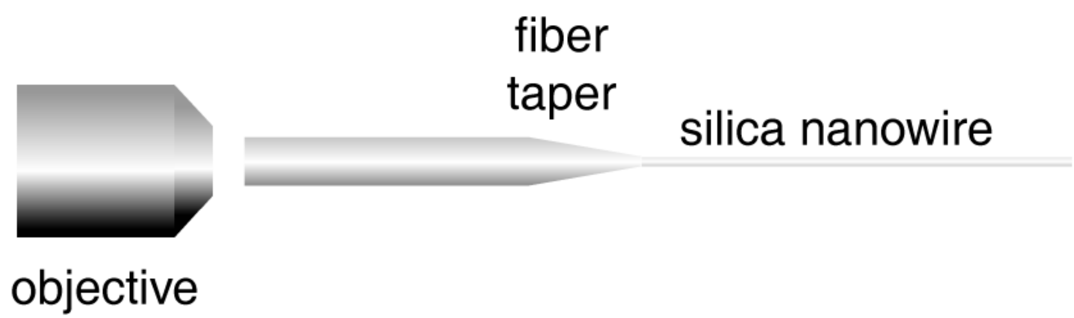
Silica nanowires

coupling light into nanowires



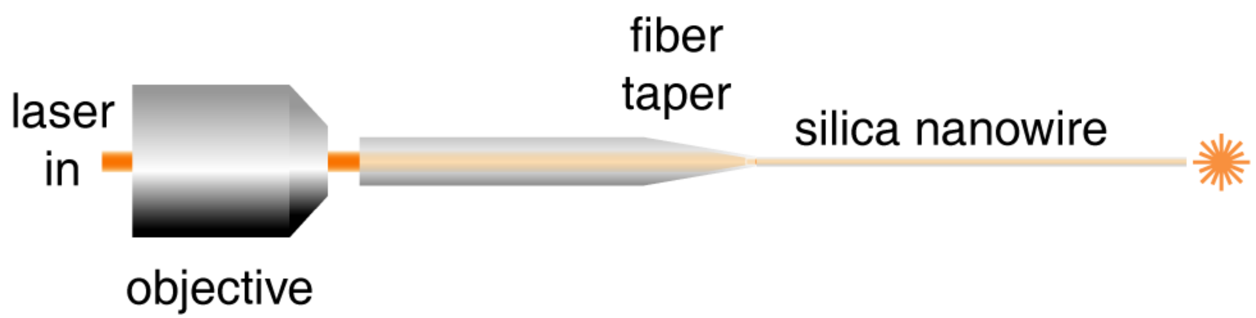
Silica nanowires

coupling light into nanowires



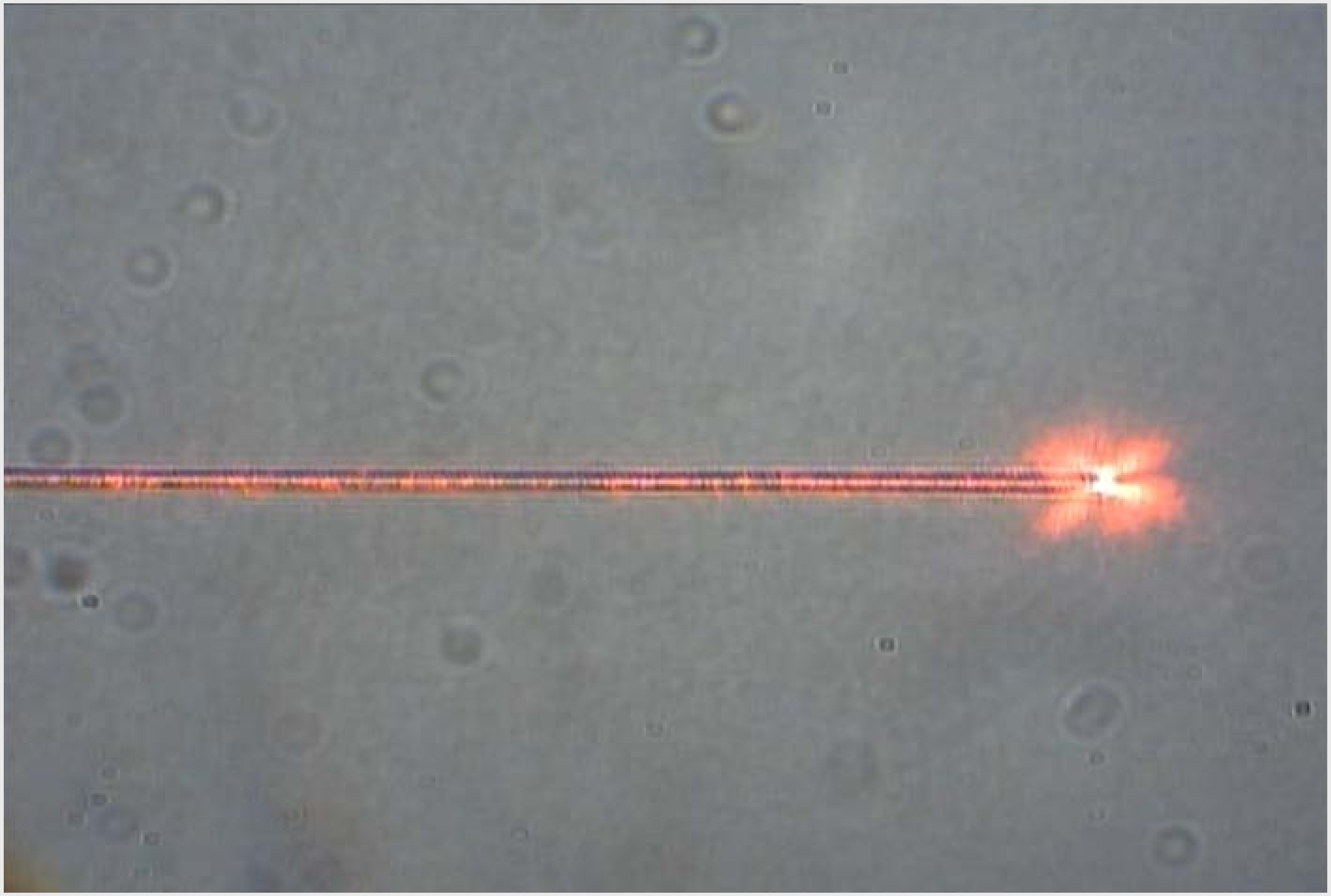
Silica nanowires

coupling light into nanowires



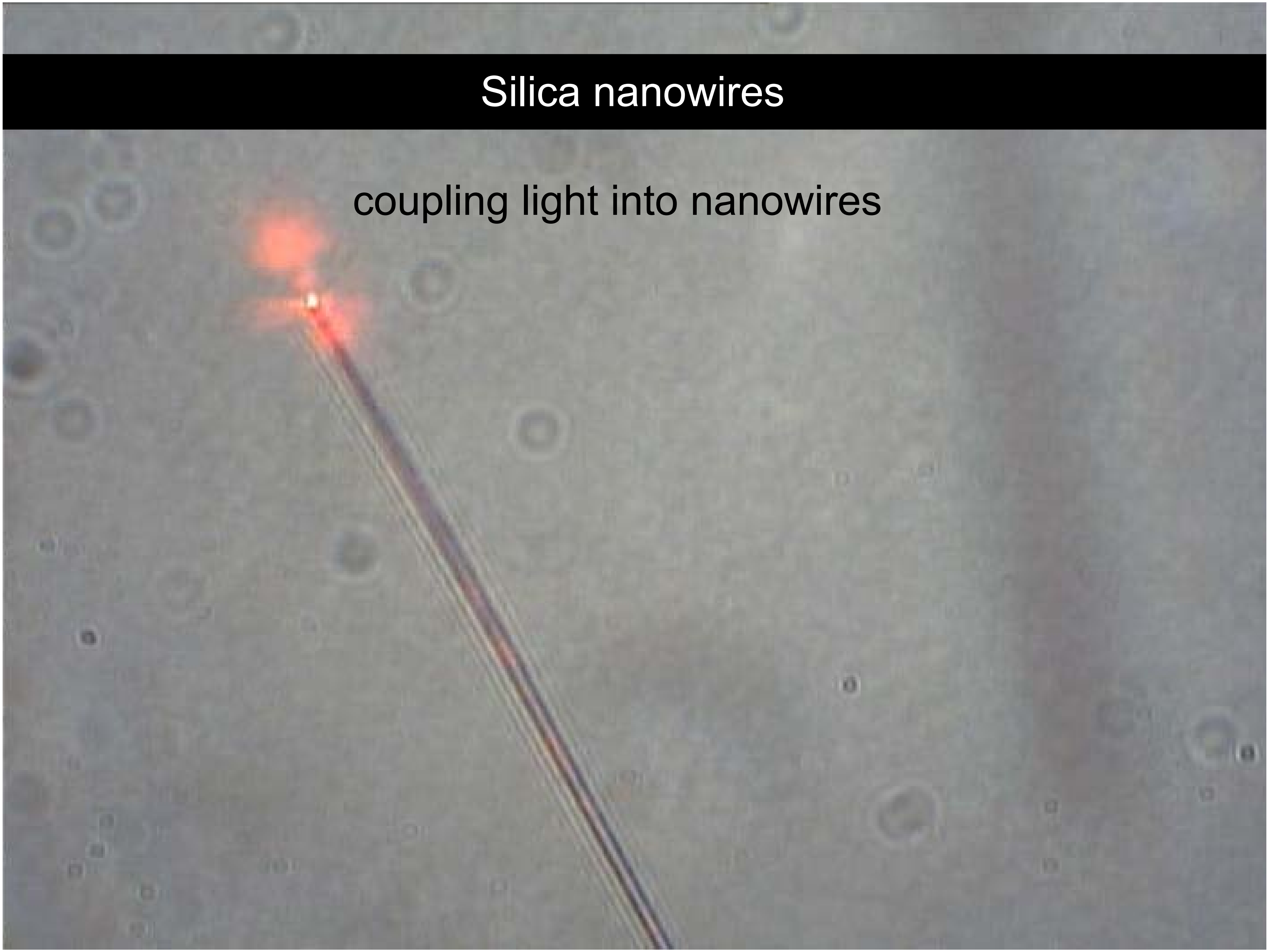
Silica nanowires

coupling light into nanowires



Silica nanowires

coupling light into nanowires



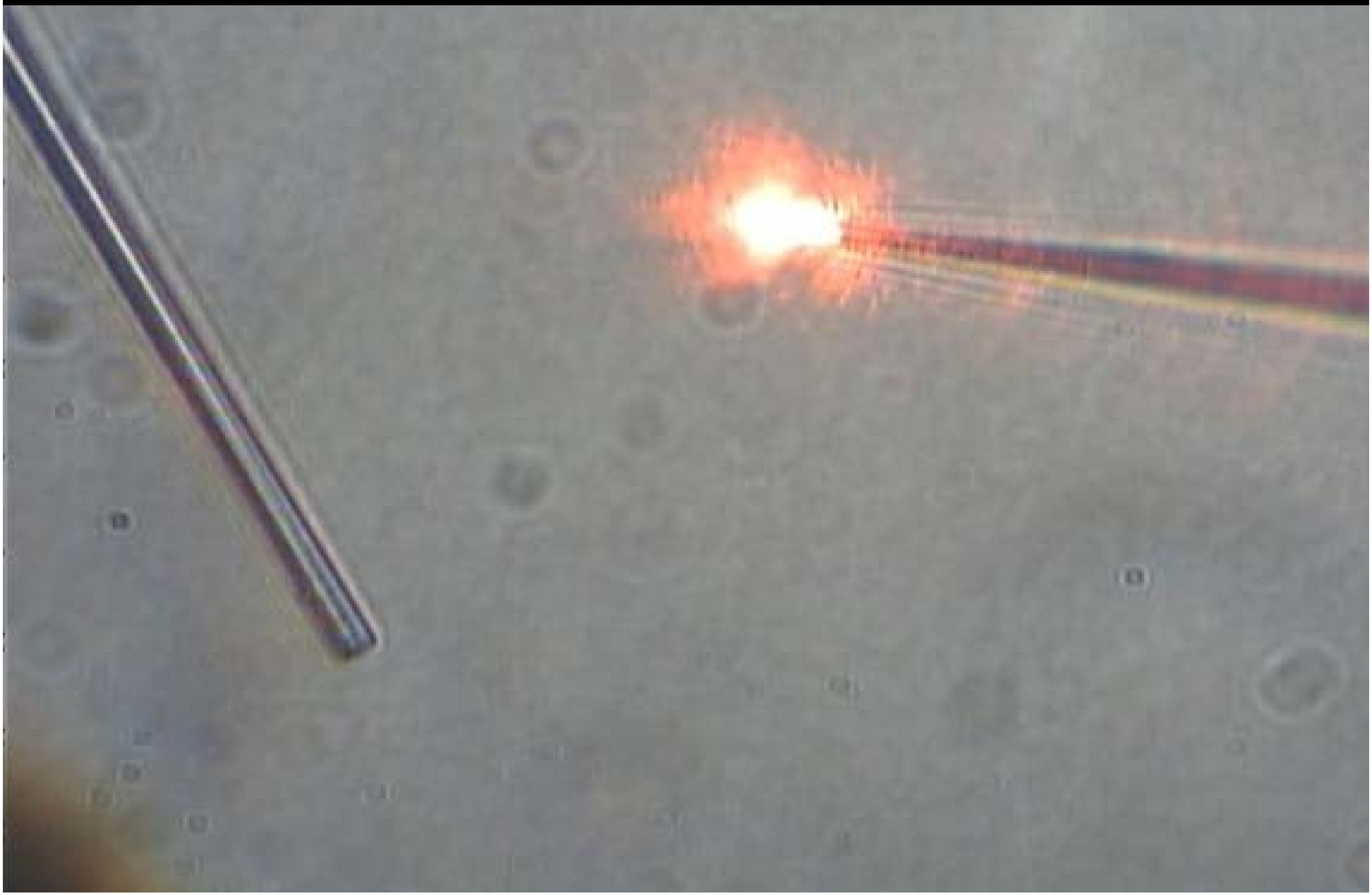
Silica nanowires

coupling light into nanowires

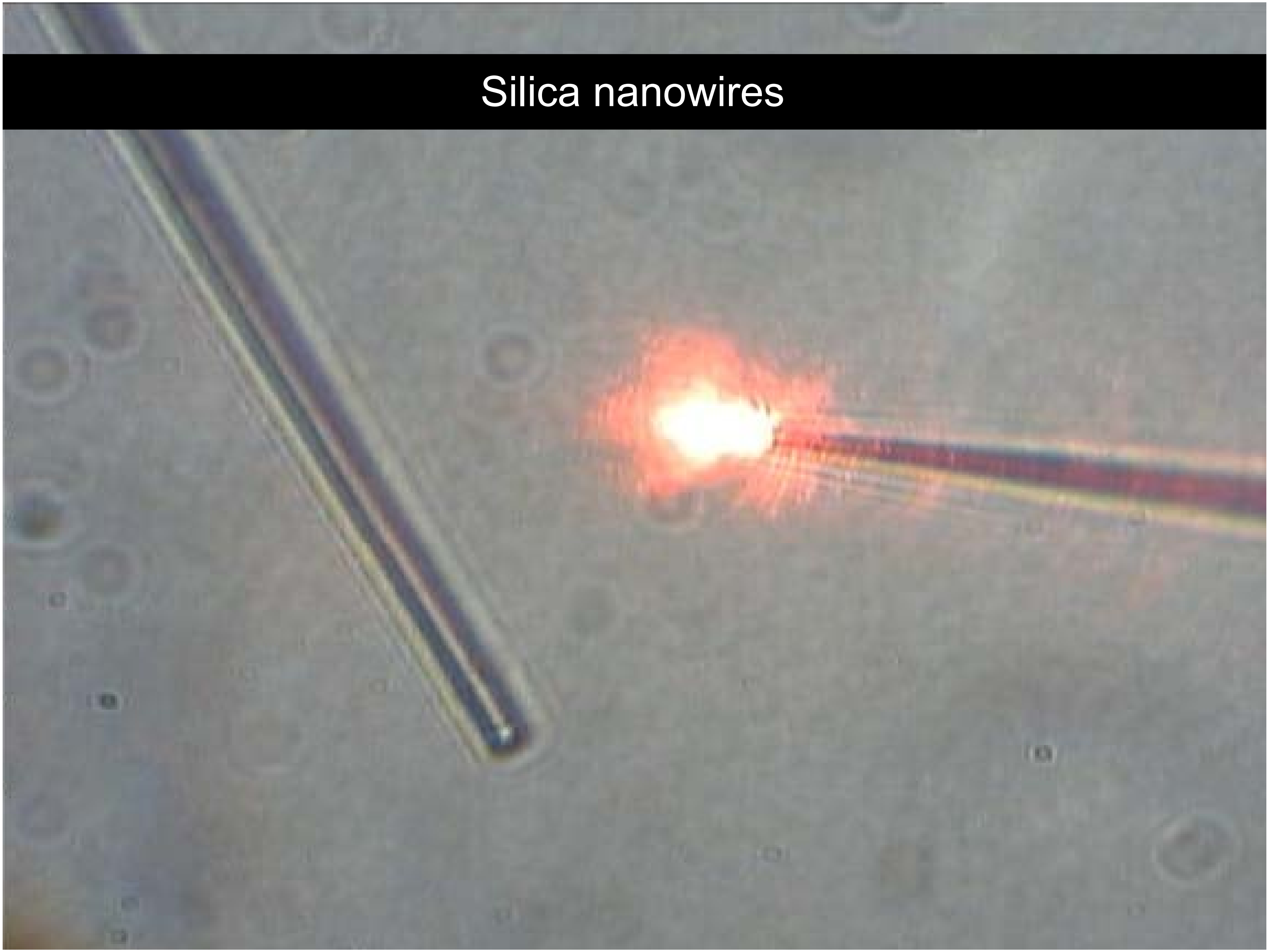
Silica nanowires

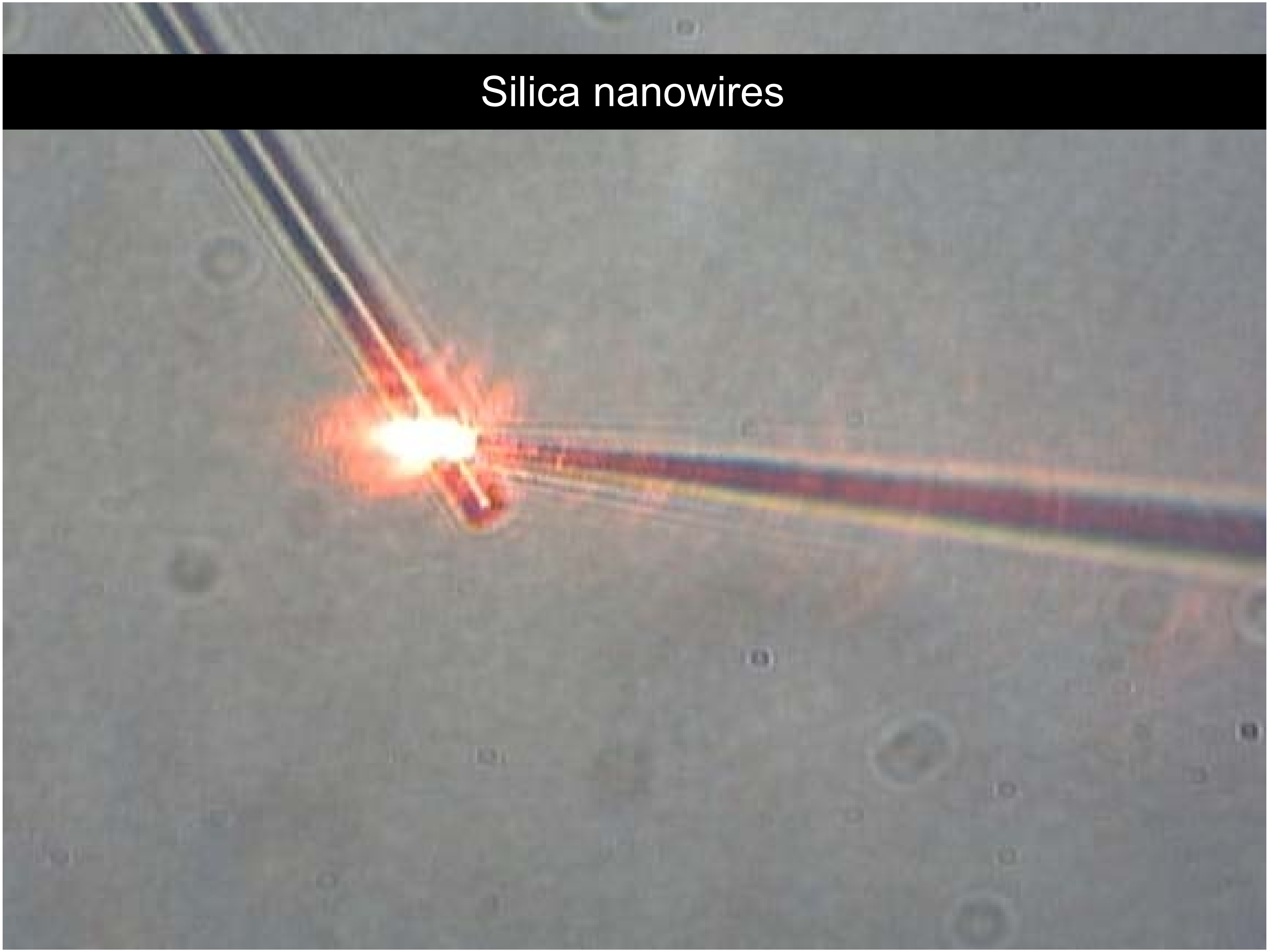
Manipulating the nanowires

Silica nanowires



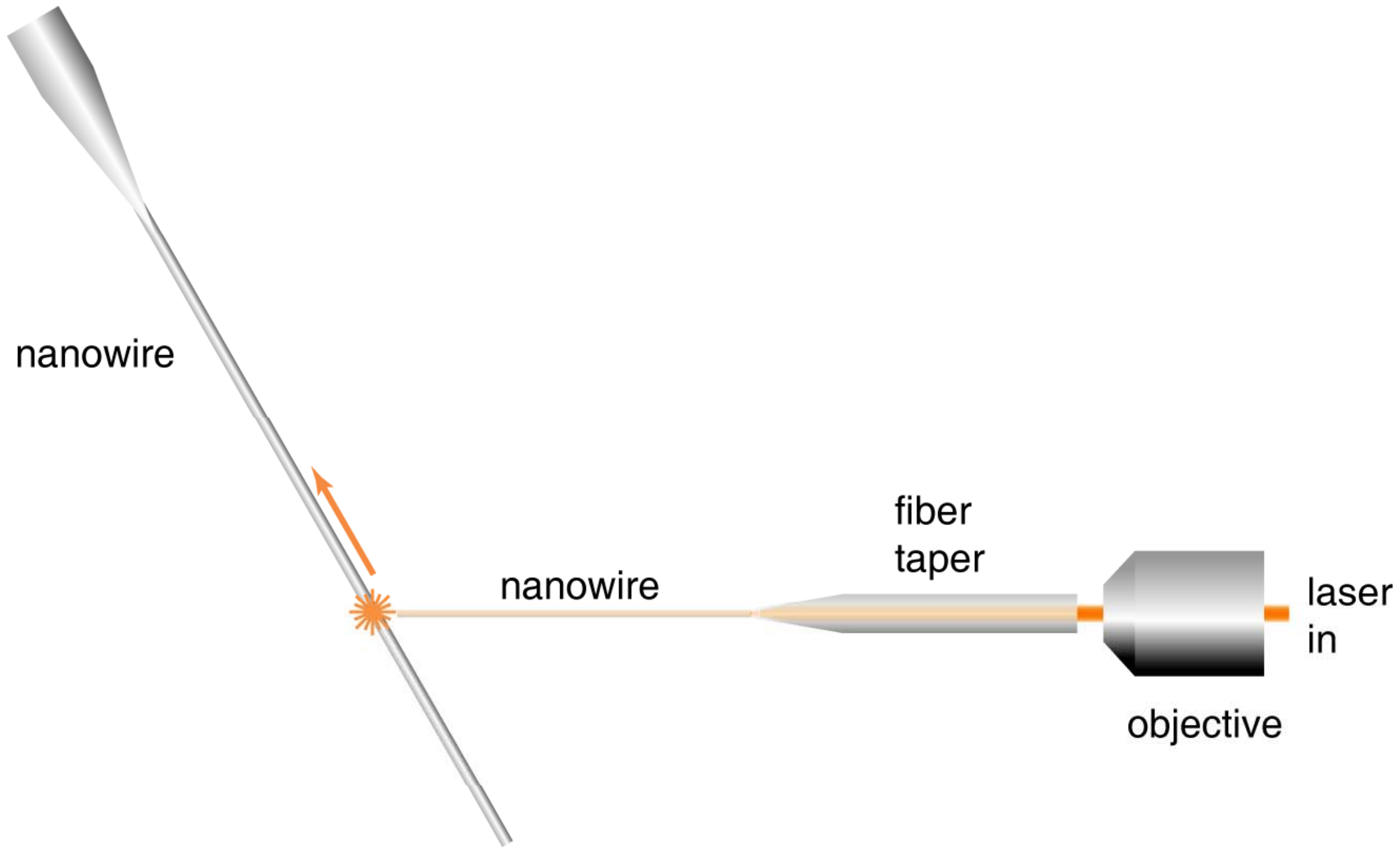
Silica nanowires




Silica nanowires

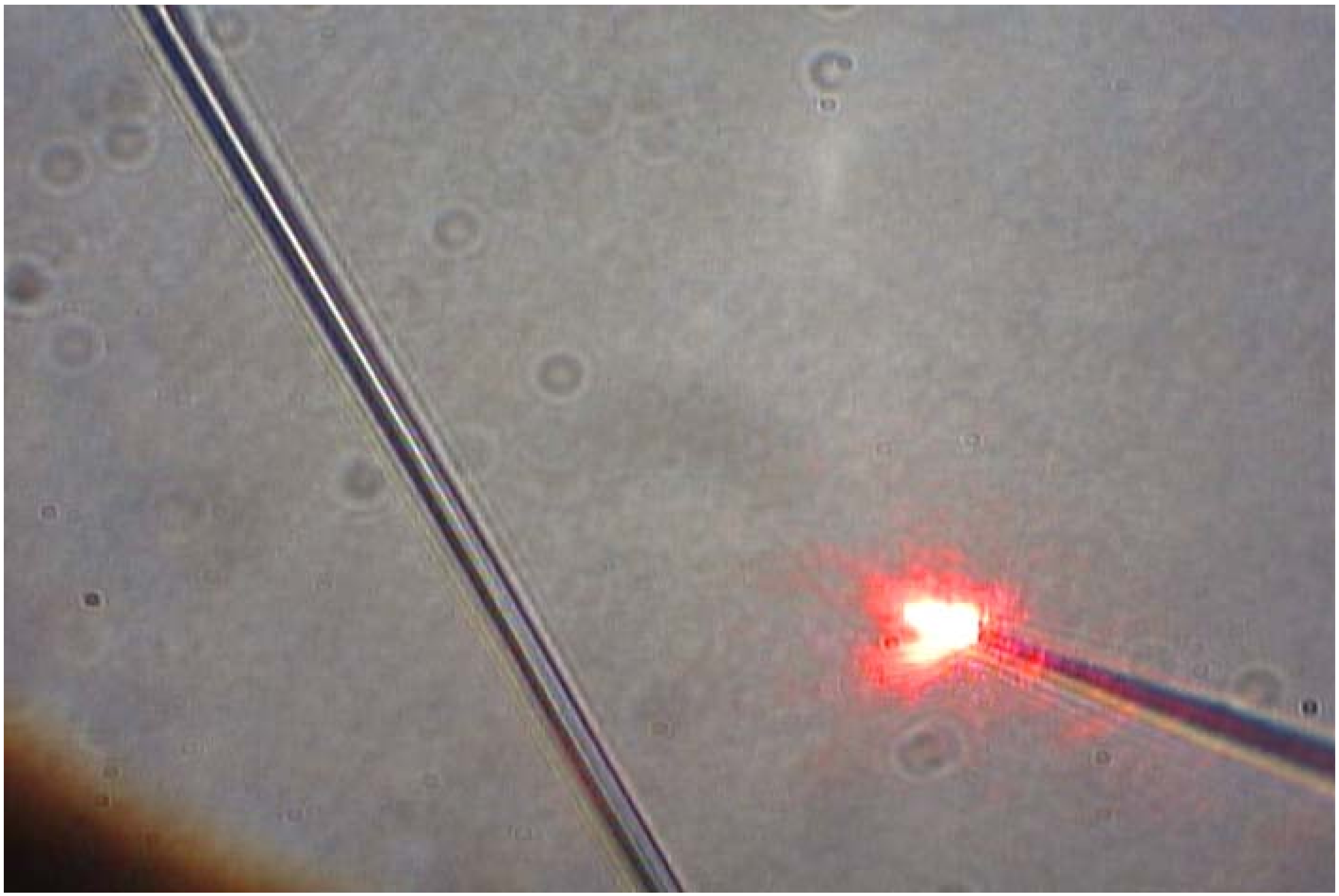
Silica nanowires

coupling light into nanowires



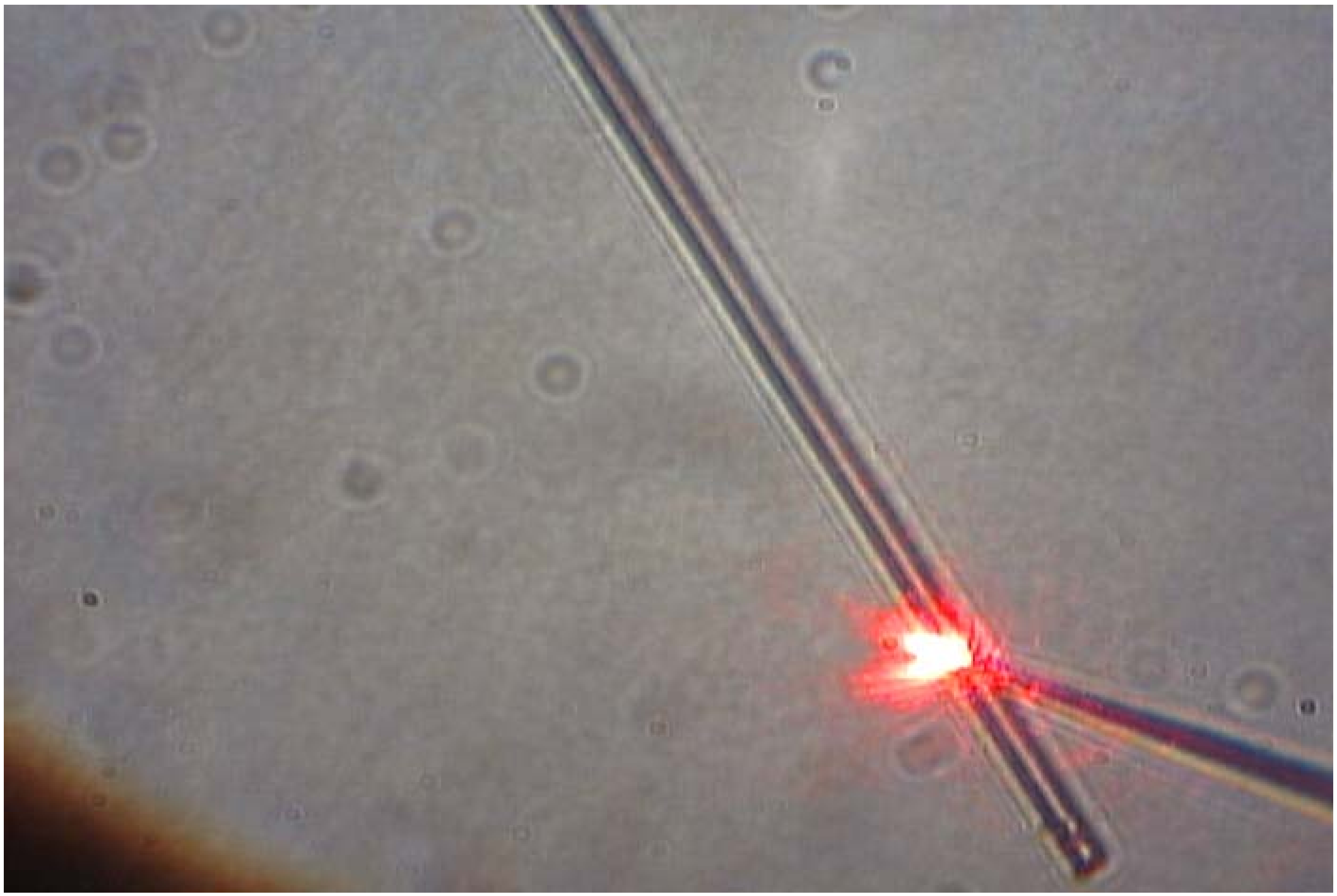
Silica nanowires

coupling light into nanowires

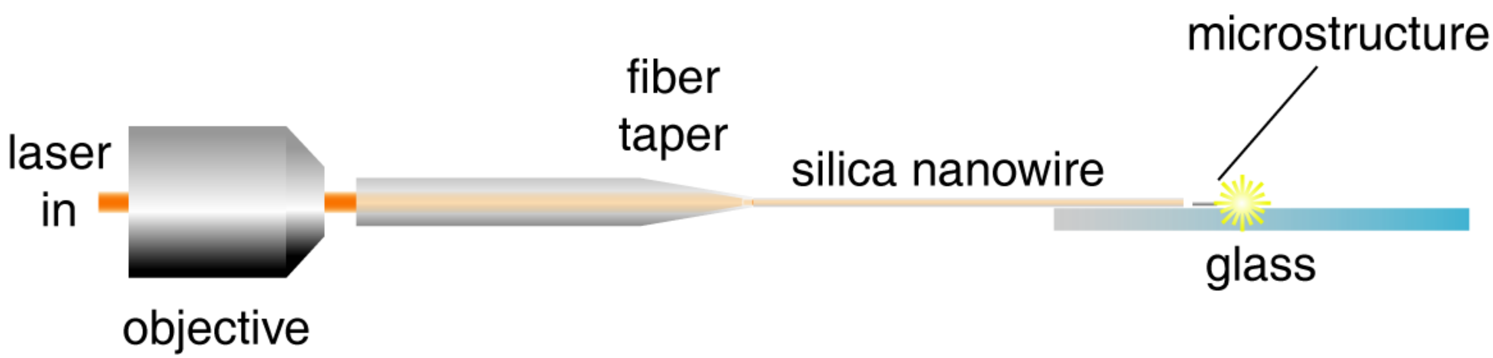


Silica nanowires

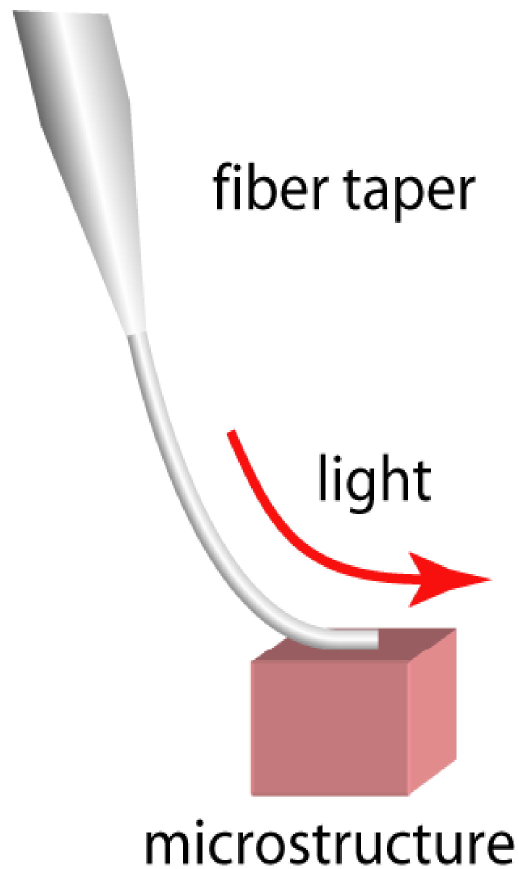
coupling light into nanowires



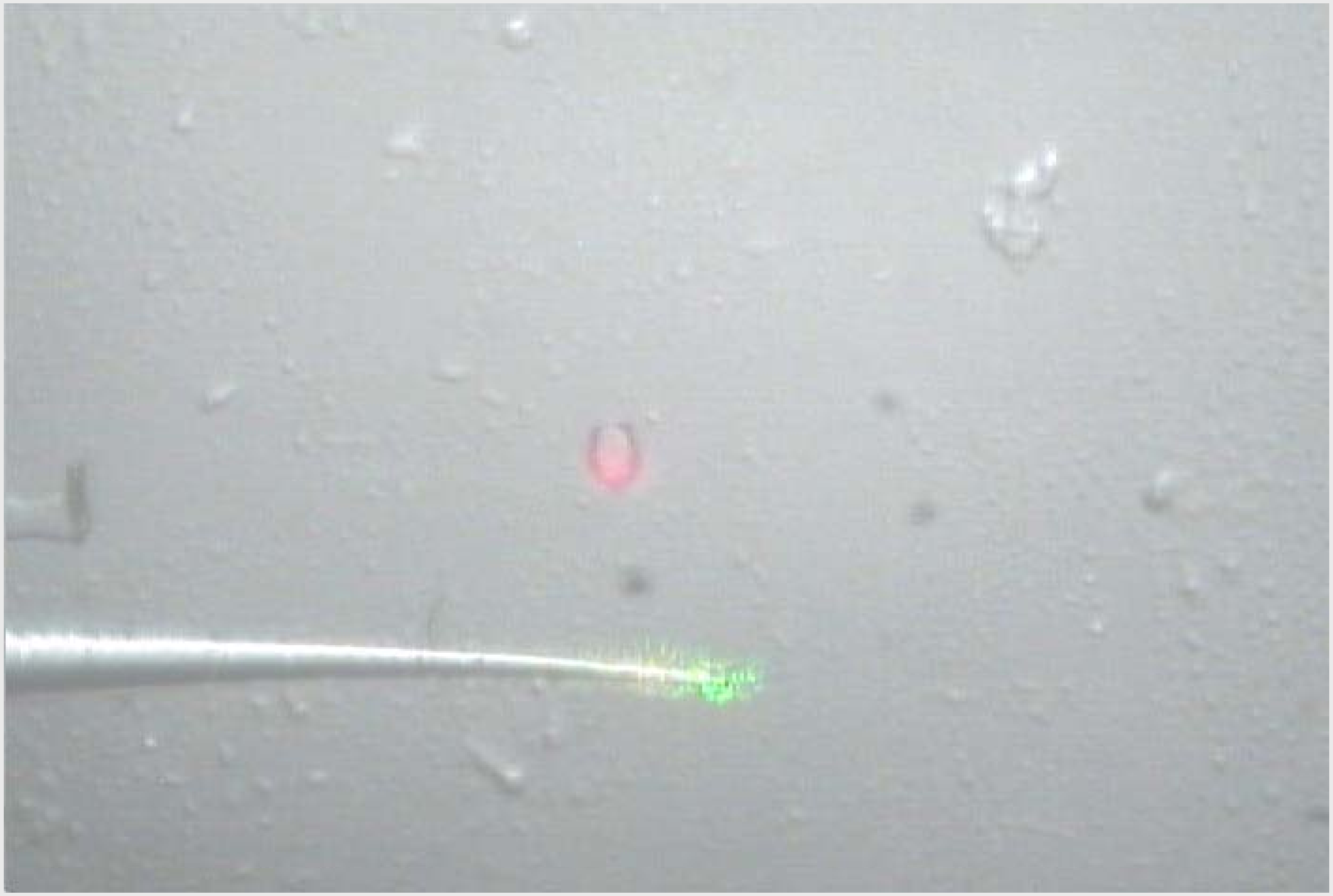
Coupling microstructures



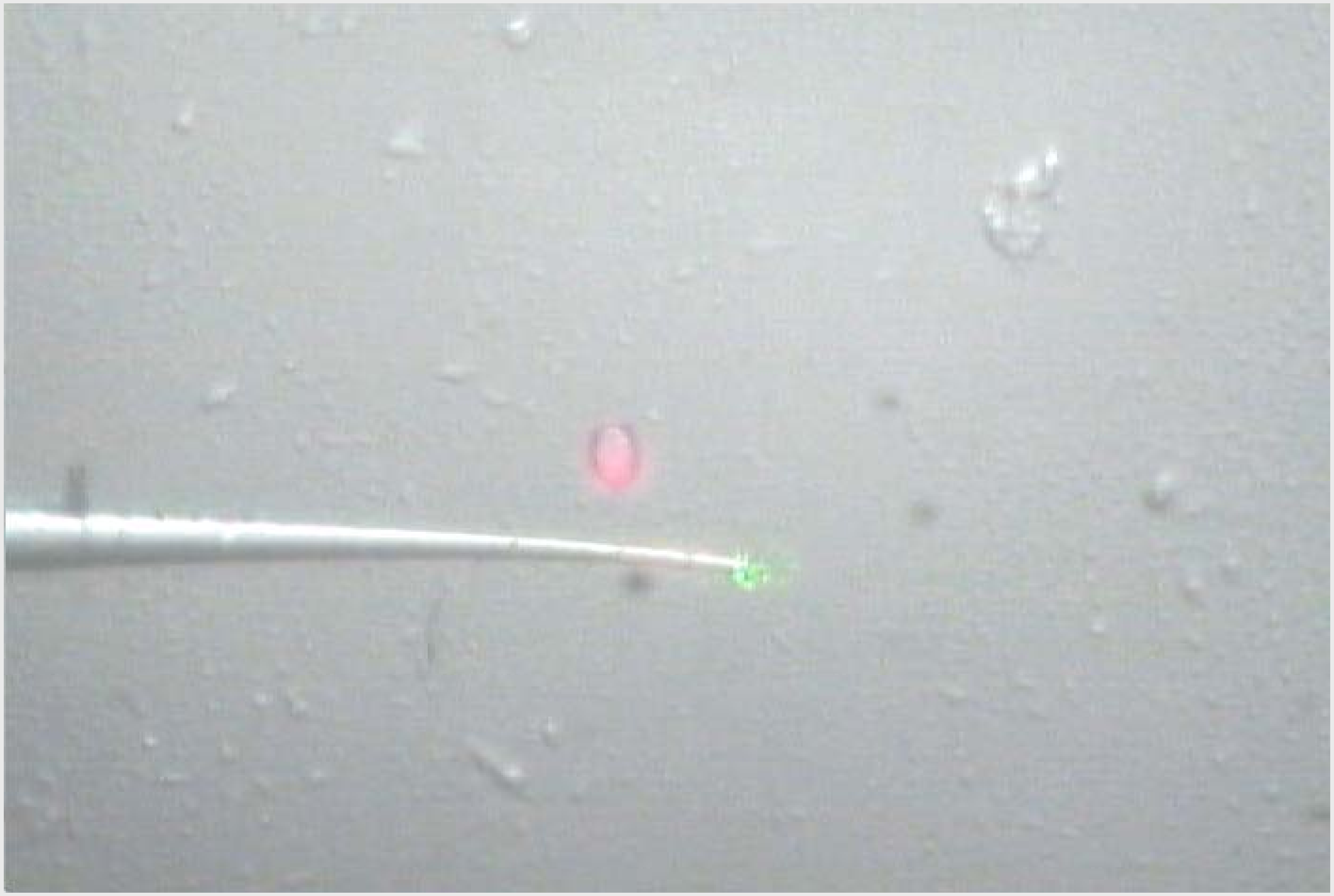
Coupling microstructures



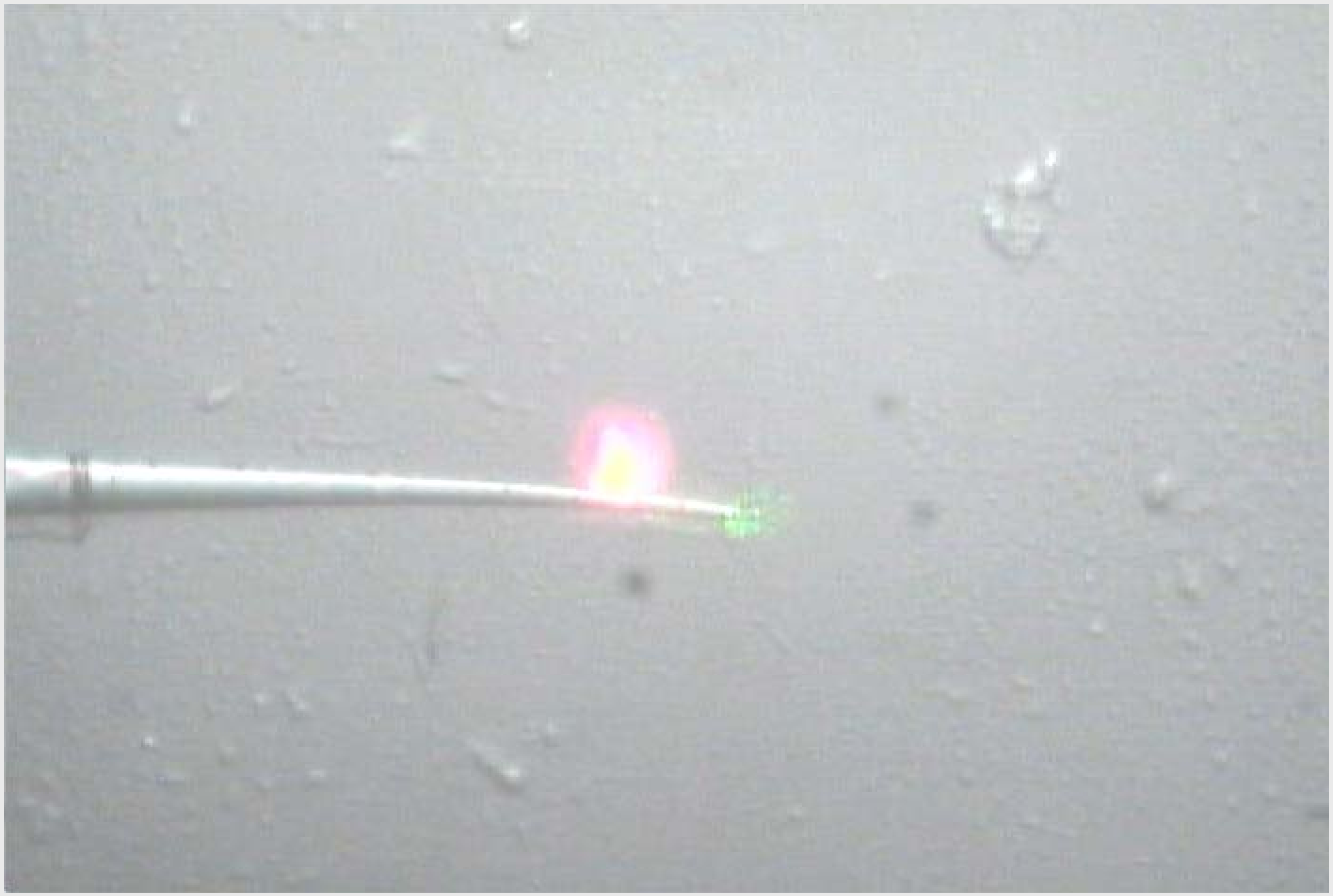
Coupling microstructures



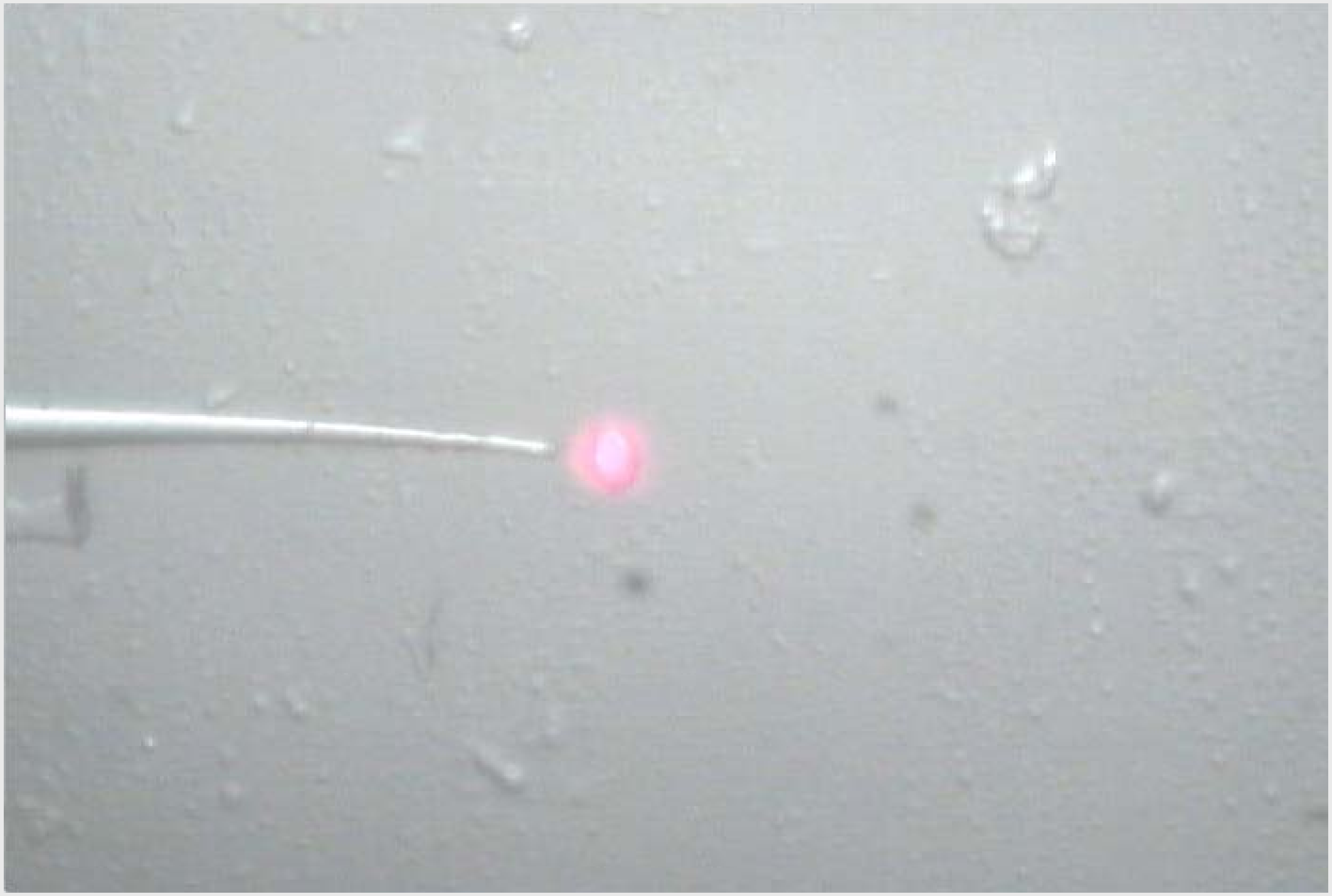
Coupling microstructures



Coupling microstructures



Coupling microstructures



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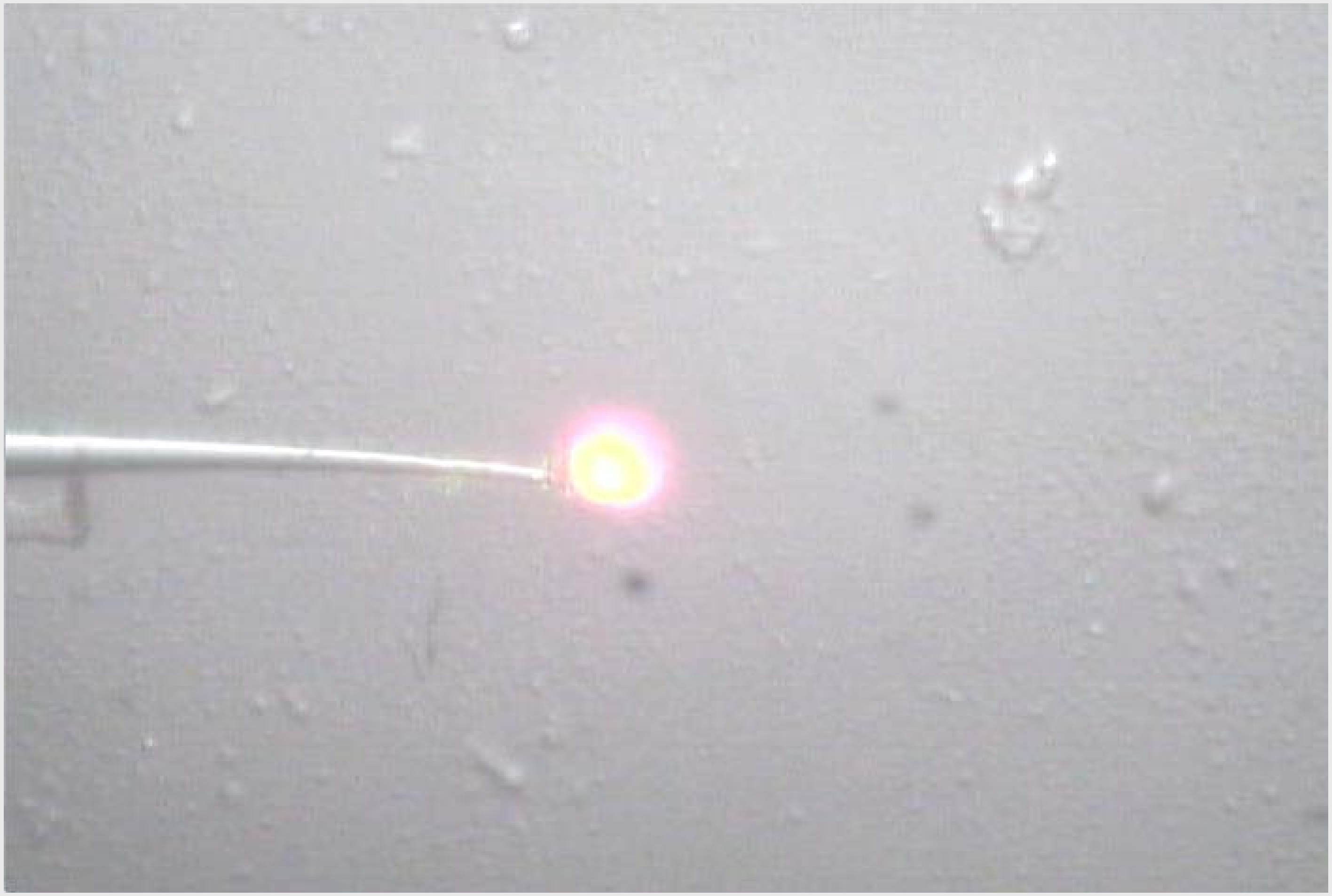

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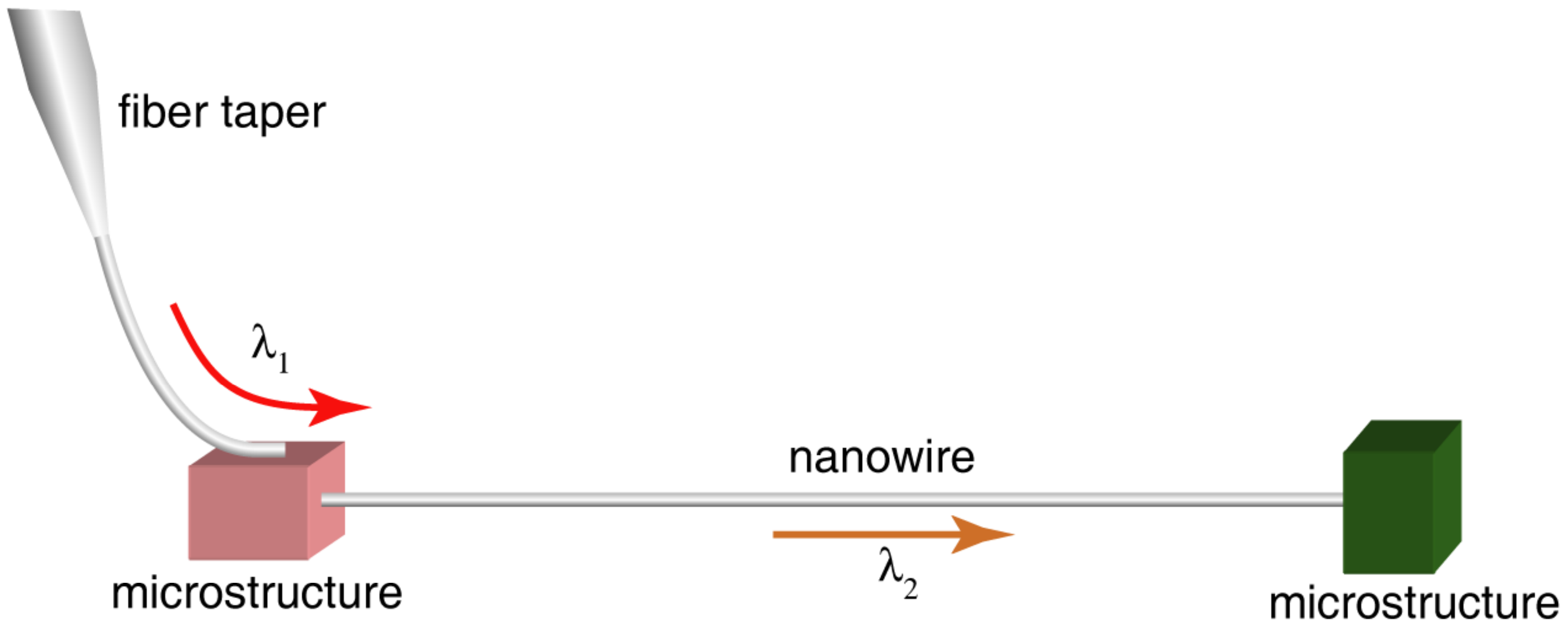
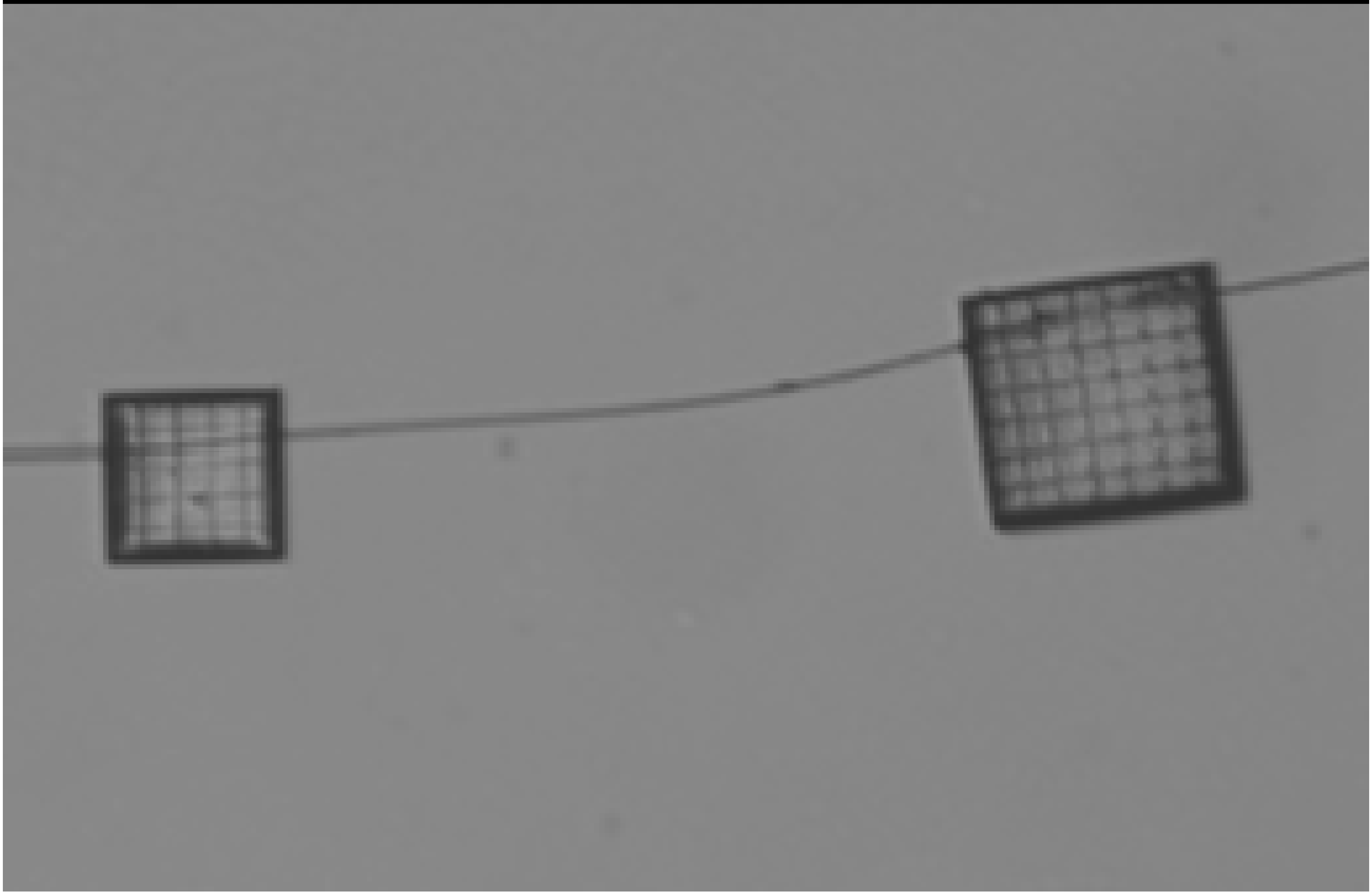


Coupling microstructures



Acknowledgments

Team

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Renato Martins
Paulo H. D. Ferreira

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